

# APPLIED PHYSICS REVIEW

## Band parameters for III–V compound semiconductors and their alloys

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We present a comprehensive, up-to-date compilation of band parameters for the technologically important III–V zinc blende and wurtzite compound semiconductors: GaAs, GaSb, GaP, GaN, AlAs, AlSb, AlP, AlN, InAs, InSb, InP, and InN, along with their ternary and quaternary alloys. Based on a review of the existing literature, complete and consistent parameter sets are given for all materials. Emphasizing the quantities required for band structure calculations, we tabulate the direct and indirect energy gaps, spin-orbit, and crystal-field splittings, alloy bowing parameters, effective masses for electrons, heavy, light, and split-off holes, Luttinger parameters, interband momentum matrix elements, and deformation potentials, including temperature and alloy-composition dependences where available. Heterostructure band offsets are also given, on an absolute scale that allows any material to be aligned relative to any other. © 2001 American Institute of Physics. [DOI: 10.1063/1.1368156]

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## I. INTRODUCTION

At present, III–V compound semiconductors provide the materials basis for a number of well-established commercial technologies, as well as new cutting-edge classes of electronic and optoelectronic devices. Just a few examples include high-electron-mobility and heterostructure bipolar transistors, diode lasers, light-emitting diodes, photodetectors, electro-optic modulators, and frequency-mixing components. The operating characteristics of these devices depend critically on the physical properties of the constituent materials, which are often combined in quantum heterostructures containing carriers confined to dimensions on the order of a nanometer. Because ternary and quaternary alloys may be included in addition to the binary compounds, and the materials may be layered in an almost endless variety of configurations, a seemingly limitless flexibility is now available to the quantum heterostructure device designer.

To fully exploit this flexibility, one clearly needs a reliable and up-to-date band parameter database for input to the electronic structure calculations and device simulations. However, after many years Volume 17 of the Landolt–Bornstein series<sup>1</sup> remains the most frequently quoted source of III–V band parameters. Although that work contains much of the required data for a broad range of materials, it is nearly 20 yr old, lacks detailed descriptions of many of the important III–V alloys, and contains no information at all on the crucial band offset alignments for heterostructures. A popular compilation by Casey and Panish<sup>2</sup> covers the band gaps for all III–V non-nitride binary materials and 12 ternary alloys, but the rapid progress in growth and characterization of many of those materials taking place since its publication in 1978 has decreased its usefulness. While a number of recent books and reviews on individual material systems are available,<sup>3–10</sup> they are not necessarily complete or mutually consistent. A useful recent compilation of band structure parameters by Levinshtein *et al.*<sup>11</sup> does not contain in-depth information on aluminum-containing elemental semiconductors, is often based on a limited number of original sources, and considers only six ternary and two quaternary alloys.

The objective of the present work is to fill the gap in the existing literature by providing a comprehensive and mutually consistent source of the latest band parameters for all of the common III–V zinc blende and wurtzite semiconductors (GaAs, AlAs, InAs, GaP, AlP, InP, GaSb, AlSb, InSb, GaN, AlN, and InN) and their ternary and quaternary alloys. The reviewed parameters are the most critical for band structure calculations, the most commonly measured and calculated, and often the most controversial. They include: (1) direct and indirect energy gaps and their temperature dependences; (2) spin-orbit splitting; (3) crystal-field splitting for nitrides; (4) electron effective mass; (5) Luttinger parameters and split-off hole mass; (6) interband matrix element  $E_P$  and the associated  $F$  parameter which accounts for remote-band effects in eight-band  $\mathbf{k}\cdot\mathbf{P}$  theory; (7) conduction and valence band deformation potentials that account for strain effects in pseudomorphic thin layers; and (8) band offsets on an absolute scale which allows the band alignments between any combination of materials to be determined. All parameter sets are fully consistent with each other and are intended to reproduce the most reliable data from the literature. For completeness, lattice constants and elastic moduli for each material will also be listed in the tables, but in most cases will not receive separate discussion in the text because they are generally well known and noncontroversial.

As a complement to the band parameter compilations, which are the main focus of this work, we also provide an overview of band structure computations. The  $\mathbf{k}\cdot\mathbf{P}$  method is outlined, followed by brief summaries of the tight-binding and pseudopotential approaches. The theoretical discussions provide a context for defining the various band parameters, and also illustrate their significance within each computational method. The tables provide all of the input parameters that are normally required for an eight-band  $\mathbf{k}\cdot\mathbf{P}$  calculation. While we have not attempted to cover every parameter that may potentially be useful, most of those excluded (e.g., the  $\kappa$  and  $q$  parameters necessary for structures in a magnetic field

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and the inversion asymmetry parameter) are either poorly characterized or have well-known best values that have not changed much over time and are easily obtained from other sources such as Landolt–Bornstein.

To the extent possible, we have fully treated the 12 major III–V binaries and their alloys. Other nominal III–V materials that are not covered include BN and other boron-containing compounds (which are commonly considered to be insulators rather than semiconductors), as well as the narrow-gap InSbBi, InTlSb, InTlAs, and InTlP alloys, which up to now have not achieved technological importance. None of these materials has been integrated appreciably into any of the mainline systems, and in most cases a paucity of band structure information precludes the recommendation of definite parameter values. On the other hand, we attempt to provide a complete and up-to-date description of the nitride family of materials, including those with a wurtzite crystal lattice, in light of its increasing prominence and the numerous intense investigations currently being conducted.

It is naturally impossible for us to universally cite every article that has ever provided information or given values for the relevant band parameters. The reference list for such a review would number in the 10's of thousands, which would be impractical even for a book-length treatment. We have therefore judiciously selected those results that are most central to the purpose of the compilation. In some cases, wide agreement on the value of a given parameter already exists, and/or previous works have critically and comprehensively reviewed the available information. Under those circumstances, we have limited the discussion to a summary of the final conclusions, along with references to the earlier reviews where additional information may be found. In other cases, we discuss more recent data that have modified or altered the earlier findings. The most difficult topics are those for which there is substantial disagreement in the literature. In those instances, we summarize the divergent views, but nonetheless choose a particular result that is either judged to be the most reliable, or represents a composite combining a variety of experimental and/or theoretical findings. Although such selections are inevitably subjective, since they require an assessment of the relative merits and reliabilities, in each case we inform the reader of the basis for our judgment.

A guiding principle has been the maintenance of full internal consistency, both in terms of temperature dependences of the parameters for a given material and with regard to variations with alloy composition. For example, composition-dependent parameter values for the  $\text{Al}_x\text{Ga}_{1-x}\text{As}$  alloy employ the best information at those intermediate compositions for which data are available, but also invariably agree with the results for GaAs and AlAs when evaluated at  $x=0$  and  $x=1$ . In a few cases, this has required the introduction of additional bowing parameters in contexts where they are not usually applied. We have also been as complete as possible in gathering all available information on the less common ternary and quaternary alloy systems.

The review is organized as follows. Discussions of the  $\mathbf{k}\cdot\mathbf{P}$ , tight-binding, and pseudopotential band structure calculations are presented in Sec. II, along with some general

considerations regarding the major band parameters. The main results for individual binary compounds, ternary alloys, and quaternary alloys are reviewed in Secs. III, IV, and V, respectively. A table summarizes the parameters recommended for each material, while the text provides justification for the choices. Section VI then reviews the band offsets that are needed to calculate energy bands in quantum heterostructure. Those results are presented in a format that references all offsets to the valence band maximum of InSb, which allows a determination of the relative band alignment for any possible combination of the materials covered in this work.

## II. RELATION TO BAND STRUCTURE THEORY AND GENERAL CONSIDERATIONS

A number of excellent books and review articles have summarized the methods for calculating bulk<sup>12–14</sup> and heterostructure<sup>15–20</sup> band structures. Since the present review is intended to focus on band-parameter compilation rather than theoretical underpinnings, this survey is aimed primarily at providing a context for the definitions of the various parameters. The section is limited to a discussion of the bare essentials for treating heterostructures and a brief description of the practical approaches. A more detailed description of the theory will be presented elsewhere.

### A. Multiband $\mathbf{k}\cdot\mathbf{P}$ method

The most economical description of the energy bands in semiconductors is the effective mass approximation, which is also known as the envelope function approximation or multiband  $\mathbf{k}\cdot\mathbf{P}$  method. It uses a minimal set of parameters that are determined empirically from experiments. By means of a perturbative approach, it provides a continuation in the wave vector  $k$  of the energy bands in the vicinity of some special point in the Brillouin zone (BZ).

The electronic wave functions that satisfy the Schrödinger equation with a periodic lattice potential in a bulk crystal are given by Bloch's theorem:

$$\psi(r) = e^{ikr} u_{nk}(r). \quad (2.1)$$

The cell-periodic Bloch functions  $u_{nk}(r)$  depend on the band index  $n$  and the envelope function wave vector  $k$ . The wave functions  $\psi(r)$  form a complete set of states as do the wave functions based on Bloch functions at any other wave vector, including the wave vectors at special points in the BZ.<sup>21</sup> In treating the optical and electronic properties of direct gap semiconductors, it is natural to consider the zone-center  $\Gamma$ -point Bloch functions  $u_{n0}(r)$  for our wave function expansions, and we drop the reference to the  $k=0$  index for these functions.

For our purposes here, the general form of the wave functions may be considered to be a linear combination of a finite number of band wave functions of the form

$$\psi(r) = f_n(z) e^{ik_x x} e^{ik_y y} u_n(r) \equiv F_n(r) u_n(r). \quad (2.2)$$

The envelope functions  $F_n(r)$  are typically considered to be slowly varying, whereas the cell periodic and more oscillatory Bloch functions satisfy Schrödinger's equation with band-edge energies. We distinguish envelope functions cor-

responding to the  $\Gamma_1$  conduction  $c$ ,  $\Gamma_{15}$  valence  $v$ , and the energetically higher remote bands with an index  $r$ :  $F_r = \{F_c, F_v, F_r\}$ . The remote bands are assumed to have band-edge energies  $|E_r - E_{cv}| \gg |E_c - E_v| = E_g$ , where  $E_g$  is the direct energy gap.

Next, Lowdin's perturbation theory<sup>22</sup> is applied in order to eliminate the functions  $F_r$  in favor of perturbation terms in the equations for the conduction and valence bands. In the bulk  $\mathbf{k} \cdot \mathbf{P}$  theory, these terms correspond to the Kane model<sup>23,24</sup> for the band structure, with quadratic  $[\mathbf{O}(k^2)]$  terms within the conduction and the valence bands<sup>24,25</sup> as well as the appropriate interband (conduction-valence) terms.

## 1. Zinc blende materials

The zinc blende crystal consists of two interpenetrating face-centered-cubic lattices, one having a group-III element atom (e.g., Ga) and the other a group-V element atom (e.g., As). A zinc blende crystal is characterized by a single lattice constant  $a_{lc}$ .

The matrix elements of the momentum operator between the conduction and valence bands can be expressed in terms of a single parameter  $\mathbf{P}$ , originally defined by Kane:

$$\mathbf{P} \equiv \frac{-i\hbar}{m_0} \langle S | p_x | X \rangle, \quad (2.3)$$

where  $\langle S | p_x | X \rangle$  is the momentum matrix element between the  $s$ -like conduction bands and  $p$ -like valence bands. Its value in a given material is usually reported in energy units (eV) as:

$$E_P = \frac{2m_0}{\hbar^2} \mathbf{P}^2. \quad (2.4)$$

The  $E_P$  matrix element is one of the band parameters that is extensively reviewed in the subsequent section.

Through second-order perturbation theory, the higher-band contributions to the conduction band are parameterized by the Kane parameter  $F$ , whose values are reviewed in the subsequent sections:

$$F = \frac{1}{m_0} \sum_r \frac{|\langle S | p_x | u_r \rangle|^2}{(E_c - E_r)}, \quad (2.5)$$

where  $\langle S | p_x | u_r \rangle$  is the momentum matrix element between the  $s$ -like conduction bands and remote bands  $r$ , and  $m_0$  is the free electron mass.

The second-order valence-band terms include those with possible intermediate  $r$  states that belong to energetically higher bands with the symmetry of  $s(\Gamma_1)$ ,  $p(\Gamma_{12})$ , and  $d(\Gamma_{15})$  atomic orbitals.<sup>26</sup> We define the following quantities in terms of matrix elements between  $p$ -like valence bands (whose symmetry here and in the following is indicated as  $X$ ,  $Y$ ,  $Z$ ) and remote bands:

$$\sigma = - \left( \frac{1}{3m_0} \right) \sum_r^{\Gamma_1} \frac{|\langle X | p_x | u_r \rangle|^2}{(E_v - E_r)}, \quad (2.6)$$

$$\pi = - \left( \frac{1}{3m_0} \right) \sum_r^{\Gamma_{15}} \frac{|\langle X | p_y | u_r \rangle|^2}{(E_v - E_r)}, \quad (2.7)$$

and

$$\delta = - \left( \frac{1}{6m_0} \right) \sum_r^{\Gamma_{12}} \frac{|\langle X | p_x | u_r \rangle|^2}{(E_v - E_r)}. \quad (2.8)$$

If the conduction-band states were not included into our analysis explicitly, the additional contribution of the nearby  $c$  bands would enter the sum over intermediate states in the second-order perturbation theory for the  $\sigma$  parameter. We denote this revised value as  $\sigma^L$ :

$$\sigma^L = \sigma - \left( \frac{1}{3m_0} \right) \sum_c^{\Gamma_1} \frac{|\langle X | p_x | S \rangle|^2}{(E_v - E_c)} = \sigma + \frac{E_P}{6E_g}. \quad (2.9)$$

Now, the  $\sigma^L$ ,  $\delta$ , and  $\pi$  parameter set is simply related to the standard definitions of the Luttinger parameters  $\gamma_1$ ,  $\gamma_2$ , and  $\gamma_3$ :

$$\begin{aligned} \gamma_1 &= -1 + 2\sigma^L + 4\pi + 4\delta, \\ \gamma_2 &= \sigma^L - \pi + 2\delta, \\ \gamma_3 &= \sigma^L + \pi - \delta. \end{aligned} \quad (2.10)$$

All of the terms appearing in the valence-band Hamiltonian may be cast in terms of the three quantities  $\sigma$ ,  $\delta$ , and  $\pi$ , or equivalently in terms of the Luttinger parameters.

The inclusion of electron spin and spin-orbit interaction effects are straightforward,<sup>23</sup> and we obtain a  $6 \times 6$  valence-band Hamiltonian. The matrix elements of the spin-orbit interaction, with  $\boldsymbol{\sigma}$  being the Pauli spin matrices here

$$H_{so} = \frac{\hbar}{4m_0^2 c^2} \Delta V \times \mathbf{p} \cdot \boldsymbol{\sigma}, \quad (2.11)$$

are parameterized by the quantity called the spin-orbit splitting

$$\Delta_{so} = \frac{3\hbar i}{4m_0^2 c^2} \langle X | \frac{\partial V}{\partial x} p_y - \frac{\partial V}{\partial y} p_x | Y \rangle. \quad (2.12)$$

The atomic potential  $V$  appears in the above expressions. The spin-orbit interaction splits the sixfold degeneracy at the zone center into fourfold degenerate heavy-hole (hh) plus light-hole (lh) bands of  $\Gamma_8$  symmetry with total angular momentum  $J=3/2$ , and a doubly degenerate split-off (so) band of  $\Gamma_7$  symmetry with  $J=1/2$ . In practice, the values of the  $\Delta_{so}$  parameter are determined experimentally.

For a bulk system, the eight-band  $\mathbf{k} \cdot \mathbf{P}$  model gives rise to eight coupled differential equations, which define the Schrödinger eigenvalue problem for the energy bands near the center of the BZ. With the envelope functions represented by  $e^{\pm i\mathbf{k} \cdot \mathbf{r}}$ , we have the usual  $8 \times 8$  Hamiltonian with terms linear and quadratic in  $\mathbf{k}$ . In a bulk semiconductor, both direct and indirect energy gaps in semiconductor materials are temperature-dependent quantities, with the functional form often fitted to the empirical Varshni form<sup>27</sup>

$$E_g(T) = E_g(T=0) - \frac{\alpha T^2}{T + \beta}, \quad (2.13)$$

where  $\alpha$  and  $\beta$  are adjustable (Varshni) parameters. Although other, more physically justified and possibly quantitatively accurate, functional forms have been proposed,<sup>28,29</sup>



they have yet to gain widespread acceptance. In this article, we compile consistent sets of Varshni parameters for all materials.

The effective mass  $m^*$  at the conduction and valence band edges can be obtained from the bulk energy dispersion  $\Omega(k)$  as<sup>30</sup>

$$\left. \frac{\partial^2}{\partial k^2} \Omega(k) \right|_{\substack{k=0 \\ E=E_n}} = \frac{\hbar^2}{m^*}. \quad (2.14)$$

Using this procedure, the conduction band effective mass is given in terms of the band parameters

$$\frac{m_0}{m_e^*} = (1 + 2F) + \frac{E_P(E_g + 2\Delta_{so}/3)}{E_g(E_g + \Delta_{so})}. \quad (2.15)$$

Both  $E_P$  [defined in Eq. (2.4)] and  $F$  [Eq. (2.5)] appearing in Eq. (2.15) are usually taken to be independent of temperature, which means that the temperature variation of the effective mass arises only through the temperature dependences of the energy gaps as in Eq. (2.13). Unfortunately, despite their importance  $E_P$  and  $F$  are inherently difficult to determine accurately, since the remote-band effects can be calculated but not directly measured. One alternative experimental technique is to rely on measuring the effective  $g$  factor, which is not as influenced by remote bands as the effective mass. In this article, we derive consistent sets of  $F$  parameters from the best available experimental reports of electron effective masses, energy gaps, spin-orbit splittings, and momentum matrix elements. There has been no previous attempt to compile reliable, self-consistent  $F$  parameters for such a broad range of materials.

In polar semiconductors such as the III–V compounds, it is the nonresonant polaron<sup>31</sup> mass that is actually measured. That quantity exceeds the bare electron mass by 1%–2%, depending on the strength of the electron–phonon interaction. However, since the band structure is governed by the bare electron mass, we attempt to present the latter value and note the approximate magnitude of the polaronic correction whenever the information is available.

At the valence-band edge, the hh effective masses in the different crystallographic directions are given by the relations

$$\begin{aligned} \left( \frac{m_0}{m_{hh}^*} \right)^z &= \gamma_1 - 2\gamma_2; \\ \left( \frac{m_0}{m_{hh}^*} \right)^{[110]} &= \frac{1}{2}(2\gamma_1 - \gamma_2 - 3\gamma_3); \\ \left( \frac{m_0}{m_{hh}^*} \right)^{[111]} &= \gamma_1 - 2\gamma_3. \end{aligned} \quad (2.16)$$

These expressions show the relationship of the Luttinger parameters, which are not as physically meaningful but more convenient to work with theoretically, to the hh effective masses that can typically be measured in a more direct manner. The lh and so hole effective masses are given by

$$\begin{aligned} \left( \frac{m_0}{m_{lh}^*} \right)^z &= \gamma_1 + 2\gamma_2, \\ \left( \frac{m_0}{m_{lh}^*} \right)^{[110]} &= \frac{1}{2}(2\gamma_1 + \gamma_2 + 3\gamma_3), \\ \left( \frac{m_0}{m_{lh}^*} \right)^{[111]} &= \gamma_1 + 2\gamma_3 \end{aligned} \quad (2.17)$$

and

$$\frac{m_0}{m_{so}^*} = \gamma_1 - \frac{E_P \Delta_{so}}{3E_g(E_g + \Delta_{so})}. \quad (2.18)$$

Equation (2.18), which relates the split-off hole mass to the Luttinger parameters, should in principle contain an additional parameter to account for the effects of remote bands (analogous to  $F$ ). However, those remote bands are not necessarily the same ones that produce the largest correction to the electron mass. At present, not enough data exist for any of the III–V materials to fix the effect of the interaction with remote bands on the split-off hole mass.

In any theoretical model, being able to reproduce the correct effective masses at the center of the BZ ensures that the curvature of the energy bands is properly reproduced. In the context of heterostructures, using incorrect effective masses could lead to severe deviations from experiment, e.g., in the bound state spectrum of a quantum well. For thin-layer quantum structures, it is also important to have a good model for the nonparabolic dispersion away from the center of the BZ. The eight-band  $\mathbf{k} \cdot \mathbf{P}$  model compares well with more rigorous calculations up to about a quarter of the way to the BZ boundary, and extra bands may be included in order to improve the agreement.<sup>32,33</sup> As an illustration, we show in Fig. 1(a) the full-zone band structure in the vicinity of the energy gap obtained for GaAs using the pseudopotential method (see Sec. II B 3). Note the anticrossing of the conduction band with a higher band along the  $\Gamma$ – $X$  direction, which sets one limit on the accuracy of perturbative approaches. A more detailed plot of the band structure near the BZ center in GaAs is given in Fig. 1(b).

The filled points in Fig. 2 show  $\Gamma$ -valley energy gaps as a function of lattice constant for zinc blende forms of the 12 binary III–V semiconductors reviewed in this work. The connecting curves represent band gaps for the random ternary alloys, although in a few cases (e.g., GaAsN and InPN) the extrapolated dependences extend well beyond the regions that are reliably characterized. We also emphasize that the  $\Gamma$ -valley direct gap is not necessarily the smallest, since several of the materials are indirect-gap semiconductors in which the  $X$  and  $L$  conduction-band valleys lie lower than the  $\Gamma$  minimum. For the non-nitride III–Vs, Fig. 3 shows a similar plot of the lowest forbidden gap in each material, with  $X$ -valley and  $L$ -valley indirect gaps indicated by the dashed and dotted lines, respectively.

## 2. Nitrides with wurtzite structure

The wurtzite crystal consists of two interpenetrating hexagonal close-packed lattices, one having a group-III element atom (e.g., Ga) and the other a group-V element atom (e.g.,

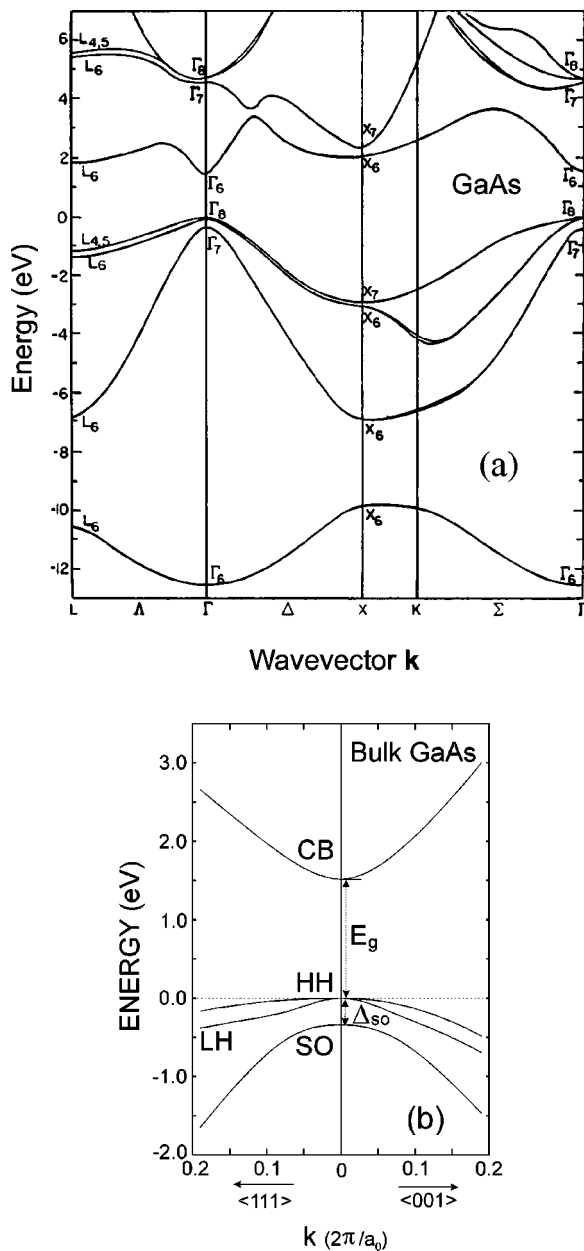


FIG. 1. Diagram of the band structure in the vicinity of the energy gap of GaAs: (a) throughout the first Brillouin zone (reproduced with permission from Ref. 81), (b) a magnified view near the zone center.

N). A wurtzite crystal is characterized by two lattice constants  $a_{lc}$  and  $c_{lc}$ . A major difference between zinc blende and wurtzite structures is that the in-plane behavior of the bands in a wurtzite crystal is different from the behavior along the  $[0001]$  axis (the  $c$  axis). The  $\Gamma_{1c}$  conduction bands are  $s$  like at the center of the BZ, while the valence bands belong to the  $\{\Gamma_{6v}:\{X,Y\}+\Gamma_{1v}:\{Z\}\}$  representations. The nearest higher-order conduction bands belong to the  $\Gamma_{6c}$  states of  $\{X,Y\}$  symmetry and the  $\Gamma_{3c}$  states transforming like the  $\{Z\}$  representation.

Due to the anisotropy of the crystal, there are two distinct interband matrix elements arising from the  $\Gamma_{6v}:\{X,Y\}$  and  $\Gamma_{1v}:\{Z\}$  representations, defined by analogy with Eq. (2.3). These are in practice derived from the anisotropic effective mass using expressions similar to Eq. (2.15) (assum-

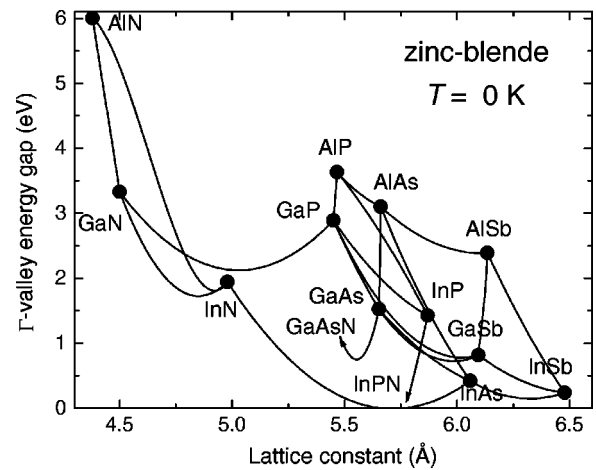


FIG. 2. Direct  $\Gamma$ -valley energy gap as a function of lattice constant for the zinc blende form of 12 III-V binary compound semiconductors (points) and some of their random ternary alloys (curves) at zero temperature. The energy gaps for certain ternaries such as AlAsP, InAsN, GaAsN, InPN, and GaPN are extended into regions where no experimental data have been reported. For GaAsN and InPN, the arrows indicate the boundaries of the regions where the gap dependence on composition may be predicted with any accuracy.

ing negligible crystal-field and spin-orbit splittings). Although the different conduction-band energy contributions from the higher  $\Gamma_{6c}=\{X,Y\}$  and  $\Gamma_{3c}=\{Z\}$  intermediate states lead to two distinct  $F$  parameters, no experiments that would enable us to establish independent values for the latter have been reported. The compilations in the following sections take the  $F$  parameters in the wurtzite nitrides to be zero.

The second-order valence-band terms in the Hamiltonian are evaluated in a manner similar to the earlier discussion for zinc blende structures. The procedure leads to six distinct  $A$  parameters, which are to a large extent analogous to the Luttinger parameters in zinc blende materials. The detailed definitions have appeared in the literature.<sup>34–38</sup>

In contrast to the zinc blende materials, the wurtzite structure does not give a triply degenerate valence band

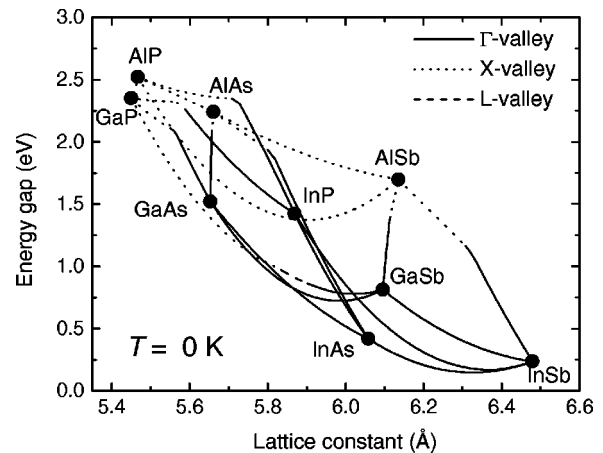


FIG. 3. Lowest forbidden gap as a function of lattice constant for non-nitride III-V compound semiconductors (points) and their random ternary alloys (lines) at zero temperature. The materials with  $\Gamma$ -,  $X$ -, and  $L$ -valley gaps are indicated by solid, dotted, and dashed lines, respectively.

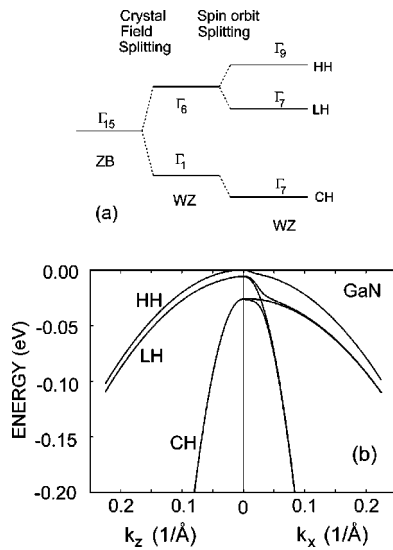


FIG. 4. (a) Schematic illustration of the spin-orbit splitting and crystal-field splitting in wurtzite materials as compared to zinc blende materials. (b) Schematic diagram of the valence band structure of a wurtzite material near the zone center with the heavy-hole (HH), light-hole (LH), and crystal-hole (CH) valence bands explicitly identified.

edge. The crystal-field splitting leads to the band-edge energies:

$$\langle X|H_{\text{cr}}|X\rangle = \langle Y|H_{\text{cr}}|Y\rangle = E_v + \Delta_1, \quad (2.19)$$

and

$$\langle Z|H_{\text{cr}}|Z\rangle = E_v. \quad (2.20)$$

The spin-orbit splitting is parameterized by the relations

$$\langle X|H_{(\text{so})z}|Y\rangle = -i\Delta_2, \quad (2.21)$$

and

$$\langle Y|H_{(\text{so})x}|Z\rangle = \langle Z|H_{(\text{so})y}|X\rangle = -i\Delta_3. \quad (2.22)$$

Although in principle, two different spin-orbit splitting parameters arise, they are commonly assumed equal ( $\Delta_2 = \Delta_3$ ). However, the crystal-field splitting ( $\Delta_1$ ) is in general not related to the spin-orbit splitting. The  $\Delta_{\text{cr}} = \Delta_1$  and  $\Delta_{\text{so}} = 3\Delta_2$  parameters are tabulated for wurtzite materials in the following sections. The definition of the spin-orbit and crystal-field splitting in the wurtzite materials is further illustrated in Fig. 4(a). A typical valence band structure for a wurtzite material is shown in Fig. 4(b).

### 3. Strain in heterostructures

To model the strain in a pseudomorphically grown heterostructure such as a quantum well, quantum wire, or quantum dot, the elastic continuum theory is usually invoked. In elastic continuum theory, the atomic displacements are represented by a local vector field,  $\mathbf{r}' - \mathbf{r} = \mathbf{u}(\mathbf{r})$ . Ignoring the quadratic term for small deformations, we define the local strain tensor  $\varepsilon_{ij}$  via  $u_i(\mathbf{r}) = \varepsilon_{ij}r_j$ .<sup>39,40</sup> The stress tensor  $\sigma_{ij}$  that generates the above strain is given by the relation  $\sigma_{ij} = \lambda_{ijkl}\varepsilon_{kl}$ . In crystals with cubic symmetry, there are only three linearly independent constants:  $\lambda_{xxxx} = C_{11}$ ,  $\lambda_{xxyy} = C_{12}$ ,  $\lambda_{xyxy} = C_{44}$ . For the wurtzite structure, there are five linearly independent elastic constants  $\lambda_{xxxx} = C_{11}$ ,  $\lambda_{zzzz}$

$= C_{33}$ ,  $\lambda_{xxyy} = C_{12}$ ,  $\lambda_{xxzz} = C_{13}$ ,  $\lambda_{xzzx} = C_{44}$ . The values for the elastic constants will be included in our compilation of the band parameters for completeness. Note that, at least for the non-nitride materials, there is little controversy regarding their values, and the datasets given below are widely accepted.

The physical deformation of the crystal leads to a distortion of the atomic locations, which in turn affects the energy levels of the band electrons.<sup>14</sup> The procedure for generating additional terms due to the presence of the strain has been described in detail by Bir and Pikus<sup>14</sup> and Bahder.<sup>41</sup> In the case of hydrostatic compression, the change in the conduction-band-edge energy  $\Delta E_c$  due to the relative change in volume  $\Delta V/V = (\varepsilon_{xx} + \varepsilon_{yy} + \varepsilon_{zz})$  can be parametrized by a linear relation between the change in energy and the hydrostatic strain. The constant of proportionality is the empirical deformation potential constant  $a_c$ . Unfortunately, this parameter is difficult to isolate experimentally. Instead it is the deformation potential constant  $a$ , associated with the change in band gap  $E_g$  due to a hydrostatic deformation, that is measured. Due to the nature of the atomic bonding in III–V materials, the band gap increases for a compressive strain. Under positive hydrostatic pressure, i.e., negative strain, the change in energy  $\Delta E_g = a(\varepsilon_{xx} + \varepsilon_{yy} + \varepsilon_{zz})$  must be positive. This implies a negative value for  $a \equiv a_c + a_v$ . Note that our sign convention for  $a_v$  is different from many other works found in the literature. It is generally believed that the conduction band edge moves upward in energy while the valence band moves downward, with most of the change being in the conduction band edge, although Wei and Zunger recently argued that this is not always the case.<sup>42</sup> The distribution of the hydrostatic pressure shift between the conduction and valence bands is generally based from theoretical predictions in this review.

From the Bir–Pikus strain interaction for the valence bands,<sup>14</sup> it may be observed that the single deformation potential  $a_v$ , which parameterizes the shift of the valence-band edge  $\Delta E_v = a_v(\varepsilon_{xx} + \varepsilon_{yy} + \varepsilon_{zz})$ , is insufficient to describe the full effect of strain. Two additional potentials  $b$  and  $d$  are necessary to describe the shear deformations terms that split the heavy/light-hole degeneracy. For the growth of pseudomorphic layers along the [001] direction, only the value of the potential  $b$  is relevant. All of the deformation potentials are tabulated for each material in the sections that follow. For the  $6 \times 6$  valence-band strain Hamiltonian that is not reproduced here, the reader is referred to the textbooks by Bir and Pikus<sup>14</sup> and by Chuang.<sup>43</sup>

The preceding discussion applies to the zinc blende crystal structure. In a wurtzite material, the crystal anisotropy leads to two distinct conduction-band deformation potentials. Furthermore, six deformation potential constants  $D_i$  arise from a full treatment of the effect of strain on the six-band valence-band structure as shown by Bir and Pikus.<sup>14</sup> These  $D_i$  are tabulated for each nitride material in the following sections.

### 4. Piezoelectric effect in III–V semiconductors

Under an externally applied stress, III–V semiconductors develop an electric moment whose magnitude is propor-

tional to the stress.<sup>44,45</sup> The strain-induced polarization  $\mathbf{P}^s$  can be related to the strain tensor  $\varepsilon_{ij}$  using piezoelectric coefficients  $e_{ijk}$  of the form

$$P_i^s = e_{ijk} \varepsilon_{jk}. \quad (2.23)$$

The symmetry of the strain under interchange of its indices allows us to write  $e_{ijk}$  in a more compact form. Converting from the tensor notation to the matrix notation we write

$$\{\varepsilon_{11}, \varepsilon_{22}, \varepsilon_{33}, (\varepsilon_{23}, \varepsilon_{32}), (\varepsilon_{31}, \varepsilon_{13}), (\varepsilon_{12}, \varepsilon_{21})\} \\ \equiv \{\varepsilon_1, \varepsilon_2, \varepsilon_3, \varepsilon_4, \varepsilon_5, \varepsilon_6\}, \quad (2.24)$$

and

$$e_{ijk} = \begin{cases} e_{im}, & (i=1,2,3; m=1,2,3); \\ \frac{1}{2} e_{im}, & (i=1,2,3; m=4,5,6), \end{cases} \quad (2.25)$$

where it is standard practice to introduce the factor of 1/2 in front of the  $e_{im}$  for  $m=4,5,6$  in order to obtain the following form without factors of 1/2:

$$P_i^s = e_{i1}\varepsilon_1 + e_{i2}\varepsilon_2 + e_{i3}\varepsilon_3 + e_{i4}\varepsilon_4 + e_{i5}\varepsilon_5 + e_{i6}\varepsilon_6. \quad (2.26)$$

In the zinc blende materials, only off-diagonal terms in the strain give rise to the electric polarization components  $P_i^s$  and

$$P_i^s = e_{i4}\varepsilon_{jk}, \quad j \neq k, \quad (2.27)$$

where  $e_{i4}$  is the one independent piezoelectric coefficient that survives due to the zinc blende symmetry. The piezoelectric effect is negligible unless the epitaxial structure is grown along a less common direction such as [111].

On the other hand, in a wurtzite crystal, the three distinct piezoelectric coefficients are  $e_{31}=e_{32}$ ,  $e_{33}$ , and  $e_{15}=e_{24}$  can be derived from symmetry considerations. The piezoelectric polarization is given in component form by

$$\begin{aligned} P_x^s &= e_{15}\varepsilon_{13}, \\ P_y^s &= e_{15}\varepsilon_{12}, \\ P_z^s &= e_{31}\varepsilon_{11} + e_{31}\varepsilon_{22} + e_{33}\varepsilon_{33}. \end{aligned} \quad (2.28)$$

where we have reverted to the tensor form for the strains  $\varepsilon_{ij}$ . Thus both diagonal and off-diagonal strain components can generate strong built-in fields in wurtzite materials that must be taken into account in any realistic band structure calculation. The piezoelectric contribution to the total polarization may be specified alternatively in terms of matrix  $\mathbf{d}$  related to matrix  $\mathbf{e}$  via the elastic constants

$$P_i = \sum_j e_{ij} \varepsilon_j, \quad (2.29)$$

$$P_i = \sum_k d_{ik} \sigma_k = \sum_j \sum_k d_{ik} c_{kj} \varepsilon_j,$$

where  $\varepsilon_j$  and  $\sigma_k$  are the components of the strain and stress tensors in simplified notation [see Eq. (2.24)], respectively.

The nitrides also exhibit spontaneous polarization, with polarity specified by the terminating anion or cation at the layer surface. Further details are available from recent publications<sup>46,47</sup> and reviews.<sup>48,49</sup> In the sections that follow,

we tabulate both piezoelectric coefficients and spontaneous polarizations for the wurtzite nitride materials.

## 5. Band structure in layered heterostructures

So far we have considered the band parameters of individual materials in the presence of strain. The misalignment of energy band gaps in adjacent layers of a quantum heterostructure is taken into account by specifying a reference layer and defining a band offset function relative to it. In general, this potential energy is given as a function  $V_P(z)$  of the coordinate in the growth direction and defines the band edge profile for the top of the valence band. With  $V_P(z)=0$  in the reference layer, the conduction band edge profile is  $V_C(z) = E_g(z) - E_g(\text{ref}) + V_P(z)$ . Valence band offsets have been determined experimentally by optical spectroscopy of quantum well structures, x-ray photoelectron spectroscopy, electrical capacitance measurements, and other techniques. On the theoretical side, this is supplemented by pseudopotential supercell calculations that include atomic layers on either side of a heterointerface. A critical review of valence band offset determinations was given by Yu, McCaldin, and McGill.<sup>50</sup> In Sec. VII we will provide an updated review of the valence band offsets in zinc blende and wurtzite materials, putting the main emphasis on the compilation of a fully consistent set of band offsets.

The coupled Schrödinger differential equations for a layered heterostructure may be solved using the finite-difference method,<sup>51,52</sup> the transfer matrix method,<sup>53–56</sup> or the finite element method,<sup>57–59</sup> which is a variational approach that may be considered a discretization of the action integral itself. Further details are available from the references cited above.

The  $\mathbf{k}\cdot\mathbf{P}$  model has also been extended to include the intrinsic inversion asymmetry of the zinc blende structure,<sup>60–63</sup> and, more phenomenologically, to include the effects of  $\Gamma$  and  $X_z$  valley mixing in order to include such effects in modeling resonant double-barrier tunneling.<sup>64–69</sup> These parameterizations are beyond the framework of the considerations presented here.

## B. Relation of $\mathbf{k}\cdot\mathbf{P}$ to other band structure models

The  $\mathbf{k}\cdot\mathbf{P}$  model is the most economical in terms of assuring agreement with the observed bulk energy band gaps and effective masses at the center of the BZ. However, for a more complete picture of the energy bands throughout the BZ, it is necessary to adopt another approach that requires additional information as input.

### 1. Empirical tight binding model

In the empirical tight-binding model (ETBM) introduced by Slater and Koster,<sup>70</sup> the electronic states are considered to be linear combinations of atomic ( $s, p, d, \dots$ ) orbitals. The Hamiltonian's matrix elements between the atomic orbital states are not evaluated directly, but are instead introduced as free parameters to be determined by fitting the band gaps and band curvatures (effective masses) at critical points in the BZ. Depending on the number of orbitals and nearest neighbors used to represent the states, the ETBM requires that the overlap integrals be determined in terms of the measured direct and indirect band gaps and/or effective masses in the



bulk material.<sup>71,72</sup> For example, the  $sp^3s^*$  basis with the second-nearest-neighbor scheme<sup>72</sup> turns out to have 27 parameters for the zinc blende lattice structure, and the energies and effective masses obtained from the diagonalization of the Hamiltonian and the resulting energy bands are nonlinear functions of these parameters, which can be fitted by trial and error or using, e.g., genetic algorithms.<sup>73</sup> The lack of a transparent relationship between the input parameters and the experimentally determined quantities is probably the single greatest disadvantage of the tight-binding method in making complicated band structure calculations. In this review, we make no attempt to give a standardized set of tight-binding parameters. The ETBM can also be applied to superlattice band structure calculations.<sup>17,74,75</sup>

## 2. Effective bond orbital model

While the inclusion of additional bands and overlaps of higher orbitals is a possible approach to improving the tight-binding modeling of energy bands in bulk semiconductors, the effective bond orbital model<sup>76–78</sup> (EBOM) uses spin-doubled  $s, p_x, p_y, p_z$  orbitals to generate an  $8 \times 8$  Hamiltonian. A crucial difference between the EBOM and related tight-binding formulations is that the  $s$  and  $p$  orbitals are centered on the face-centered cubic lattice sites of the zinc blende crystal rather than on both of the two real atoms per lattice site. The resulting somewhat *ad hoc* formulation offers considerable computational savings in comparison with the ETBM. However, the main significance of the EBOM approach derives from the fact that the resulting secular matrix has a small- $\mathbf{k}$  expansion that exactly reproduces the form of the eight-band  $\mathbf{k} \cdot \mathbf{P}$  Hamiltonian. This allows the EBOM input parameters to be readily expressed in terms of the experimentally measured parameters, such as the band gap, the split-off gap, and the zone-center mass of each band, which has not been accomplished using the more involved ETBM. In fact, the EBOM can be thought of as an extension of the  $\mathbf{k} \cdot \mathbf{P}$  method to provide an approximate representation of the energy bands over the full BZ. Since short-period superlattice bands sample wavevectors throughout the BZ, we may expect the EBOM to be more accurate than the  $\mathbf{k} \cdot \mathbf{P}$  model for thin-layer structures. However, the EBOM is considerably less efficient computationally than  $\mathbf{k} \cdot \mathbf{P}$ , especially for thicker superlattices. Each lattice position must be represented in the supercell technique, i.e., no envelope function approximation is made.

## 3. Empirical pseudopotential model

The influence of core electrons in keeping the valence electrons outside of the core may be represented by an effective repulsive potential in the core region. When this is added to the attractive ionic potential, the net “pseudopotential” nearly cancels<sup>79,80</sup> at short distances. The valence states are orthogonal to the core states, and the resulting band structure theory corresponds to the nearly free-electron model. In the empirical pseudopotential model, the crystal potential is represented by a linear superposition of atomic potentials, which are modified to obtain good fits to the experimental direct and indirect band gaps and effective masses. Further details

are presented by Cohen and Chelikowsky<sup>81</sup> and in the reviews by Heine and Cohen.<sup>82,83</sup> *Ab initio* approaches employ calculated band parameters (e.g., from the density-functional theory) in lieu of experimental data. Combinations of *ab initio* and empirical methods have been developed to a high level of sophistication.<sup>84</sup> Extension of the pseudopotential method to heterostructures entails the construction of a supercell to assure the proper periodic boundary conditions. With atomic potentials as the essential input, the electronic properties of the heterostructure can be determined, although the required computational effort far exceeds the demands of the  $\mathbf{k} \cdot \mathbf{P}$  method. The relative merits of the  $\mathbf{k} \cdot \mathbf{P}$  and pseudopotential approaches have been assessed.<sup>85,86</sup>

## III. BINARY COMPOUNDS

### A. GaAs

GaAs is the most technologically important and the most studied compound semiconductor material.<sup>3</sup> Many band structure parameters for GaAs are known with a greater precision than for any other compound semiconductor. This is especially true of the fundamental energy gap with a value of 1.519 eV at 0 K.<sup>87</sup> The analysis by Thurmond<sup>88</sup> indicated  $\alpha = 0.5405$  meV/K and  $\beta = 204$  K [in Eq. (2.13)]. A more recent examination of a large number of samples by ellipsometry produced a very similar parameter set of  $E_g(T=0) = 1.517$  eV,  $\alpha = 0.55$  meV/K, and  $\beta = 225$  K.<sup>89</sup> The two results are well within the quoted experimental uncertainty of each other and several other experimental determinations,<sup>3,90</sup> although somewhat different parameter sets have been proposed recently on the basis of photoluminescence measurements:  $E_g(T=0) = 1.519$  eV,  $\alpha = 0.895 - 1.06$  meV/K, and  $\beta = 538 - 671$  K.<sup>91,92</sup>

The original controversy<sup>87</sup> about the ordering of the  $L$  and  $X$ -valley minima was resolved by Aspnes,<sup>93</sup> who proposed on the basis of numerous earlier experiments the following sets:  $E_g^L(T=0) = 1.815$  eV,  $\alpha^L = 0.605$  meV/K, and  $E_g^X(T=0) = 1.981$  eV,  $\alpha^X = 0.460$  meV/K with  $\beta = 204$  K in both cases. Schottky-barrier electroreflectance measurements yielded the widely accepted value for the split-off energy gap in GaAs:  $\Delta_{so} = 0.341$  eV.<sup>94</sup>

Electron effective masses of  $m_e^* = 0.0665m_0$  and  $0.0636m_0$  were observed at  $T = 60$  and  $290$  K, respectively, by Stradling and Wood<sup>95</sup> using magnetophonon resonance experiments.<sup>96–98</sup> A low-temperature value of  $0.065m_0$  was determined for the bare electron mass once the polaronic correction was subtracted.<sup>99</sup> While a somewhat larger mass of  $\approx 0.07m_0$  was derived theoretically in several *ab initio* and semiempirical band structure studies,<sup>100–102</sup> recent cyclotron resonance measurements<sup>103</sup> indicate a low-temperature result of  $0.067m_0$  at the band edge. This is the value we adopt following the recommendation of Nakwaski in his comprehensive review,<sup>104</sup> which is based on reports employing a wide variety of different experimental techniques. At room temperature, the currently accepted value is  $0.0635m_0$ , as confirmed, for example, by photoluminescence measurements.<sup>105</sup> We employ the effective masses for the  $L$  and  $X$  valleys given by Adachi<sup>3</sup> and Levinshtein *et al.*,<sup>11</sup> which were compiled from a variety of measurements.

Many different sets of Luttinger parameters are available in the literature.<sup>99</sup> The most popular set:  $\gamma_1=6.85$ ,  $\gamma_2=2.10$ , and  $\gamma_3=2.90$  (also given in Landolt-Bornstein<sup>1</sup>), which was derived by Lawaetz<sup>106</sup> on the basis of five-level (14-band)  $\mathbf{k}\cdot\mathbf{P}$  calculations, is in good agreement with early cyclotron resonance,<sup>107</sup> magnetoreflexion,<sup>108</sup> and magnetoexciton<sup>109</sup> experiments. While two-photon magnetoabsorption measurements<sup>110</sup> indicated very little warping in the valence band, those results are contradicted by optical spectroscopy<sup>111</sup> and Raman scattering<sup>112</sup> studies of GaAs quantum wells as well as by fits to the shallow acceptor spectra.<sup>113,114</sup> Here we prefer a composite data set, which is within the experimental error of all accurate determinations and reproduces well the measured hole masses and warping.<sup>99,104</sup>  $\gamma_1=6.98$ ,  $\gamma_2=2.06$ , and  $\gamma_3=2.93$ .

While its value is usually less critical to the device design and band structure computations, the split-off hole mass in GaAs has also been measured and calculated using a variety of approaches.<sup>106,111</sup> A composite value  $m_{so}^*=0.165m_0$  was derived by Adachi,<sup>3</sup> which is in excellent agreement with the recent calculation by Pfeffer and Zawadzki.<sup>33</sup> However, we will use a slightly different value,  $m_{so}^*=0.172m_0$ , in order to provide self-consistency with the  $\mathbf{k}\cdot\mathbf{P}$  expression in Eq. (2.18).

The first electron-spin-resonance measurements of the interband matrix element in GaAs, which were reported by Chadi *et al.*<sup>115</sup> and Hermann and Weisbuch,<sup>116</sup> yielded  $E_P=28.8\text{--}29.0\text{ eV}$ . However, Shantharama *et al.*<sup>96,117</sup> suggested that those analyses overestimated the influence of remote bands outside of the 14-band  $\mathbf{k}\cdot\mathbf{P}$  model and gave  $E_P=25.0\pm 0.5\text{ eV}$ . Theoretical studies<sup>99,118</sup> have derived intermediate values. Since the analysis by Shantharama *et al.* appears to have internal consistency problems, we adopt the Hermann and Weisbuch value (implying  $F=-1.94$ ), which has been used with some success in the literature to determine the optical gain in GaAs quantum-well lasers.<sup>119</sup>

The greatest uncertainty in the GaAs band structure parameters is associated with the deformation potentials, which are needed to calculate strain effects in pseudomorphically grown layers. In this review, we will consider only deformation potentials for the  $\Gamma$  valley. The total hydrostatic deformation potential  $a$  is proportional to the pressure coefficient of the direct band gap, where the constant of proportionality is approximately the bulk modulus. Some trends in the band gap pressure coefficients were noted by Wei *et al.*<sup>42,120</sup> The experimental hydrostatic pressure dependence of  $E_g$  for GaAs implies a total deformation potential  $a=a_c+a_v\approx -8.5\text{ eV}$ ,<sup>121</sup> where the minus sign represents the fact that the band gap expands when the crystal is compressed (note that our sign convention for  $a_v$  is different from a large number of articles). The conduction-band deformation potential  $a_c$  corresponds to the shift of the conduction band edge with applied strain. Pseudopotential<sup>122</sup> and linear-muffin-tin-orbital<sup>123</sup> calculations yielded  $a_c$  as large as  $-18.3\text{ eV}$ , whereas various analyses of mobility data<sup>3,124</sup> using standard deformation-potential scattering models are consistent with  $a_c$  falling in the range  $-6.3$  to  $-13.5\text{ eV}$ . A recent study of acoustic-phonon scattering in GaAs/AlGaAs quantum wells<sup>125</sup> produced an estimate of  $a_c=-11.5\pm 0.5\text{ eV}$ . On the

other hand, studies of the valence-band deformation potential<sup>3,126,127</sup> suggest a small  $a_v$ . In order to be consistent with the experimental hydrostatic pressure shift, we recommend using the values  $a_c=-7.17\text{ eV}$  and  $a_v=-1.16\text{ eV}$ , which were derived from the “model-solid” formalism by Van de Walle.<sup>129</sup> However, the first-principles calculations of Wei and Zunger<sup>42</sup> show that the energy of the valence-band maximum increases as the unit cell volume decreases for a number of III-V semiconductors including GaAs, GaP, GaSb, InP, InAs, and InSb, whereas it has the opposite sign in other materials. Whatever the direction of the valence-band maximum, it is generally agreed that the conduction band moves much faster with pressure. Heterolayer band-structure calculations are relatively insensitive to the value of  $a_v$  when it is close to zero.

The shear deformation potentials  $b$  and  $d$  have been determined both experimentally and theoretically.<sup>3,121,126,128–131</sup> Moreover, a ratio of the deformation potentials  $d/b=2.4\pm 0.1$  was recently derived from studies of acceptor-bound excitons in biaxially and uniaxially strained GaAs epilayers.<sup>132</sup> The various values for the deformation potential  $b$  varied between  $-1.66$  and  $-3.9\text{ eV}$ , although recent results tend toward the lower end of that range. We propose the following composite values:  $b=-2.0\text{ eV}$  and  $d=-4.8\text{ eV}$ , which are consistent with the vast majority of measurements and several calculations.

All of the recommended parameters for GaAs are compiled in Table I.

## B. AlAs

Because of its frequent incorporation into GaAs-based heterostructures, AlAs is also one of the most important electronic and optoelectronic materials.<sup>3,6,8</sup> Unlike GaAs, AlAs is an indirect-gap semiconductor with the  $X-L-\Gamma$  ordering of the conduction valley minima. The  $X$ -valley minimum is located at a wave vector  $k=(0.903,0,0)$ . The exciton energies corresponding to the  $\Gamma$ -valley energy gap were measured by Monemar<sup>133</sup> to be 3.13 and 3.03 eV at 4 and 300 K, respectively. A small ( $\approx 10\text{ meV}$ ) correction for the exciton binding energy is presumably necessary.<sup>134</sup> Similar values were obtained by Onton,<sup>135</sup> Garriga *et al.*,<sup>136</sup> and Dumke *et al.*<sup>137</sup> Since direct measurements on AlAs are difficult owing to its rapid oxidation upon exposure to air, we choose parameters that are consistent with the more readily available data on the AlGaAs alloy discussed in detail below as well as with the foregoing measurements on bulk AlAs. The temperature dependence of the direct energy gap, which is similar to that for GaAs, was given in an extrapolated form by Logothetidis *et al.*,<sup>138</sup> although better agreement with the results of Monemar<sup>133</sup> can be obtained by increasing  $\beta$  to 530 K.

The low-temperature  $X-\Gamma$  indirect gap in AlAs was measured to be  $\approx 2.23\text{--}2.25\text{ eV}$ .<sup>133,137,139</sup> We suggest the following temperature-dependence parameters, which are somewhat different from the empirical suggestion of Guzzi *et al.*,<sup>139</sup> but are more consistent with the experimental results of Monemar:<sup>133</sup>  $\alpha=0.70\text{ meV/K}$  and  $\beta=530\text{ K}$ . Not many data are available on the temperature variation of the  $L-\Gamma$  gap, although it should be similar to that in GaAs. At

TABLE I. Band structure parameters for GaAs.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$5.65325 + 3.88 \times 10^{-5}(T - 300)$	
$E_g^\Gamma$ (eV)	1.519	1.420–1.435 (300 K)
$\alpha(\Gamma)$ (meV/K)	0.5405	0.51–1.06
$\beta(\Gamma)$ (K)	204	190–671
$E_g^X$ (eV)	1.981	...
$\alpha(X)$ (meV/K)	0.460	...
$\beta(X)$ (K)	204	...
$E_g^L$ (eV)	1.815	...
$\alpha(L)$ (meV/K)	0.605	...
$\beta(L)$ (K)	204	...
$\Delta_{so}$ (eV)	0.341	0.32–0.36
$m_e^*$ ( $\Gamma$ )	0.067	0.065–0.07 (0 K), 0.0635–0.067 (300 K)
$m^*(L)$	1.9	...
$m_t^*(L)$	0.0754	...
$m_{DOS}^*(L)$	0.56	...
$m_l^*(X)$	1.3	...
$m_t^*(X)$	0.23	...
$m_{DOS}^*(X)$	0.85	...
$\gamma_1$	6.98	6.79–7.20
$\gamma_2$	2.06	1.9–2.88
$\gamma_3$	2.93	2.681–3.05
$m_{so}^*$	0.172	0.133–0.388
$E_P$ (eV)	28.8	25.5–29.0
$F$	−1.94	0.76–(−2)
VBO (eV)	−0.80	
$a_c$ (eV)	−7.17	−6.3–(−18.3)
$a_v$ (eV)	−1.16	−0.2–(−2.1)
$b$ (eV)	−2.0	−1.66–(−3.9)
$d$ (eV)	−4.8	−2.7–(−6.0)
$c_{11}$ (GPa)	1221	...
$c_{12}$ (GPa)	566	...
$c_{44}$ (GPa)	600	...

room temperature, a gap of  $\approx 2.35$  eV is generally adopted.<sup>2,3,140,141</sup> A split-off gap of 0.275 eV was measured by Onton,<sup>135</sup> although the extrapolations by Aubel *et al.*<sup>142</sup> and Wrobel *et al.*<sup>143</sup> indicated higher values.

The  $\Gamma$ -valley electron effective mass in AlAs is difficult to determine for the same reasons that the band gaps are uncertain, and also because, in contrast to GaAs, it is impossible to maintain a  $\Gamma$ -valley electron population in thermal equilibrium. Various calculations and measurements have been compiled by Adachi<sup>3</sup> and Nakwaski.<sup>104</sup> As pointed out by Adachi, the indirect determinations<sup>144,145</sup> employing resonant tunneling diodes with AlAs barriers give an effective mass comparable to that in GaAs, but are less trustworthy than the extrapolations from AlGaAs<sup>146,147</sup> and theoretical calculations<sup>100,148</sup> which indicate  $m_e^* = 0.15m_0$ . A slightly lower value of  $0.124m_0$  was inferred from a fit to absorption data.<sup>137</sup>

Electron effective masses for the  $X$  valley with an ellipsoidal constant-energy surface were calculated using the pseudopotential method,<sup>148</sup> and measured by Faraday rotation<sup>149</sup> and cyclotron resonance.<sup>104,150</sup> The former experiment in fact measured only the ratio between the longitudinal and transverse masses (of 5.7), and there is some evidence that the assumed value for  $m_l$  was inconsistent with other data.<sup>104,151</sup> For reasons that are discussed in some detail by Nakwaski,<sup>104</sup> it appears that the recent results by Goiran

*et al.*<sup>152</sup> represent the most reliable values available at present. For the longitudinal and transverse effective masses of the  $L$  valley, we employ the calculated results of Hess *et al.*<sup>148</sup>

The band edge hole masses in AlAs are also not known with a great degree of precision. Both theoretical<sup>106,148</sup> and experimental<sup>111</sup> sets of Luttinger parameters have been published. Unfortunately, the latter was obtained from a fit to measurements on GaAs/AlGaAs quantum wells, which had only limited sensitivity to the AlAs parameters. However, the agreement between different calculations of the hole masses is rather good. We propose a composite Luttinger parameter set based on an averaging of the heavy-hole and light-hole masses from various sources and recommendations by Nakwaski:<sup>104</sup>  $\gamma_1 = 3.76$ ,  $\gamma_2 = 0.82$ , and  $\gamma_3 = 1.42$ . These values are quite similar to the composite parameters suggested by Adachi.<sup>3</sup> For the split-off hole mass, we adopt a value of  $0.28m_0$  for consistency with the  $E_P$  value of 21.1 eV ( $F = -0.48$ ) given by Lawaetz.<sup>106</sup> This mass falls midway between the recommendations by Pavesi and Guzzi<sup>134</sup> and Adachi.<sup>3</sup>

Very few determinations of the electron and hole deformation potentials in AlAs exist. Most of the experimental values are in fact extrapolations from AlGaAs (see below). As for the case of GaAs, we recommend using the values  $a_c = -5.64$  eV and  $a_v = -2.47$  eV derived from the model-

TABLE II. Band structure parameters for AlAs.

Parameters	Recommended values	Range
$a_{\text{lc}}$ (Å)	$5.6611 + 2.90 \times 10^{-5}(T - 300)$	...
$E_g^{\Gamma}$ (eV)	3.099	2.9–3.14
$\alpha(\Gamma)$ (meV/K)	0.885	...
$\beta(\Gamma)$ (K)	530	...
$E_g^X$ (eV)	2.24	2.23–2.25
$\alpha(X)$ (meV/K)	0.70	...
$\beta(X)$ (K)	530	...
$E_g^L$ (eV)	2.46	2.35–2.53
$\alpha(L)$ (meV/K)	0.605	...
$\beta(L)$ (K)	204	...
$\Delta_{\text{so}}$ (eV)	0.28	0.275–0.31
$m_e^*$ ( $\Gamma$ )	0.15	0.06–0.15
$m_l^*(L)$	1.32	...
$m_l^*(L)$	0.15	...
$m_l^*(X)$	0.97	...
$m_l^*(X)$	0.22	...
$\gamma_1$	3.76	3.42–4.04
$\gamma_2$	0.82	0.67–1.23
$\gamma_3$	1.42	1.17–1.57
$m_{\text{so}}^*$	0.28	0.24–0.68
$E_p$ (eV)	21.1	...
$F$	−0.48	...
VBO (eV)	−1.33	...
$a_c$ (eV)	−5.64	0.7–(−5.64)
$a_v$ (eV)	−2.47	−1.2–(−2.6)
$b$ (eV)	−2.3	−1.4–(−3.9)
$d$ (eV)	−3.4	−2.7–(−6.0)
$c_{11}$ (GPa)	1250	...
$c_{12}$ (GPa)	534	...
$c_{44}$ (GPa)	542	...

solid formalism by Van de Walle.<sup>129</sup> For the shear deformation potentials, the following values are suggested:  $b = -2.3$  eV<sup>153</sup> and  $d = -3.4$  eV.<sup>3</sup> The former is supported by ellipsometry measurements of the heavy-light hole exciton splittings in AlGaAs epitaxial layers, whereas further experiments are necessary to confirm the latter.

All of the recommended parameters for AlAs are compiled in Table II.

### C. InAs

InAs has assumed increasing importance in recent years as the electron quantum well material for InAs/GaSb/AlSb-based electronic<sup>154</sup> and long-wavelength optoelectronic<sup>155</sup> devices. The vast majority of experimental low-temperature energy gaps fall in the 0.41–0.42 eV range,<sup>156–159</sup> although somewhat higher values have also been reported.<sup>160,161</sup> We adopt the value 0.417 eV that was obtained from recent measurements on a high-purity InAs sample,<sup>162</sup> in which it was possible to separate shallow impurity, exciton, and band-to-band transitions. The temperature dependence of the band gap has also been reported by several authors.<sup>2,27,163–165</sup> Although there is considerable variation in the proposed Varshni parameters, most of the data agree reasonably well with the values given by Fang *et al.*:<sup>164</sup>  $\alpha = 0.276$  meV/K and  $\beta = 93$  K. Energies for the  $L$  and  $X$  conduction-band minima in InAs have not been studied experimentally. Our recommended values are based on the suggestions by Adachi<sup>166</sup> and Levinshtein *et al.*<sup>11</sup> extrapolated from room temperature

TABLE III. Band structure parameters for InAs.

Parameters	Recommended values	Range
$a_{\text{lc}}$ (Å)	$6.0583 + 2.74 \times 10^{-5}(T - 300)$	...
$E_g^{\Gamma}$ (eV)	0.417	0.410–0.450
$\alpha(\Gamma)$ (meV/K)	0.276	...
$\beta(\Gamma)$ (K)	93	...
$E_g^X$ (eV)	1.433	...
$\alpha(X)$ (meV/K)	0.276	...
$\beta(X)$ (K)	93	...
$E_g^L$ (eV)	1.133	1.13–1.175
$\alpha(L)$ (meV/K)	0.276	...
$\beta(L)$ (K)	93	...
$\Delta_{\text{so}}$ (eV)	0.39	0.37–0.41
$m_e^*$ ( $\Gamma$ )	0.026	0.023–0.03
$m_l^*(L)$	0.64	...
$m_l^*(L)$	0.05	...
$m_{\text{dos}}^*(L)$	0.29	...
$m_l^*(X)$	1.13	...
$m_l^*(X)$	0.16	...
$m_{\text{dos}}^*(X)$	0.64	...
$\gamma_1$	20.0	6.79–7.20
$\gamma_2$	8.5	1.9–2.88
$\gamma_3$	9.2	2.681–3.05
$m_{\text{so}}^*$	0.14	0.09–0.15
$E_p$ (eV)	21.5	21.5–22.2
$F$	−2.90	0–(−2.90)
VBO (eV)	−0.59	...
$a_c$ (eV)	−5.08	−5.08–(−11.7)
$a_v$ (eV)	−1.00	−1.00–(−5.2)
$b$ (eV)	−1.8	−8–(−2.57)
$d$ (eV)	−3.6	...
$c_{11}$ (GPa)	832.9	...
$c_{12}$ (GPa)	452.6	...
$c_{44}$ (GPa)	395.9	...

to 0 K. The temperature dependences of the indirect gaps are taken to be identical to the direct gap, since no determinations appear to be available. The experimental spin-orbit splittings given in Landolt–Bornstein<sup>1</sup> fall in the 0.37–0.41 eV range. We take an average of 0.39 eV, which also agrees well with the more recent experiments of Zverev *et al.*<sup>167</sup>

The electron effective mass in InAs has been determined by magnetophonon resonance, magnetoabsorption, cyclotron resonance, and band structure calculations.<sup>95,104,162,168–179</sup> Owing to the strong conduction-band nonparabolicity in this narrow-gap semiconductor, considerable care must be taken to measure the mass at the band edge rather than at the Fermi level.<sup>180</sup> The majority of results at both low and high temperatures fall between  $0.0215m_0$ <sup>174</sup> and  $0.026m_0$ .<sup>171</sup> Although a few theoretical and experimental studies have obtained low-temperature masses as high as  $0.03m_0$ ,<sup>101,102,104,181</sup> these values were most likely influenced by the strong nonparabolicity. While a value near the bottom of the reported range is usually recommended since the band edge mass represents a lower limit on the measured quantity,<sup>104</sup> many of the results supporting such a mass were in fact performed at room temperature. Since there are almost no credible reports of an effective mass lower than  $0.0215m_0$  at any temperature,<sup>104</sup> our recommended low-temperature value is  $0.026m_0$  which, accounting for the shift of the energy gap, implies  $0.022m_0$  at 300 K. The small (1%) polaronic correction is well within the experimental uncer-



tainty in this case. The density-of-states effective masses for the  $X$  and  $L$  valleys are taken from Levinshtein *et al.*<sup>11</sup> By employing typical experimental  $m_l/m_t$  ratios for related III–V materials (such as GaAs and GaSb) corresponding longitudinal and transverse masses have been estimated and listed in Table III.

Although Luttinger parameters for InAs were determined experimentally by Kanskaya *et al.*,<sup>159</sup> those parameters appear to disagree with the heavy-hole masses for various directions given in the same reference. The values of  $\gamma_1$  and  $\gamma_3$  given in that reference are very close to a previous determination of Pidgeon *et al.*<sup>157</sup> A number of theoretical works<sup>104,106,182</sup> predict a much higher degree of anisotropy in the valence band. Surveying the data available to date, Nakwaski<sup>104</sup> concludes that further experimental work is needed to resolve the matter. Noting the considerable uncertainty involved in this estimate, we suggest the following composite set:  $\gamma_1=20$ ,  $\gamma_2=8.5$ , and  $\gamma_3=9.2$ . Experimental studies<sup>183</sup> have suggested a split-off mass of  $0.14m_0$  in InAs.

The interband matrix element in InAs appears to have been determined relatively accurately owing to the large  $g$  factor in this narrow-gap semiconductor. Whereas early studies suggested a value of 22.2 eV,<sup>106,116</sup> more recently  $E_P=21.5$  eV has gained acceptance.<sup>159,184</sup> We recommend this value, which leads to  $F=-2.90$ . This is somewhat larger than the effect predicted by other workers,<sup>159</sup> which also assumed a smaller low-temperature electron mass ( $0.024m_0$ ).

The hydrostatic deformation potential in InAs was determined to be  $a=-6.0$  eV.<sup>1</sup> We take the conduction and valence-band deformation potentials of Van de Walle,<sup>129</sup> who estimates that most of the energy shift occurs in the conduction band. Somewhat different values were calculated by Blacha *et al.*<sup>122</sup> and Wei and Zunger.<sup>42</sup> The shear deformation potentials adopted from Landolt–Bornstein<sup>1</sup> are in good agreement with the calculations of Blacha *et al.*<sup>122</sup> Another set of deformation potentials has been calculated by Wang *et al.*<sup>86</sup> Unfortunately, at present there exist little experimental data from which to judge the relative merits of the above calculations. All of the recommended parameters for InAs are compiled in Table III.

#### D. GaP

Nitrogen-doped GaP has for a long time been used as the active material for visible light-emitting diodes (LEDs).<sup>185</sup> GaP is the only indirect-gap (with  $X-L-\Gamma$  ordering of the conduction-band minima) binary semiconductor we will consider that does not contain Al. The band structure is somewhat similar to that of AlAs, with the  $X$ -valley minimum at  $k=(0.95,0,0)$ .<sup>5</sup> Indirect  $X-\Gamma$  energy gaps of 2.338–2.350 eV have been reported.<sup>186,187</sup> The main uncertainty in determining the various energy gaps for GaP is that excitonic rather than band-to-band absorption lines typically dominate, so that a calculated exciton binding energy (which presumably has a weak temperature dependence) must be added to the experimental results. The situation is further complicated by the camel's back structure of the  $X$ -valley conduction-band minimum.<sup>187</sup> The most commonly employed Varshni parameters, reported in Casey and Panish,<sup>2</sup> are in excellent

agreement with piezomodulation spectroscopy results by Augvergne *et al.*<sup>188</sup> The  $L$ -valley minimum is located  $\approx 0.37$  eV above the  $X$  valley,<sup>4</sup> although its temperature dependence has not been determined. The low-temperature value for the direct excitonic band gap was found to be 2.86–2.87 eV from absorption measurements.<sup>133,137,189</sup> An exciton binding energy of 20 meV is added to obtain the energy for interband transitions, although the precise value is not well known. GaP has a small spin-orbit splitting of 0.08 eV.<sup>1,189</sup>

The electron effective mass in the  $\Gamma$  valley is estimated from theory to be  $0.09m_0$ ,<sup>11,96</sup> although higher values have also been reported.<sup>101,106</sup> The diamagnetic shifts measured in magnetoluminescence experiments on GaAs<sub>1-x</sub>P<sub>x</sub> alloys with  $x<0.45$ <sup>190</sup> suggest an effective mass of  $\approx 0.13m_0$  for GaP, which is in good agreement with tight-binding calculations by Shen and Fan.<sup>191</sup>

There have been a number of experimental determinations<sup>192</sup> of the  $X$ -valley longitudinal and transverse masses, although the measurements are complicated by the camel's back structure that makes the longitudinal mass highly nonparabolic. This nonparabolicity must be accounted for in any treatment of the density of electron states in GaP, and is in fact more crucial than the precise value of  $m_l$  far above the camel's back. Effective masses of  $5-7m_0$  have been reported for the bottom of the camel's back,<sup>193</sup> whereas  $m_l^*\approx 2m_0$  high above.<sup>194</sup> Estimates for the transverse mass range from  $0.19m_0$ <sup>182</sup> to  $0.275m_0$ ,<sup>195</sup> although the present consensus puts the value at  $0.25m_0$ .<sup>193</sup> We have taken longitudinal and transverse effective masses for the  $L$ -valley minimum from Levinshtein *et al.*<sup>11</sup>

The Luttinger parameters for GaP were first calculated by Lawaetz.<sup>106</sup> Subsequent cyclotron resonance experiments refined the masses along the  $[111]$ <sup>196–198</sup> and  $[100]$ <sup>198</sup> directions. Street and Senske also determined Luttinger parameters from acceptor binding energies.<sup>199</sup> Those parameters as corrected in Landolt–Bornstein<sup>1</sup> are in reasonably good agreement with cyclotron resonance results, and may be considered the most reliable:  $\gamma_1=4.05$ ,  $\gamma_2=0.49$ , and  $\gamma_3=1.25$ . A split-off hole mass of  $0.23-0.24m_0$  was calculated by Lawaetz<sup>106</sup> and by Krijn.<sup>101</sup> We use a slightly higher value of  $0.25m_0$  in order to be consistent with the interband matrix element.

Lawaetz obtained  $E_P=22.2$  eV using a rather high theoretical estimate for the  $\Gamma$ -valley effective mass in GaP.<sup>106</sup> Recently, more accurate determinations of the interband matrix element in GaAsP have been published.<sup>190,191</sup> By analogy with the case of GaAs discussed above, these imply a much higher  $E_P$  of 31.4 eV, which leads to  $F=-2.04$ . Although such an extrapolation from data on As-rich alloys is somewhat questionable, there is no *a priori* reason that an interband matrix element in GaP so much different from that in GaAs is unreasonable.

The hydrostatic deformation potential for the direct energy gap in GaP was measured by Mathieu *et al.*<sup>200</sup> to be  $a=-9.9$  eV. Van de Walle<sup>129</sup> estimated that the valence-band shift is small compared with the conduction-band shift. We recommend his valence-band deformation potential, with the conduction-band contribution corrected to reproduce the result of Mathieu *et al.*<sup>200</sup> A number of theoretical and experi-

TABLE IV. Band structure parameters for GaP.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$5.4505 + 2.92 \times 10^{-5}(T - 300)$	...
$E_g^\Gamma$ (eV)	$2.886 + 0.1081 [1 - \coth(164/T)]$	2.86–2.895
$E_g^X$ (eV)	2.35	2.338–2.350
$\alpha(X)$ (meV/K)	0.5771	...
$\beta(X)$ (K)	372	...
$E_g^L$ (eV)	2.72	...
$\alpha(L)$ (meV/K)	0.5771	...
$\beta(L)$ (K)	372	...
$\Delta_{so}$ (eV)	0.08	0.08–0.13
$m_e^*$ (Γ)	0.13	0.09–0.17
$m_l^*(X)$	2.0 (camel back)	2–7
$m_l^*(X)$	0.253 (camel back)	0.19–0.275
$m_l^*(L)$	1.2	...
$m_l^*(L)$	0.15	...
$\gamma_1$	4.05	4.04–4.20
$\gamma_2$	0.49	...
$\gamma_3$	2.93	...
$m_{so}^*$	0.25	0.23–0.25
$E_p$ (eV)	31.4	22.2–31.4
$F$	−2.04	0–(−2.04)
VBO (eV)	−1.27	...
$a_c$ (eV)	−8.2	−6.3–(−18.3)
$a_v$ (eV)	−1.7	−0.2–(−2.1)
$b$ (eV)	−1.6	−1.66–(−3.9)
$d$ (eV)	−4.6	−2.7–(−6.0)
$c_{11}$ (GPa)	1405	...
$c_{12}$ (GPa)	620.3	...
$c_{44}$ (GPa)	703.3	...

mental values have been reported<sup>130,187,200</sup> for the shear deformation potentials, which are generally in good agreement with each other. We suggest the following composite values:  $b = -1.6$  eV and  $d = -4.6$  eV.

All of the recommended parameters for GaP are compiled in Table IV.

### E. AIP

AIP, with the largest direct gap of the III–V compound semiconductors, is undoubtedly the most “exotic” and least studied. Nevertheless, the essential characteristics have been known for some time. It is unclear whether the conduction-band minima follow the  $X-\Gamma-L$ <sup>201</sup> or  $X-L-\Gamma$ <sup>182</sup> ordering, since no actual measurements of the  $L$ -valley position appear to have been performed. The indirect energy gap of 2.5 eV and its temperature dependence are given in Casey and Panish<sup>2</sup> with appropriate corrections to the original determinations. A similar value has been obtained by extrapolation from AlGaP alloys by Alferov *et al.*<sup>202</sup> The direct gap of AIP was measured by Monemar<sup>133</sup> to be 3.63 eV at 4 K and 3.62 eV at 77 K, while Bour *et al.*<sup>203</sup> obtained an extrapolation to 300 K of 3.56 eV. The required correction of these results due to the exciton binding energy is unclear. The spin-orbit splitting in AIP should be small, on the order of 0.06–0.07 eV,<sup>101,204</sup> although the actual value has apparently never been measured.

Almost no experimental data are available on the effective masses in AIP. A  $\Gamma$ -valley mass of  $0.22m_0$  was calculated using the augmented spherical wave approach.<sup>101</sup> Another *ab initio* calculation<sup>182</sup> yielded  $m_l^* = 3.67m_0$  and  $m_l^*$

TABLE V. Band structure parameters for AIP.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$5.4672 + 2.92 \times 10^{-5}(T - 300)$	...
$E_g^\Gamma$ (eV)	3.63	3.62 (77 K), 3.56 (300 K)
$\alpha(\Gamma)$ (meV/K)	0.5771	...
$\beta(\Gamma)$ (K)	372	...
$E_g^X$ (eV)	2.52	2.49–2.53
$\alpha(X)$ (meV/K)	0.318	...
$\beta(X)$ (K)	588	...
$E_g^L$ (eV)	3.57	...
$\alpha(L)$ (meV/K)	0.318	...
$\beta(L)$ (K)	588	...
$\Delta_{so}$ (eV)	0.07	0.06–0.07
$m_e^*$ (Γ)	0.22	...
$m_l^*(X)$	2.68	2.68–3.67
$m_l^*(X)$	0.155	0.155–0.212
$\gamma_1$	3.35	...
$\gamma_2$	0.71	...
$\gamma_3$	1.23	...
$m_{so}^*$	0.30	0.29–0.34
$E_p$ (eV)	17.7	...
$F$	−0.65	...
VBO (eV)	−1.74	...
$a_c$ (eV)	−5.7	−5.54–(−5.7)
$a_v$ (eV)	−3.0	−3.0–(−3.15)
$b$ (eV)	−1.5	−1.4–(−4.1)
$d$ (eV)	−4.6	...
$c_{11}$ (GPa)	1330	...
$c_{12}$ (GPa)	630	...
$c_{44}$ (GPa)	615	...

$= 0.212m_0$  for the  $X$  valley, although Issiki *et al.*<sup>205</sup> obtained better agreement with photoluminescence results for AIP/GaP heterostructures using a somewhat smaller  $X$ -valley mass. We have adjusted the theoretical longitudinal and transverse masses by the same factor to conform to that fitting, although further studies are clearly needed to confirm our projections. Composite values for the Luttinger parameters and the split-off hole mass have been taken from various calculations.<sup>101,106,182</sup> An interband matrix element of 17.7 eV ( $F = -0.65$ ) is given by Lawaetz.<sup>106</sup>

The hydrostatic deformation potentials were calculated by Van de Walle,<sup>129</sup> although a slight correction was found to be necessary when energy level alignments in a GaInP/AlGaInP laser structure were fit.<sup>206</sup> We select  $b = -1.5$  eV in accordance with the calculations of O'Reilly<sup>130</sup> and Krijn,<sup>101</sup> although higher values have been computed by Blacha *et al.*<sup>122</sup> No values for the shear deformation potential  $d$  appear to have been reported. In the absence of other information, we recommend the value of  $d = -4.6$  eV derived for GaP (see previous subsection).

All of the band structure parameters for AIP are collected in Table V.

### F. InP

InP is a direct-gap semiconductor of great technological significance,<sup>4–7,10</sup> since it serves as the substrate for most optoelectronic devices operating at the communications wavelength of 1.55  $\mu\text{m}$ . Numerous studies of the band structure parameters for InP and its alloys have been carried out.

Rochon and Fortin<sup>207</sup> found the low-temperature direct band gap to be 1.423 eV, with most other reports agreeing to within a few meV.<sup>1</sup> Since exciton rather than interband transitions are usually observed in such absorption measurements, the binding energy of 5 meV has been added to the spectral position of the resonance.<sup>1,207</sup> The temperature dependence of the direct band gap has been reported by Varshni,<sup>27</sup> Casey and Panish,<sup>2</sup> Lautenschlager *et al.*,<sup>208</sup> Hang *et al.*,<sup>209</sup> and Pavesi *et al.*<sup>210</sup> When  $T \gg \beta$ , the gap decreases linearly with temperature and use of the Varshni expression is not necessary (i.e.,  $\beta = 0$ ). Lautenschlager *et al.* and Pavesi *et al.* did not use the Varshni functional form, and Hang *et al.* focused primarily on fitting higher-temperature band gaps up to 870 K. We recommend using the Casey and Panish temperature dependence (with a corrected value of  $E_g$  at  $T=0$ ) if one's interest is primarily in the temperature range from 0 K to somewhat above room temperature. However, the Lautenschlager *et al.*<sup>211</sup> and Hang *et al.*<sup>212</sup> forms are more appropriate at temperatures well above 300 K.

There are greater uncertainties in the positions of the X-valley and L-valley conduction-band minima in InP. The L-valley minimum is believed to lie 0.4–0.7 eV above the  $\Gamma$ -valley minimum, with the most reliable values favoring an approximately 0.6 eV separation. The temperature dependence is unclear.<sup>1,4,11,201</sup> The  $\Gamma$ -X separation has been studied more closely,<sup>1</sup> and the different works have been compared in detail.<sup>213</sup> The inferred low-temperature value is 0.96 eV, with  $dE_{\Gamma-X}/dT = -0.37$  meV/K. The spin-orbit splitting was determined as  $\Delta_{so} = 0.108$  eV by wavelength-modulated reflection<sup>214</sup> and photovoltaic effect<sup>207</sup> measurements.

The  $\Gamma$ -valley electron effective mass in InP has been investigated in great detail by cyclotron resonance, magnetophonon resonance, and magnetospectroscopy of donor transitions. While values have spanned the range 0.068–0.084 $m_0$ ,<sup>97,98,108,173,207,215–225</sup> if early and ambiguous determinations are excluded and the polaron correction is estimated to retrieve the bare mass,<sup>99,218</sup> the reasonable range for  $m_e^*(T=0)$  narrows to 0.077–0.081 $m_0$ . Averaging the results from different groups, we obtain  $m_e^*(T=0) = 0.0795m_0$ , which is slightly smaller than the typically recommended values of 0.080–0.081 $m_0$ .<sup>1,10</sup> The effective masses for the L and X valleys are taken from Pitt,<sup>213</sup> although there is some controversy on this point and a different set of parameters was given by Levinshstein *et al.*<sup>11</sup>

Luttinger parameters for InP have been measured using cyclotron resonance,<sup>198</sup> magnetorefectance,<sup>109,226</sup> the piezomodulated photovoltaic effect,<sup>207</sup> and magnetoabsorption.<sup>227</sup> Furthermore, the valence-band warping was accurately determined by Alekseev *et al.* using hot-carrier photoluminescence,<sup>228,229</sup> and theoretical calculations have also been performed.<sup>101,106</sup> In arriving at our composite parameters, we follow the procedure of averaging the reported values for heavy-hole and light-hole masses along the [100] and [111] directions. The resulting set of  $\gamma_1 = 5.08$ ,  $\gamma_2 = 1.60$ , and  $\gamma_3 = 2.10$  is in good agreement with all of the most reliable experimental results. The split-off hole mass was measured by Rochon and Fortin<sup>207</sup> to be 0.21 $m_0$ .

TABLE VI. Band structure parameters for InP.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$5.8697 + 2.79 \times 10^{-5}(T - 300)$	...
$E_g^{\Gamma}$ (eV)	1.4236	1.420–1.432
$\alpha(\Gamma)$ (meV/K)	0.363	0.51–1.06
$\beta(\Gamma)$ (K)	162	190–671
$E_g^X$ (eV)	$2.384 - 3.7 \times 10^{-4}T$	1.48–2.39
$E_g^L$ (eV)	2.014	1.82–2.12
$\alpha(L)$ (meV/K)	0.363	...
$\beta(L)$ (K)	162	...
$\Delta_{so}$ (eV)	0.108	0.108–0.13
$m_e^*(\Gamma)$	0.0795	0.068–0.084
$m_{DOS}^*(L)$	0.47	0.25–0.47
$m_{DOS}^*(X)$	0.88	0.32–0.88
$\gamma_1$	5.08	4.61–6.28
$\gamma_2$	1.60	0.94–2.08
$\gamma_3$	2.10	1.62–2.76
$m_{so}^*$	0.21	0.17–0.21
$E_p$ (eV)	20.7	16.6–20.7
$F$	−1.31	0.-(−1.31)
VBO (eV)	−0.94	...
$a_c$ (eV)	−6.0	−3.4-(−21)
$a_v$ (eV)	−0.6	−0.4-(−7.1)
$b$ (eV)	−2.0	−1.0-(−2.0)
$d$ (eV)	−5.0	−4.2-(−5.0)
$c_{11}$ (GPa)	1011	...
$c_{12}$ (GPa)	561	...
$c_{44}$ (GPa)	456	...

Lawaetz<sup>106</sup> and Gorczyca *et al.*<sup>118</sup> calculated the interband matrix element  $E_p$  in InP to be close to 20 eV. This result is in good agreement with the value of 20.7 eV proposed by Hermann and Weisbuch.<sup>116</sup> However, a number of other experimental determinations have favored a value close to 16.5 eV.<sup>96,117,207,219,223</sup> This discrepancy is easily resolved once it is realized that the majority of references did not consider remote-band effects on the electron mass. The difference between the results of Hermann and Weisbuch<sup>116</sup> and Shantharama *et al.*<sup>96</sup> has already been discussed in connection with the interband matrix element for GaAs. We adopt the former value of  $E_p = 20.7$  for InP, which implies  $F = -1.31$  (the latter result would imply  $F \approx 0$ ), although a more detailed examination of this issue is called for in view of the large divergence between the two results.

There is a great deal of variation in the experimental and theoretical deformation potentials for InP as compiled by Adachi.<sup>4</sup> The most reliable values for the conduction-band deformation potential are probably those of Nolte *et al.*<sup>127</sup> (−7 eV) and Van de Walle<sup>129</sup> (−5.04 eV). In combination with the reported direct-gap deformation potential of −6.6 eV,<sup>1</sup> these values imply a rather small shift in the valence band. The shear deformation potentials  $b$  and  $d$  have been determined by Camassel *et al.*<sup>214</sup> and are in good agreement with exciton reflectance measurements.<sup>230</sup>

All of the band structure parameters for InP are collected in Table VI.

## G. GaSb

GaSb is often referred to an intermediate-gap semiconductor, i.e., its gap of  $\approx 0.8$  eV is neither as wide as in GaAs



and InP nor as narrow as in InAs and InSb. Since GaSb forms an increasingly important component of mid-infrared optoelectronic devices,<sup>155</sup> its various alloys have been investigated in some detail. Dutta *et al.* have recently published a comprehensive review of the material and structural properties of GaSb.<sup>231</sup>

Photoluminescence measurements on high-purity layers grown by liquid-phase epitaxy yielded a free exciton transition energy of 0.810 eV at 16 K.<sup>232</sup> Correcting for the exciton binding energy and extrapolating the temperature, we obtain  $E_g(T=0)=0.812$  eV, which agrees to within 1 meV with earlier determinations<sup>1</sup> and also with the recent transmission measurements of Ghezzi *et al.*<sup>233</sup> Varshni parameters for the direct gap have been given by Casey and Panish,<sup>2</sup> Wu and Chen ( $0 < T < 215$  K),<sup>232</sup> Ghezzi *et al.*,<sup>233</sup> Bellani *et al.*,<sup>234</sup> and Joullie *et al.*<sup>235</sup> (numerical values used in that work are given in Ref. 231). The four results that fit the data to room temperature are in excellent agreement with each other, and recommended values have been obtained by simply averaging the Varshni parameters  $\alpha$  and  $\beta$ .

At low temperatures, the  $L$  valley in GaSb is only 0.063–0.100 meV higher than the  $\Gamma$  valley.<sup>1,11,231,235,236,237</sup> The values near the bottom of that range, which were obtained by electroreflectance<sup>235</sup> and modulation spectroscopy,<sup>236</sup> appear to be the most reliable. The temperature dependence of the  $L$ -valley minimum is known to be stronger than that of the  $\Gamma$  valley.<sup>11,236</sup> The position and temperature dependence of the  $X$ -valley minimum were determined by Lee and Woolley,<sup>238</sup> although there was some spread in the earlier reports.<sup>1</sup> The spin-orbit splitting was measured by a number of techniques,<sup>1</sup> with a value of 0.76 eV<sup>236</sup> being commonly accepted.

The  $\Gamma$ -valley band-edge electron mass in GaSb has been studied by a variety of techniques,<sup>175,233,239–245</sup> which produced low-temperature values in the rather narrow range of 0.039–0.042 $m_0$ . The smallness of the spread is rather surprising in consideration of the indirect nature of many of the determinations, which are complicated by the relatively strong conduction-band nonparabolicity in GaSb. Once again, care must be taken to separate results for the polaron and bare effective masses, although as is often the case the polaron correction is no greater than the experimental uncertainty. Averaging produces a bare effective mass of  $m_e^*=0.039m_0$  at 0 K. Somewhat higher values for the effective mass have been calculated theoretically.<sup>100–106</sup>

Owing to the small  $\Gamma$ – $L$  energy separation in GaSb and the much lower density of states at the  $\Gamma$  minimum, at room temperature a significant fraction of the electrons occupy  $L$ -valley states. Effective masses for those states were measured by cyclotron resonance,<sup>11,244,245</sup> Faraday rotation,<sup>1</sup> and piezoresistance.<sup>1</sup> On the basis of these results, we form composite values of  $m_l^*=0.10m_0$  and  $m_l^*=1.3m_0$ . A large nonparabolicity at the  $L$  point has also been reported.<sup>245</sup> Effective masses for the  $X$  valley are taken from Levinstein *et al.*<sup>11</sup>

The Luttinger parameters for GaSb have been determined using a number of experimental and theoretical approaches.<sup>106,239,240,242,243,246,247</sup> On the basis of these results, we suggest the composite values  $\gamma_1=13.4$ ,  $\gamma_2=4.7$ ,

TABLE VII. Band structure parameters for GaSb.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$6.0959 + 4.72 \times 10^{-5}(T - 300)$	...
$E_g^\Gamma$ (eV)	0.812	0.811–0.813
$\alpha(\Gamma)$ (meV/K)	0.417	0.108–0.453
$\beta(\Gamma)$ (K)	140	–10–186
$E_g^X$ (eV)	1.141	1.12–1.242
$\alpha(X)$ (meV/K)	0.475	...
$\beta(X)$ (K)	94	...
$E_g^L$ (eV)	0.875	0.871–0.92
$\alpha(L)$ (meV/K)	0.597	...
$\beta(L)$ (K)	140	...
$\Delta_{so}$ (eV)	0.76	0.749–0.82
$m_i^*(\Gamma)$	0.039	0.039–0.042
$m_l^*(L)$	1.3	1.1–1.4
$m_l^*(L)$	0.10	0.085–0.14
$m_l^*(X)$	1.51	...
$m_l^*(X)$	0.22	...
$\gamma_1$	13.4	11–14.5
$\gamma_2$	4.7	3–5.3
$\gamma_3$	6.0	4.4–6.6
$m_{so}^*$	0.12	0.12–0.14
$E_P$ (eV)	27.0	...
$F$	–1.63	...
VBO (eV)	–0.03	...
$a_c$ (eV)	–7.5	...
$a_v$ (eV)	–0.8	...
$b$ (eV)	–2.0	...
$d$ (eV)	–4.7	...
$c_{11}$ (GPa)	884.2	...
$c_{12}$ (GPa)	402.6	...
$c_{44}$ (GPa)	432.2	...

and  $\gamma_3=6.0$ , which are weighted toward the more recent experiments, but are also quite close to the ones typically used in the literature.<sup>248</sup> The split-off hole mass in GaSb was measured by Reine *et al.*<sup>239</sup>

The interband matrix element for GaSb has been estimated by several workers.<sup>116,239–243</sup> Here the band structure is more sensitive to the adopted value of  $E_P$  than in most materials, because the energy gap is nearly equal to the split-off gap. Therefore, instead of using the result of Hermann and Weisbuch,<sup>116</sup> we determine a composite value  $E_P=27.0$  eV, which is within the experimental uncertainty of nearly all the reports. This composite implies  $F=-1.63$ , which is quite close to the results of Reine *et al.*<sup>239</sup> and Roth and Fortin.<sup>243</sup>

An average value for the direct-gap deformation potential  $a=-8.3$  eV was determined for GaSb by uniaxial stress and transmission experiments.<sup>1</sup> We adopt the Van de Walle<sup>129</sup> suggestion for the valence-band potential of  $a_v=-0.8$  eV, and adjust his  $a_c$  slightly to produce the consistent value of  $a$ . There is good agreement between various measurements of the shear deformation potentials in GaSb, as summarized in Landolt–Bornstein.<sup>1</sup>

All of the band structure parameters for GaSb are collected in Table VII.

## H. AlSb

AlSb is an indirect-gap semiconductor with a lattice constant only slightly larger than that of GaSb. In recent years it



has found considerable use as the barrier material in high-mobility electronic<sup>154</sup> and long-wavelength optoelectronic<sup>155</sup> devices. The direct gap in AlSb was measured using modulation spectroscopy by Alibert *et al.*,<sup>236</sup> spectroscopic ellipsometry by Zollner *et al.*,<sup>249</sup> and also using other methods.<sup>1</sup> Bulk AlSb samples were found to exhibit a gap of 2.35–2.39 eV at liquid-helium temperature, and a  $T$  dependence similar to that in GaSb. The conduction-band minima ordering is believed to be the same as in GaP and AlAs:  $X-L-\Gamma$ , with the  $L$  valley only 60–90 meV above the  $\Gamma$  valley<sup>236</sup> (also quite similar to GaSb). The indirect gap associated with the lowest  $X$  valley was investigated by Sirota and Lukomskii,<sup>250</sup> Mathieu *et al.*,<sup>251</sup> and Alibert *et al.*<sup>236</sup> It has been suggested<sup>1</sup> that early estimates of the band gap needed to be revised, since the exciton binding energy is 19 meV<sup>252</sup> instead of the assumed value of 10 meV.<sup>250</sup> We employ the resulting low-temperature value given in Landolt–Bornstein,<sup>1</sup> along with composite Varshni parameters. The spin-orbit splitting is taken from Alibert *et al.*,<sup>236</sup> which falls near the data compiled in Landolt–Bornstein.<sup>1</sup>

The electron mass in the  $\Gamma$  valley was measured using hot-electron luminescence.<sup>253</sup> While the  $L$ -valley and  $X$ -valley effective masses have been calculated,<sup>1,254</sup> there appear to be no definitive measurements. It is likely that the  $X$  valley in AlSb exhibits a camel's back structure by analogy with AlAs and GaP. Little information is available on the hole masses in AlSb.<sup>253,255</sup> We form our composite values of the Luttinger parameters on the basis of theoretical studies<sup>101,106,182,254</sup> in conjunction with literature values for the hole masses. The interband matrix element is taken from Lawaetz,<sup>106</sup> and the split-off mass is taken to be consistent with Eq. (2.18), although it could be argued that both parameters have a high degree of uncertainty.

The deformation potentials in AlSb were measured at 77 K using a wavelength modulation technique.<sup>256</sup> Once again, we take the valence-band hydrostatic deformation potential calculated by Van de Walle,<sup>129</sup> and make the rest of the results consistent with what appears to be the sole experimental determination.

All of the band structure parameters for AlSb are collected in Table VIII.

## I. InSb

InSb is the III–V binary semiconductor with the smallest band gap. For many years it has been a touchstone for band structure computational methods,<sup>257</sup> partly because of the strong band mixing and nonparabolicity that result from the small gap. The primary technological importance of InSb arises from mid-infrared optoelectronics applications.<sup>258</sup>

Numerous studies of the fundamental energy gap and its temperature dependence have been conducted over the last 3 decades.<sup>1,2,11,160,161,164,243,259–264</sup> While there is a broad consensus that  $E_g(T=0)=0.235$  eV, several different sets of Varshni parameters have been proposed.<sup>2,164,259,264,265</sup> Averaging parameters from the most reliable references, we obtain the composite set:  $\alpha=0.32$  meV/K and  $\beta=170$  K. The  $L$ - and  $X$ -valley energies are taken from Adachi.<sup>166</sup> The spin-

TABLE VIII. Band structure parameters for AlSb.

Parameters	Recommended values	Range
$a_{lc}$ (Å)	$6.1355 + 2.60 \times 10^{-5}(T - 300)$	...
$E_g^\Gamma$ (eV)	2.386	2.35–2.39
$\alpha(\Gamma)$ (meV/K)	0.42	...
$\beta(\Gamma)$ (K)	140	...
$E_g^X$ (eV)	1.696	1.68–1.70
$\alpha(X)$ (meV/K)	0.39	...
$\beta(X)$ (K)	140	...
$E_g^L$ (eV)	2.329	2.327–2.329
$\alpha(L)$ (meV/K)	0.58	...
$\beta(L)$ (K)	140	...
$\Delta_{so}$ (eV)	0.676	...
$m_i^*(\Gamma)$	0.14	0.09–0.18
$m_i^*(L)$	1.64	...
$m_i^*(X)$	0.23	...
$m_l^*(X)$	1.357	...
$m_l^*(X)$	0.123	...
$\gamma_1$	5.18	4.15–5.89
$\gamma_2$	1.19	1.01–1.29
$\gamma_3$	1.97	1.75–2.25
$m_{so}^*$	0.22	...
$E_P$ (eV)	18.7	...
$F$	−0.56	...
VBO (eV)	−0.41	...
$a_c$ (eV)	−4.5	...
$a_v$ (eV)	−1.4	...
$b$ (eV)	−1.35	...
$d$ (eV)	−4.3	...
$c_{11}$ (GPa)	876.9	...
$c_{12}$ (GPa)	434.1	...
$c_{44}$ (GPa)	407.6	...

orbit splitting energy was measured to be 0.81–0.82 eV.<sup>183,260</sup>

Experimental and theoretical studies have found band-edge electron masses for InSb in the range 0.012–0.015 $m_0$ .<sup>95,106,168,171,260,262,265–275</sup> A bare effective mass of 0.0135 $m_0$  at 0 K is in good agreement with a majority of the investigations. On the other hand, little information on the effective masses in the indirect valleys is available. Levinshtein *et al.* quotes a density-of-states effective mass of 0.25 $m_0$  for the  $L$  valley.<sup>11</sup> We have found no explicit theoretical or experimental results for the  $X$ -valley effective masses, although in principle it should be possible to extract them from pseudopotential calculations that have already been performed for bulk InSb.

A wide variety of experimental and theoretical techniques such as magnetophonon resonance and other magneto-optical approaches have been employed to investigate the valence-band structure of InSb.<sup>106,168,243,265,266,269,276–282</sup> By averaging the values for  $\gamma_1$ ,  $m_{hh}^*(001)$ , and  $m_{hh}^*(111)$ , we deduce the composite set:  $\gamma_1=34.8$ ,  $\gamma_2=15.5$ ,  $\gamma_3=16.5$ . These parameters are in good agreement with the majority of the values found in the cited references. Owing to the narrow energy gap, the light-hole effective mass in InSb is only slightly larger than the electron mass.<sup>168,260,265,267,282,283</sup> The split-off hole mass is estimated to be 0.10–0.11 $m_0$ .<sup>106,260</sup>

Our composite interband matrix element for InSb is 23.2 eV.<sup>106,118,263,269,284</sup> A slightly higher value was deduced by

TABLE IX. Band structures parameters for InSb.

Parameters	Recommended values	Range
$a_{\text{lc}}$ (Å)	$6.4794 + 3.48 \times 10^{-5}(T - 300)$	...
$E_g^{\Gamma}$ (eV)	0.235	...
$\alpha(\Gamma)$ (meV/K)	0.32	0.299–0.6
$\beta(\Gamma)$ (K)	170	106–500
$E_g^X$ (eV)	0.63	...
$E_g^L$ (eV)	0.93	...
$\Delta_{\text{so}}$ (eV)	0.81	0.8–0.9
$m_g^*$ ( $\Gamma$ )	0.0135	0.012–0.015
$m_{\text{dos}}^*(L)$	0.25	...
$\gamma_1$	34.8	32.4–38.5
$\gamma_2$	15.5	13.4–18.1
$\gamma_3$	16.5	15.15–18
$m_{\text{so}}^*$	0.11	...
$E_P$ (eV)	23.3	...
$F$	−0.23	...
VBO (eV)	0	...
$a_c$ (eV)	−6.94	...
$a_v$ (eV)	−0.36	...
$b$ (eV)	−2.0	...
$d$ (eV)	−4.7	...
$c_{11}$ (GPa)	684.7	...
$c_{12}$ (GPa)	373.5	...
$c_{44}$ (GPa)	311.1	...

Hermann and Weisbuch,<sup>116</sup> possibly due to an overestimate of the effective  $g$  factor. Somewhat lower values for  $E_P$  are also encountered in the literature.<sup>243,260</sup> Our corresponding  $F$  parameter (−0.23) is close to other determinations.<sup>243,284</sup>

The deformation potentials in InSb have been studied by various optical and electrical techniques.<sup>1,285,286</sup> For the total hydrostatic deformation potential, we take an average value of −7.3 eV. According to the model-solid calculations of Van de Walle,<sup>129</sup> the valence-band deformation potential is rather small by analogy with the other III–V materials. There appears to be a consensus on values for the shear deformation potentials in InSb:  $b = -2.0$  and  $d = -4.7$ .<sup>1,285–287</sup>

All of the recommended band structure parameters for InSb are given in Table IX.

## J. GaN

GaN is a wide-gap semiconductor that usually crystallizes in the wurtzite lattice (also known as hexagonal or  $\alpha$ -GaN). However, under certain conditions zinc blende GaN (sometimes referred to as cubic or  $\beta$ -GaN) can also be grown on zinc blende substrates under certain conditions. Under very high pressure, GaN and other nitrides experience a phase transition to the rocksalt lattice structure.<sup>288</sup> If the crystal structure of a nitride semiconductor is not stated in what follows, the wurtzite phase is implied, whereas the zinc blende phase is always explicitly specified. A review of the physical properties of GaN and other group-III nitride semiconductors up to 1994 was edited by Edgar.<sup>289</sup> The status of GaN work in the 1970's was summarized in two reviews<sup>290,291</sup> as well as in Landolt-Bornstein.<sup>1</sup> For a comprehensive recent review of the growth, characterization, and various properties of nitride materials, we refer the reader to the article by Jain *et al.*<sup>292</sup>

## 1. Wurtzite GaN

Unlike any of the non-nitride wide-gap III–V semiconductors discussed above, GaN is a direct-gap material, which has led to its successful application in blue lasers and LEDs.<sup>293</sup> It has been known since the early 1970's that the energy gap in wurtzite GaN is about 3.5 eV.<sup>294,295</sup> However, a precise determination from luminescence experiments is not straightforward, since what is usually measured at cryogenic temperatures are the energies for various pronounced exciton transitions. The identification of these closely spaced resonances is nontrivial. For example, at very low temperatures, the lowest-order  $A$ ,  $B$ , and  $C$  exciton types related to the three valence bands can be resolved, as well as higher-order  $A(2s,2p)$  exciton transitions.<sup>296</sup> The situation is further complicated by the excitons bound to various impurities, such as neutral donors.<sup>290</sup> All of these considerations contribute to the rather large experimental uncertainty in the bare direct energy gap at low temperatures.

Early measurements of the temperature-dependent direct gap in wurtzite GaN, which are still the most frequently quoted in the nitride device literature, were performed by Monemar.<sup>297,298</sup> Those experiments yielded a free- $A$ -exciton transition energy of 3.475 eV and an estimate of 28 meV for the binding energy. Numerous other PL and absorption studies were published in the 1990s,<sup>296,299–308</sup> which broadened the range of reported  $A$ -exciton transition energies at 0 K to 3.474–3.507 eV. It has been suggested that this spread is due to variations of the strain conditions present in the different experiments.<sup>309</sup> If we average all of the available experimental values, an exciton transition energy of 3.484 eV is obtained. Experimental binding energies for the  $A$  exciton range from 18 to 28 meV.<sup>296,298,302,303,306,310–312</sup> An accurate theoretical determination<sup>313</sup> is out of reach at present owing to the large uncertainty in the reduced mass (primarily associated with the poorly known hole effective mass). We therefore average the most reliable experimental binding energies deduced from the difference between the ground-state and first-excited-state energies of the  $A$  exciton.<sup>296,302,303,306,308,310,311</sup> This gives 23 meV for the exciton binding energy, which implies 3.507 eV for the zero-temperature energy gap.

The temperature dependence of the GaN energy gap was first reported by Monemar,<sup>298</sup> who obtained  $\alpha = -0.508$  meV/K and  $\beta = -996$  K. While the signs of his Varshni coefficients are opposite to all of the other materials considered in this review, a large number of subsequent studies have derived less anomalous results. From optical absorption measurements on bulk and epitaxial layers grown on sapphire, Teisseyre *et al.*<sup>314</sup> obtained  $\alpha = 0.939 - 1.08$  meV/K and  $\beta = 745 - 772$  K. For the temperature variation of the  $A$  exciton resonance, Shan *et al.* reported  $\alpha = 0.832$  meV/K and  $\beta = 836$  K.<sup>299</sup> Petalas *et al.*<sup>315</sup> fixed  $\beta = 700$  K and found  $\alpha = 0.858$  meV/K using spectroscopic ellipsometry. Salvador *et al.*<sup>316</sup> obtained  $\alpha = 0.732$  meV/K and  $\beta = 700$  K based on PL results. Manasreh<sup>304</sup> reported  $\alpha = 0.566 - 1.156$  meV/K and  $\beta = 738 - 1187$  K from absorption measurements on samples grown by MBE and metalorganic chemical vapor deposition. The contactless electroreflectance study of Li *et al.*<sup>307</sup> led to  $\alpha = 1.28$  meV/K and  $\beta = 1190$  K

for the  $A$  exciton transition energy. Finally, Zubrilov *et al.*<sup>317</sup> suggested  $\alpha=0.74$  meV/K and  $\beta=600$  K based on exciton luminescence spectra. It is not obvious how to reconcile these diverse parameter sets, especially since in several cases considerably different values are inferred even in the same study. Much of the difficulty stems from the fact that the resonances dominating the exciton spectra at low temperatures are not readily distinguishable at ambient temperature. Our recommended Varshni parameters represent a simple average of the various reported values except the anomalous results of Monemar.<sup>298</sup> This yields  $\alpha=0.909$  meV/K and  $\beta=830$  K, which are in good agreement with the parameters suggested by absorption measurements on AlGaIn (a negligible composition dependence was reported).<sup>318</sup> It is fortunate that owing to the small relative change in the band gap energy (only 72 meV between 0 and 300 K), the precise choice of Varshni parameters has only a modest impact on the device characteristics.

The indirect energy gaps in GaN are much larger than the direct gap. Few studies have attempted to resolve them, although various estimates of the critical points are available from theory and experiment.<sup>1,290,319–323</sup> Considering the huge uncertainties in the indirect gaps and their lack of importance to device applications, we do not recommend values for the wurtzite forms of the nitride materials. Zinc blende indirect gaps are specified in the tables, however, because they are smaller and somewhat better known.

In contrast to most zinc blende materials, for which only the spin-orbit splitting must be specified, in wurtzite materials the crystal-field splitting is at least as important and cannot be ignored if one wishes to recover a realistic description of the valence-band states (see Sec. II for details).<sup>324</sup> In the following, we take  $\Delta_2=\Delta_3=\Delta_{so}/3$  and  $\Delta_1=\Delta_{cr}$ . An early study of Dingle *et al.* found  $\Delta_{cr}=22$  meV and  $\Delta_{so}=11$  meV.<sup>294</sup> A more recent and detailed analysis by Gil *et al.* yielded the values  $\Delta_{cr}=10$  meV and  $\Delta_{so}=18$  meV.<sup>301</sup> Reynolds *et al.* obtained  $\Delta_{cr}=25$  meV and  $\Delta_{so}=17$  meV from a fit of their exciton data.<sup>311</sup> Using a more precise description of the strain variation of the valence band-edge energies, Chuang and Chang reanalyzed the Gil *et al.* data and derived  $\Delta_{cr}=16$  meV and  $\Delta_{so}=12$  meV.<sup>325</sup> From a similar approach, Shikanai *et al.* obtained  $\Delta_{cr}=22$  meV and  $\Delta_{so}=15$  meV from their own data. *Ab initio* theoretical calculations<sup>326</sup> support a rather small value for the spin-orbit splitting ( $\leq 10$  meV), but tend to overestimate the crystal-field splitting. To obtain our recommended set of  $\Delta_{cr}=19$  meV and  $\Delta_{so}=14$  meV, we averaged all of the reported values with the exception of those from the first-principles theory.

The bottom of the conduction band in GaN is well approximated by a parabolic dispersion relation, although a slight anisotropy (resulting from the reduced lattice symmetry) is not ruled out.<sup>327</sup> In early studies, Barker and Illegems<sup>328</sup> obtained an effective mass of  $0.20m_0$  from plasma reflection measurements, Rheinlander and Neumann<sup>329</sup> inferred  $0.27m_0$  from the Faraday rotation, and Sidorov *et al.*<sup>330</sup> derived values of  $0.1m_0$ – $0.28m_0$ , depending on what primary scattering channel was assumed, from fits to the thermoelectric power. Other early values may be

found in the reviews from the 1970s.<sup>291,290</sup> However, a considerable body of recent work has led to more precise evaluations of the effective mass. Meyer *et al.*<sup>331</sup> and Witowski *et al.*<sup>332</sup> used measurements of the shallow-donor transition energies to obtain masses of  $0.236m_0$  and  $0.222m_0$ , respectively. The latter result has the smallest error bounds quoted in the literature (0.2%). Drechsler *et al.* pointed out the importance of the polaron correction in GaN since it is so strongly polar (10%), and derived a bare mass of  $0.20m_0$  from cyclotron resonance measurements.<sup>333</sup> Perlin *et al.*<sup>334</sup> obtained similar results using infrared-reflectivity and Hall-effect measurements, and additionally found the anisotropy to be less than 1%. A slightly higher dressed mass of  $0.23m_0$  was recently obtained by Wang *et al.*<sup>335</sup> and Knap *et al.* The former may require a slight downward revision because the electron gas was confined in a quantum well, whereas the latter report apparently corrected for that effect.<sup>336</sup> No appreciable correction appears to be necessary for the measurement by infrared ellipsometry on bulk  $n$ -doped GaN reported by Kasic *et al.*,<sup>337</sup> in which a marginally anisotropic electron effective mass with the values of  $0.237\pm 0.006m_0$  and  $0.228\pm 0.008m_0$  along the two axes was obtained. Finally, Elhamri *et al.*,<sup>338</sup> Saxler *et al.*,<sup>339</sup> Wong *et al.*,<sup>340</sup> and Wang *et al.*<sup>341</sup> determined masses ranging from  $0.18m_0$  to  $0.23m_0$  from Shubnikov–de Haas oscillations in the two-dimensional (2D) electron gas at a GaN/AlGaIn heterojunction. It was suggested<sup>338</sup> that strain effects may have to some extent compromised the masses obtained by some of the other studies. Our recommendation of  $0.20m_0$  for the bare mass is close to the consensus from the investigations of bulk materials, and to the average from the studies of 2D electrons.

The experimental information presently available is sufficient only to suggest an approximate band-edge effective mass for the holes. Factors contributing to this uncertainty include strong nonparabolicity near the valence-band edge and the close proximity of heavy-, light-, and crystal-hole bands [see the schematic diagram in Fig. 4(b)].<sup>325</sup> In order to derive the various parameters needed to characterize the valence band of a wurtzite material, one must resort to theoretical projections.<sup>327,342</sup> In the cubic approximation, these parameters may also be recast in terms of the Luttinger parameters familiar from the case of the zinc blende materials.<sup>324</sup> While early work suggested a GaN hole effective mass of  $0.8m_0$ ,<sup>290,343,344</sup> consideration of the acceptor binding energies led Orton<sup>345</sup> to suggest a much smaller value of  $0.4m_0$ . An even smaller mass of  $0.3m_0$  was obtained by Salvador *et al.* from a fit to the PL results.<sup>316</sup> On the other hand, the excess-carrier lifetime measurements of Im *et al.* indicated a very heavy hole mass of  $2.2m_0$ .<sup>305</sup> Merz *et al.* obtained an isotropically averaged heavy-hole mass of  $0.54m_0$  from luminescence data.<sup>303</sup> Fits of the exciton binding energies yielded hole masses in the range  $0.9$ – $1.2m_0$ .<sup>308,346</sup> Finally, an infrared ellipsometric study by Kasic *et al.* yielded a hole mass of  $1.4m_0$  for  $p$ -doped GaN.<sup>337</sup> It should be pointed out that most of these experimental values are somewhat lower than the theoretical masses derived by Suzuki *et al.*,<sup>327</sup> which are commonly used in band structure calculations, and are much lower than



the pseudopotential results of Yeo *et al.*<sup>323</sup> On the other hand, first-principles calculations by Chen *et al.* produced a smaller density-of-states effective mass of  $0.6m_0$ .<sup>302</sup> An alternative set of effective-mass parameters was recently calculated from a pseudopotential model by Dugdale *et al.*<sup>347</sup> Their electron mass is lower than the experimental results, which may indicate lower accuracy of the  $A$  parameters. Yet another parameter set was extracted from empirical pseudopotential calculations by Ren *et al.*<sup>38</sup> That work succeeded in theoretically extracting the inversion parameter  $A_7 = 93.7 \text{ meV/\AA}$  from a comparison with empirical pseudopotential calculations. Our recommendation is to use the effective-mass parameters of Suzuki *et al.*,<sup>327</sup> which imply an average hole mass approximately equal to the free electron value ( $m_0$ ). It is hoped that a theoretical band structure picture that is fully consistent with the recent experimental results will be developed in the near future.

In principle, there are two independent momentum matrix elements in wurtzite GaN. However, the assumption that the electron mass anisotropy is small implies that these are nearly equal. Insofar as no information is available on the effects of remote bands on the wurtzite GaN band structure, that interaction is neglected. If one then derives an interband matrix element directly from the electron effective mass, the result is  $E_p = 14 \text{ eV}$  ( $F=0$ ). While there is one report<sup>305</sup> of  $E_p = 7.7 \text{ eV}$  in wurtzite GaN, that would imply a unrealistic positive  $F$  parameter.

Six distinct valence-band deformation potentials, in addition to the strain tensor and the overall hydrostatic deformation potential, are necessary to describe the band structure of GaN under strain. Using the cubic approximation, these can be re-expressed in terms of the more familiar  $a_v$ ,  $b$ , and  $d$  potentials.<sup>324</sup> Christensen and Gorczyca<sup>319</sup> reported a hydrostatic deformation potential  $a = -7.8 \text{ eV}$ , which is in good agreement with fits to the data of Gil *et al.* ( $-8.16 \text{ eV}$ ).<sup>301</sup> A somewhat lower  $a = -6.9 \text{ eV}$  was derived from an *ab initio* calculation by Kim *et al.*<sup>348</sup> Shan *et al.*<sup>349</sup> noted that the hydrostatic deformation potential should be anisotropic due to the reduced symmetry of the wurtzite crystal, and gave the values:  $a_1 = -6.5 \text{ eV}$  and  $a_2 = -11.8 \text{ eV}$  for the two components. These are our recommended values. Numerous sets of valence-band deformation potentials have been derived from both first-principles calculations<sup>325,342,350</sup> and fits to experimental data.<sup>301,306,349</sup> There are considerable discrepancies between the reported data, with variations of nearly a factor of 6 in some cases. Obviously, further work is needed to resolve this controversy. We form our composite set of deformation potentials by selecting those values that seem to be most representative of the majority of results:  $D_1 = -3.0 \text{ eV}$ ,<sup>350</sup>  $D_2 = 3.6 \text{ eV}$ ,<sup>350</sup>  $D_3 = 8.82 \text{ eV}$ ,<sup>306</sup>  $D_4 = -4.41 \text{ eV}$ ,<sup>306</sup>  $D_5 = -4.0 \text{ eV}$ ,<sup>350</sup> and  $D_6 = -5.1 \text{ eV}$  (derived by adopting the cubic approximation<sup>325</sup>).

The determination of elastic constants for wurtzite GaN has been reviewed by Wright,<sup>351</sup> who compared the results of a number of experiments<sup>352–355</sup> with two calculations.<sup>348,351</sup> Overall, theory agrees best with the data of Polian *et al.*,<sup>353</sup> who obtained the recommended values:  $C_{11} = 390 \text{ GPa}$ ,  $C_{12} = 145 \text{ GPa}$ ,  $C_{13} = 106 \text{ GPa}$ ,  $C_{33} = 398 \text{ GPa}$ , and  $C_{44} = 105 \text{ GPa}$ . However, there are significant disagreements be-

tween the various experimental results, so that in contrast to the zinc blende materials the elastic constants for GaN remain somewhat controversial.

Very few measurements of the piezoelectric coefficients in GaN have been reported. Guy *et al.*<sup>356,357</sup> performed a careful study, which pointed out the differences between the coefficients in a bulk material versus a strained thin film. Coefficients of  $d_{33} = 3.7 \text{ pm/V}$  and  $d_{13} = -1.9 \text{ pm/V}$  were deduced for the bulk GaN from the single-crystal thin-film value  $d_{33} = 2.8 \text{ pm/V}$  and the relation  $d_{13} = -d_{33}/2$ . Another measurement by Lueng *et al.* yielded a thin-film value  $d_{33} = 2.13 \text{ pm/V}$ .<sup>358</sup> The latter measurement had the inherent uncertainty of an AlN buffer layer being present. Bykhovski *et al.* attempted to derive the  $e_{31}$  and  $e_{33}$  coefficients from the  $e_{14}$  coefficient in zinc blende GaN, obtaining values of  $e_{31} = -0.22 \text{ C/m}^2$  and  $e_{33} = 0.43 \text{ C/m}^2$ .<sup>359</sup> Bernardini *et al.* employed a first-principles calculation to derive  $e_{31} = -0.49 \text{ C/m}^2$  and  $e_{33} = 0.73 \text{ C/m}^2$ .<sup>360</sup> A calculation of Shimada *et al.* yielded values of  $e_{31} = -0.32 \text{ C/m}^2$  and  $e_{33} = 0.63 \text{ C/m}^2$ .<sup>361</sup> We recommend using the  $d$  coefficients from the experimental study of Guy *et al.* and use the assumed elastic constants to obtain the  $e$  coefficients:  $e_{31} = -0.35 \text{ C/m}^2$  and  $e_{33} = 1.27 \text{ C/m}^2$ , which turn out to be somewhat different from those calculated in the original report.<sup>357</sup>

Only two first-principles calculations of the spontaneous polarization in GaN are available.<sup>360,362</sup> Very different values of  $P_{\text{sp}} = -0.029 \text{ C/m}^2$  and  $P_{\text{sp}} = -0.074 \text{ C/m}^2$  were reported. In one of the papers,<sup>362</sup> it was noted that the computed spontaneous polarization is highly sensitive to the values of the internal structure parameters such as the lengths of the atomic bonds. This consideration may prevent an accurate theoretical evaluation of the spontaneous polarization for realistic nitride structures. Since only *differences* in the spontaneous polarization are important in heterostructure band calculations, we defer a full discussion of the experimental probes of the spontaneous polarization in GaN/AlGaIn quantum wells until the AlN section. The band structure parameters for wurtzite GaN are compiled in Table X.

## 2. Zinc blende GaN

A number of theoretical and experimental studies of the energy gap for the zinc blende phase of GaN have been reported.<sup>315,363–371</sup> Some works rely on an explicit comparison with the better understood case of wurtzite GaN, whereas the most accurate appear to come from low-temperature luminescence measurements<sup>372–374</sup> of the free-exciton peak, which is estimated to be  $26.5 \text{ meV}$  below the energy gap. Experimentally, the low-temperature energy gaps range from  $3.2$  to  $3.5 \text{ eV}$ , although the most reliable values fall approximately midway, between  $3.29$  and  $3.35 \text{ eV}$ .<sup>365,367,368</sup> We recommend a value of  $3.299 \text{ eV}$  obtained from averaging the results of the luminescence measurements. The temperature dependence of the energy gap was studied in detail by Ramirez-Flores *et al.*<sup>368</sup> and Petalas *et al.*<sup>315</sup> Although the two studies obtain the same  $\beta = 600 \text{ K}$  (using the more reliable model 1 in Ref. 315), the  $\alpha$  parameters are different, and we recommend using an average value of  $0.593 \text{ meV/K}$ . Although the indirect-gap energies have not been measured, a



TABLE X. Recommended band structure parameters for wurtzite nitride binaries.

Parameters	GaN	AlN	InN
$a_{lc}$ (Å) at $T=300$ K	3.189	3.112	3.545
$c_{lc}$ (Å) at $T=300$ K	5.185	4.982	5.703
$E_g$ (eV)	3.507	6.23	1.994
$\alpha$ (meV/K)	0.909	1.799	0.245
$\beta$ (K)	830	1462	624
$\Delta_{cr}$ (eV)	0.019	-0.164	0.041
$\Delta_{so}$ (eV)	0.014	0.019	0.001
$m_e^*$	0.20	0.28	0.12
$m_e^*$	0.20	0.32	0.12
$A_1$	-6.56	-3.95	-8.21
$A_2$	-0.91	-0.27	-0.68
$A_3$	5.65	3.68	7.57
$A_4$	-2.83	-1.84	-5.23
$A_5$	-3.13	-1.95	-5.11
$A_6$	-4.86	-2.91	-5.96
$E_p$ (eV)	14.0	14.5	14.6
$F$	0	0	0
VBO (eV)	-2.64	-3.44	-1.59
$a_1$ (eV)	-6.5	-9.0	-3.5
$a_2$ (eV)	-11.8	-9.0	-3.5
$D_1$ (eV)	-3.0	-3.0	-3.0
$D_2$ (eV)	3.6	3.6	3.6
$D_3$ (eV)	8.82	9.6	8.82
$D_4$ (eV)	-4.41	-4.8	-4.41
$D_5$ (eV)	-4.0	-4.0	-4.0
$D_6$ (eV)	-5.1	-5.1	-5.1
$c_{11}$ (GPa)	390	396	223
$c_{12}$ (GPa)	145	137	115
$c_{13}$ (GPa)	106	108	92
$c_{33}$ (GPa)	398	373	224
$c_{44}$ (GPa)	105	116	48
$e_{13}$ (C/m <sup>2</sup> )	-0.35	-0.50	-0.57
$e_{33}$ (C/m <sup>2</sup> )	1.27	1.79	0.97
$P_{sp}$ (C/m <sup>2</sup> )	-0.029	-0.081	-0.032

recent calculation of Fan *et al.* puts the  $X$ -valley and  $L$ -valley minima at 1.19 and 2.26 eV above the  $\Gamma$  valley, respectively.<sup>369</sup> Ramirez-Flores *et al.*<sup>368</sup> have measured the spin-orbit splitting in zinc blende GaN to be 17 meV.

Electron spin resonance measurements indicated an electron effective mass of  $0.15m_0$  in zinc blende GaN.<sup>375</sup> Since this appears to be the only experimental result, we adopt it as our recommendation. Similar  $\Gamma$ -valley effective masses were derived from first-principles calculations by Chow *et al.*<sup>376</sup> and Fan *et al.*<sup>369</sup> Effective masses of  $m_l^* = 0.5m_0$  and  $m_t^* = 0.3m_0$  were recently calculated for the  $X$  valley in GaN,<sup>370</sup> which are similar to values obtained by Fan *et al.*<sup>369</sup> The convergence of results from two different studies allows us to adopt these as our recommended values.

Although the hole effective masses in zinc blende GaN have not been measured, a number of theoretical sets of Luttinger parameters are available.<sup>369–378</sup> In order to derive our recommended values, we average the heavy-hole and light-hole masses along  $[001]$  as well as the degree of anisotropy  $\gamma_3 - \gamma_2$ . This results in the following parameter set:  $\gamma_1 = 2.67$ ,  $\gamma_2 = 0.75$ , and  $\gamma_3 = 1.10$ . When all of the reported<sup>369–371,379</sup> split-off masses are averaged, we obtain  $m_{so}^* = 0.29m_0$ .

TABLE XI. Recommended band structure parameters for zinc blende nitride binaries.

Parameters	GaN	AlN	InN
$a_{lc}$ (Å) at $T=300$ K	4.50	4.38	4.98
$E_g^I$ (eV)	3.299	4.9	1.94
$\alpha(\Gamma)$ (meV/K)	0.593	0.593	0.245
$\beta(\Gamma)$ (K)	600	600	624
$E_g^X$ (eV)	4.52	6.0	2.51
$\alpha(X)$ (K)	0.593	0.593	0.245
$\beta(X)$ (meV/K)	600	600	624
$E_g^L$ (eV)	5.59	9.3	5.82
$\alpha(L)$ (K)	0.593	0.593	0.245
$\beta(L)$ (meV/K)	600	600	624
$\Delta_{so}$ (eV)	0.017	0.019	0.006
$m_e^*(\Gamma)$	0.15	0.25	0.12
$m_l^*(X)$	0.5	0.53	0.48
$m_t^*(X)$	0.3	0.31	0.27
$\gamma_1$	2.67	1.92	3.72
$\gamma_2$	0.75	0.47	1.26
$\gamma_3$	1.10	0.85	1.63
$m_{so}^*$	0.29	0.47	0.3
$E_p$ (eV)	25.0	27.1	25.0
$F$	-0.92	0.76	-0.92
VBO (eV)	-2.64	-3.44	-2.38
$a_c$ (eV)	-2.2	-6.0	-1.85
$a_v$ (eV)	-5.2	-3.4	-1.5
$b$ (eV)	-2.2	-1.9	-1.2
$d$ (eV)	-3.4	-10	-9.3
$c_{11}$ (GPa)	293	304	187
$c_{12}$ (GPa)	159	160	125
$c_{44}$ (GPa)	155	193	86

Two theoretical values for  $E_p$  in zinc blende GaN have been reported in the literature.<sup>371,379</sup> An average of the two yields  $E_p = 25.0$  eV, which in turn implies  $F = -0.92$ . A note of caution is that these values have not been verified experimentally.

Various calculations put the hydrostatic deformation potential for zinc blende GaN in the range between -6.4 and -8.5 eV.<sup>42,319,369,370,376,380</sup> We choose an average value of  $a = -7.4$  eV. The same procedure is followed in obtaining the recommended values of  $a_v = -5.2$  eV (-0.69 to -13.6 eV range) and  $b = -2.2$  eV (-1.6 to -3.6 eV range). The value of  $d = -3.4$  eV is an average between the only published values from Ohtoshi *et al.*<sup>380</sup> and Van de Walle and Neugebauer.<sup>381</sup> No experimental confirmations of any of these deformation potentials for zinc blende GaN appear to exist. Elastic constants of  $C_{11} = 293$  GPa,  $C_{12} = 159$  GPa, and  $C_{44} = 155$  GPa are taken from the theoretical analysis of Wright.<sup>351</sup> Very similar sets were calculated by Kim *et al.*<sup>382</sup> and Bechstedt *et al.*<sup>362</sup> The band structure parameters for zinc blende GaN are compiled in Table XI.

## K. AlN

Although binary AlN is rarely used in practical devices, it represents the end point for the technologically important AlGaIn alloy. As in the case of GaN, both wurtzite and zinc blende forms of AlN can in principle be grown, although the growth of zinc blende AlN has not been reported. Wurtzite AlN has the distinction of being the only Al-containing III-V semiconductor compound with a direct energy gap.

Furthermore, it is the largest-gap material that is still commonly considered to be a semiconductor. The absorption measurements of Yim *et al.*<sup>383</sup> and Perry and Rutz<sup>384</sup> indicate that the energy gap in wurtzite AlN varies from 6.28 eV at 5 K to 6.2 eV at room temperature. Varshni parameters of  $\alpha = 1.799$  meV/K and  $\beta = 1462$  K were reported by Guo and Yoshida, who also found the low-temperature gap to be 6.13 eV.<sup>385</sup> A similar energy gap was reported by Vispute *et al.*<sup>386</sup> With the aid of cathodoluminescence experiments, Tang *et al.*<sup>387</sup> resolved at 300 K what they believed to be the free or shallow-impurity-bound exciton, at an energy of 6.11 eV. We recommend an intermediate value of 6.23 eV for the low-temperature band gap, in conjunction with the Varshni parameters of Guo and Yoshida.<sup>385</sup> Although Brunner *et al.*<sup>318</sup> also reported Varshni parameters, the finding of no significant differences from GaN for the entire composition range of the AlGaIn alloy may indicate that their results are somewhat less reliable.

The crystal-field splitting in AlN is believed to be negative, which implies that the topmost valence band is crystal hole-like. Suzuki *et al.*<sup>327</sup> calculated  $\Delta_{\text{cr}} = -58$  meV, whereas Wei and Zunger<sup>326</sup> obtained  $\Delta_{\text{cr}} = -217$  meV. Pugh *et al.*<sup>371</sup> cited values of  $-104$  and  $-169$  meV from first-principles and semiempirical pseudopotential calculations, respectively, and Kim *et al.*<sup>388</sup> obtained  $\Delta_{\text{cr}} = -215$  meV. Averaging all of the available theoretical crystal-field splittings, we obtain our recommended value of  $\Delta_{\text{cr}} = -164$  meV. Spin-orbit splittings ranging from  $11^{371}$  to  $20$  meV<sup>327</sup> have been cited in the literature. We adopt the value of  $19$  meV suggested by Wei and Zunger.<sup>326</sup> Again, it is important to emphasize that our recommendations for the crystal-field and spin-orbit splittings in AlN have only provisional status, since it appears that no experimental data exist.

A number of calculations are available for the electron effective mass in AlN.<sup>327,371,388</sup> A greater anisotropy than in wurtzite GaN is predicted.<sup>327</sup> The recommended values of  $m_e^{\perp} = 0.28m_0$  and  $m_e^{\parallel} = 0.32m_0$  were obtained by averaging all available theoretical masses, although it is again noted that experimental studies are needed to verify these calculations. We recommend the valence-band effective mass parameters of Suzuki *et al.*<sup>327</sup> An alternative set of  $A$  parameters was recently published by Dugdale *et al.*<sup>347</sup> The apparent disagreement in signs in various papers for  $A_5$  and  $A_6$  is ignored, since only absolute values of these parameters enter the Hamiltonian.<sup>371,388</sup>

The hydrostatic deformation potential for wurtzite AlN is believed to lie in the range between  $-7.1$  and  $-9.5$  eV.<sup>319,348</sup> We select a median value of  $-9.0$  eV, which is consistent with the observation that the band gap pressure coefficients in AlGaIn alloys have little dependence on composition.<sup>389</sup> Theoretical values are also available for a few of the valence-band deformation potentials ( $D_3 = 9.6$  eV,  $D_4 = -4.8$  eV).<sup>348</sup> The elastic constants in wurtzite AlN were measured by Tsubouchi *et al.*<sup>390</sup> and McNeil *et al.*<sup>391</sup> We recommend the values  $C_{11} = 396$  GPa,  $C_{12} = 137$  GPa,  $C_{13} = 108$  GPa,  $C_{33} = 373$  GPa, and  $C_{44} = 116$  GPa suggested by Wright, who provides a detailed discussion of their expected accuracy.<sup>351</sup>

Several early measurements<sup>392,393</sup> of the piezoelectric coefficient in AlN were compiled in Ref. 357. That reference obtained  $d_{33} = 5.6$  pm/V and  $d_{13} = -2.8$  pm/V, which were rather similar to the previous determinations. The available calculations<sup>360,361,394</sup> are in reasonable agreement with the experimental values. Two rigorous calculations<sup>360,362</sup> of the spontaneous polarization in AlN have been performed with the reported results of  $P_{\text{sp}} = -0.081$  C/m<sup>2</sup> and  $P_{\text{sp}} = -0.12$  C/m<sup>2</sup>. The effect of the spontaneous polarization on the optical properties of GaN/AlGaIn quantum wells was observed by Leroux *et al.*<sup>395,396</sup> However, it was found that the results were consistent with a lower value for the spontaneous polarization in AlN ( $-0.051 < P_{\text{sp}} < -0.036$  C/m<sup>2</sup>). A study of the charging of GaN/AlGaIn field-effect transistors led to similar conclusions.<sup>397</sup> Hogg *et al.* were able to fit their luminescence data by assuming negligible spontaneous polarization.<sup>398</sup> Park and Chuang<sup>399</sup> required  $P_{\text{sp}} = -0.040$  C/m<sup>2</sup> to reproduce their GaN/AlGaIn quantum-well data. On the other hand, Cingolani *et al.* reported good agreement with experiment using the original Bernardini *et al.*<sup>360</sup> calculation.<sup>400</sup> The magnitude of the estimated spontaneous polarization is dependent on the assumed piezoelectric coefficients. It may be possible to explain the remaining discrepancy between the majority of the experimental investigations and the Bernardini *et al.* calculation if a linear interpolation of  $P_{\text{sp}}$  is invalid for the AlGaIn alloy, due to either bowing or long-range ordering. At this juncture, we recommend the calculated value and note that the controversy will likely be resolved in future work. The recommended band structure parameters for wurtzite AlN are compiled in Table X.

Zinc blende AlN is projected to be an indirect-band gap material, with  $X$ -,  $\Gamma$ -, and  $L$ -valley gaps of 4.9, 6.0, and 9.3 eV, respectively.<sup>319,369,371</sup> The spin-orbit splitting is believed to be the same as in wurtzite AlN (19 meV).<sup>326</sup> Averaging the theoretical results from different sources,<sup>369,371,378,379,388</sup> we obtain the recommended  $\Gamma$ -valley effective mass of  $0.25m_0$ . The longitudinal and transverse masses for the  $X$  valley are predicted to be  $0.53m_0$  and  $0.31m_0$ , respectively.<sup>369</sup> The same procedure employed for GaN yields the recommended Luttinger parameters:<sup>369,371,378,379,388</sup>  $\gamma_1 = 1.92$ ,  $\gamma_2 = 0.47$ , and  $\gamma_3 = 0.85$  ( $m_{\text{so}} = 0.47m_0$ ). The momentum matrix element is taken to be an average of the reported values:<sup>371,379</sup>  $E_P = 27.1$  eV ( $F = 0.76$ ). Hydrostatic deformation potentials of  $-9.0$  eV<sup>319</sup> and  $-9.8$  eV<sup>369</sup> have been reported. Our recommended values for the deformation potentials are  $a = -9.4$  eV,  $a_v = -3.4$  eV,<sup>42,369</sup>  $b = -1.9$  eV,<sup>369,381</sup> and  $d = -10.0$  eV.<sup>348,381</sup> The elastic constants of  $C_{11} = 304$  GPa,  $C_{12} = 160$  GPa, and  $C_{44} = 193$  GPa are adopted from the calculations of Wright.<sup>351</sup> Similar sets were quoted in other theoretical works.<sup>362,382,401</sup> The recommended band structure parameters for zinc blende AlN are compiled in Table XI.

## L. InN

Although InN is rarely if ever used in devices in its binary form, it forms an alloy with GaN that is at the core of the blue diode laser.<sup>293</sup> Especially since some degree of seg-

regation is believed to occur when that alloy is grown, it is important to understand the properties of bulk InN in its wurtzite phase. Osamura *et al.*<sup>402</sup> measured the energy gap at 78 K to be 2.0 eV (although for the purposes of the quadratic fit for GaInN, a different gap was stated in the abstract of that article), which became approximately 60 meV lower at room temperature. The absorption measurements of Puychev and Menoret<sup>403</sup> on polycrystalline InN indicated gaps of 2.21 and 2.09 eV at 77 and 300 K, respectively. Another set of absorption measurements by Tyagai *et al.*<sup>404</sup> yielded  $E_g = 2.05$  eV at 300 K. The result of Tansley and Foley,<sup>405</sup>  $E_g = 1.89$  eV at 300 K for high-purity InN thin films, is often quoted in the literature. It is judged more reliable than earlier experiments performed on samples with high electron densities. An even lower gap was obtained by Westra and Brett,<sup>406</sup> although in their case a high electron density was also present. Varshni parameters of  $\alpha = 0.245$  meV/K and  $\beta = 624$  K were reported by Guo and Yoshida<sup>385</sup> for wurtzite InN, along with low-temperature and room-temperature gaps of 1.994 and 1.97 eV, respectively. These values, which closely resemble a previous result from the same group,<sup>407</sup> represent our recommended temperature dependence. The recommended crystal-field and spin-orbit splittings of 41 and 1 meV, respectively, are taken from the calculation of Wei and Zunger.<sup>326</sup>

There appear to be only two measurements of the electron mass in InN, which found values of  $0.11m_0$ <sup>404</sup> and  $0.12m_0$ .<sup>408</sup> We recommend the latter, since it closely matches the theoretical projection.<sup>321</sup> Valence-band effective-mass parameters were calculated by Yeo *et al.*<sup>323</sup> using the empirical pseudopotential method, by Pugh *et al.*<sup>371</sup> and Dugdale *et al.*<sup>347</sup> using essentially the same techniques. The results of the first two studies are quite similar, and we recommend the parameters derived by Pugh *et al.*<sup>371</sup>

Christensen and Gorczyca predicted a hydrostatic deformation potential of  $-4.1$  eV for wurtzite InN,<sup>319</sup> although a smaller value of  $-2.8$  eV was calculated by Kim *et al.*<sup>348</sup> We recommend the average of  $a = -3.5$  eV. Since apparently there have been no calculations of the valence-band deformation potentials, we recommend appropriating the set specified above for GaN. While elastic constants were measured by Sheleg and Savastenko,<sup>352</sup> we recommend the improved set of Wright.<sup>351</sup>  $C_{11} = 223$  GPa,  $C_{12} = 115$  GPa,  $C_{13} = 92$  GPa,  $C_{33} = 224$  GPa, and  $C_{44} = 48$  GPa. The piezoelectric coefficients and spontaneous polarization for InN are taken from the calculation by Bernardini *et al.*<sup>360</sup> The recommended band structure parameters for wurtzite InN are compiled in Table X.

Although the growth of zinc blende InN has been reported,<sup>409</sup> only theoretical estimates are available for any of its band parameters. It is predicted to be a direct-gap material, with  $\Gamma$ -,  $X$ -, and  $L$ -valley gaps of 1.94, 2.51, and 5.82 eV, respectively.<sup>370</sup> The spin-orbit splitting is projected to be 6 meV.<sup>326</sup> We recommend an electron effective mass identical to that in wurtzite InN,  $0.12m_0$ , which is in the middle of the range  $0.10$ – $0.14m_0$  that has been calculated.<sup>370,371,379</sup> The longitudinal and transverse masses for the  $X$  valley are predicted to be  $0.48m_0$  and  $0.27m_0$ , respectively.<sup>370</sup> The rec-

ommended Luttinger parameter set:  $\gamma_1 = 3.72$ ,  $\gamma_2 = 1.26$ , and  $\gamma_3 = 1.63$  is from the results of Pugh *et al.*,<sup>371</sup> and the split-off mass is chosen to be  $m_{so}^* = 0.3m_0$ .<sup>370,371</sup> For the hydrostatic deformation potential, an average of  $-3.35$  eV from the theoretical<sup>319,348,370</sup> range of  $-2.2$  to  $-4.85$  eV is recommended. Valence-band deformation potentials are taken from a combination of the calculations of Wei and Zunger,<sup>42</sup> Kim *et al.*,<sup>370</sup> and Van de Walle and Neugebauer.<sup>381</sup>  $a_v = -1.5$  eV,  $b = -1.2$  eV, and  $d = -9.3$  eV. Elastic constants of  $C_{11} = 187$  GPa,  $C_{12} = 125$  GPa, and  $C_{44} = 86$  GPa have been adopted from the calculations of Wright.<sup>351</sup> Similar sets were derived from other calculations.<sup>362,382</sup> The recommended band structure parameters for zinc blende InN are compiled in Table XI.

#### IV. TERNARY ALLOYS

For all of the ternary alloys discussed below, the dependence of the energy gap on alloy composition is assumed to fit a simple quadratic form:<sup>410</sup>

$$E_g(A_{1-x}B_x) = (1-x)E_g(A) + xE_g(B) - x(1-x)C, \quad (4.1)$$

where the so-called bowing parameter  $C$  accounts for the deviation from a linear interpolation (virtual-crystal approximation) between the two binaries  $A$  and  $B$ . The bowing parameter for III–V alloys is typically positive (i.e., the alloy band gap is smaller than the linear interpolation result) and can in principle be a function of temperature. The physical origin of the band gap bowing can be traced to disorder effects created by the presence of different cations (anions).<sup>410</sup> A rough proportionality to the lattice mismatch between the end-point binaries has also been noted.<sup>201</sup>

In what follows, the bowing concept has been generalized to include quadratic terms in the alloy-composition series expansions for several other band parameters as well, which in some cases may be attributable to specific physical mechanisms but in others simply represent empirical fits to the experimental data. We will employ the above functional form for all parameters and, with minor exceptions, neglect higher-order terms in the expansions. Since full self-consistency has been imposed upon all of the recommended parameter sets, we will give only bowing parameters for the alloy properties, and note that the end points may be found in the tables corresponding to the relevant binaries.

We also point out that since the  $\Gamma$ -valley electron mass  $m_e^*$  can be obtained from Eq. (2.15) in conjunction with the specified values for  $E_g$ ,  $E_p$ ,  $\Delta_{so}$ , and  $F$ , it is not an independent quantity. In compiling the tables for binaries, we have assured that the values given for the mass and the other parameters are consistent with Eq. (2.15). For alloys, the suggested approach is to: (1) interpolate linearly the  $E_p$  and  $F$  parameters,<sup>115</sup> (2) use the bowing parameter specified for the alloy to derive  $E_g(T)$  and  $\Delta_{so}(T)$  from Eq. (4.1), and (3) obtain the temperature-dependent electron mass in the alloy from Eq. (2.15). While this procedure yields a complex dependence of the effective mass on composition, it assures self-consistency and in all of the cases that we are aware of it appears to be reliable. Simpler approximations are naturally



sometimes possible. In the tables, we attempt to give electron mass bowing parameters that are consistent with the above procedure.

Linear interpolations are suggested for the electron masses in the  $X$  and  $L$  valleys, split-off hole mass, and heavy-hole and light-hole masses along the  $[001]$  direction.<sup>146</sup> In order to estimate the valence-band warping, the suggested procedure is to interpolate the  $\gamma_3 - \gamma_2$  difference. Direct interpolation of the individual Luttinger parameters is *not* recommended. Lattice constants and elastic moduli may also be linearly interpolated.

## A. Arsenides

### 1. AlGaAs

AlGaAs is the most important and the most studied III-V semiconductor alloy. Its key role in a variety of transistor and optoelectronic devices has necessitated a precise knowledge of the fundamental energy gap as well as the alignment of the three main conduction-band valleys. Investigations are complicated by the fact that whereas GaAs is a direct-gap material with  $\Gamma$ - $L$ - $X$  valley ordering, AlAs is an indirect material with exactly the reverse ordering. Particular attention has been devoted to the crossover point, at which the  $\Gamma$  and  $X$  valley minima have the same energies.

Bowing parameters from 0.14 to 0.66 eV have been proposed for the  $\Gamma$ -valley energy gap when Eq. (4.1) is used for all compositions of  $\text{Al}_x\text{Ga}_{1-x}\text{As}$ .<sup>8,92,140,142,143,411</sup> Casey and Panish suggested a linear  $x$  dependence in the range  $0 < x < 0.45$  (also supported by other data)<sup>412-415</sup> and a quadratic dependence when  $0.45 < x < 1$ .<sup>2</sup> Using spectroscopic ellipsometry to derive the positions of the critical points, Aspnes *et al.* obtained a composition-dependent bowing parameter:  $C = (-0.127 + 1.310x)$  eV.<sup>416</sup> A small bowing parameter was favored on theoretical grounds,<sup>410</sup> although a more recent treatment by Magri and Zunger<sup>417,418</sup> gave a complex fourth-order dependence reminiscent of the Aspnes *et al.* result. Although the bowing parameters that we recommend in all other cases (with the exception of the direct gap in AlGaSb) are not a function of composition, in the present case it appears that much more accurate results can be obtained by using the cubic form of Aspnes *et al.* There is insufficient data to determine the temperature dependence of the bowing parameter, since most of the determinations were performed either at room temperature or at liquid-helium temperature. Varshni parameters for  $\text{Al}_x\text{Ga}_{1-x}\text{As}$  have been obtained from photoluminescence, photoreflectance, and spectroscopic ellipsometry studies.<sup>90,138,419</sup> These are in reasonable agreement with our recommended assumption that the bowing parameter is independent of temperature.

Bowing parameters for the  $X$ -valley and  $L$ -valley gaps in AlGaAs were determined using electrical measurements in combination with a theoretical model by Lee *et al.*<sup>140</sup> and Saxena<sup>141</sup> as well as empirically by Casey and Panish.<sup>2</sup> These results and photoluminescence excitation spectroscopy data<sup>420</sup> support a  $C(E_g^L)$  almost equal to zero. We select  $C(E_g^X) = 0.055$  eV obtained from photoluminescence measurements,<sup>134,139</sup> which is near the bottom of the earlier range of values but is the most recent and seems the most

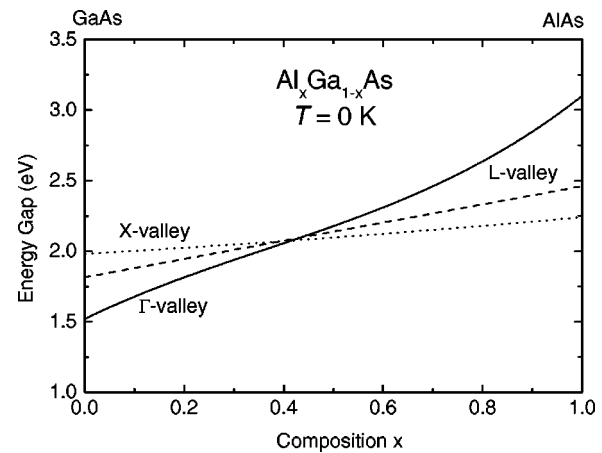


FIG. 5.  $\Gamma$ -,  $X$ -, and  $L$ -valley gaps for the AlGaAs alloy at  $T=0$  K (solid, dotted, and dashed curves, respectively).

reliable. This result implies a  $\Gamma$ - $X$  crossover composition of  $x=0.38$  at low temperatures (and 0.39 at 300 K), which agrees with the trend in the table compiled by Adachi.<sup>3</sup> Composition dependences for all three of the direct and indirect gaps in  $\text{Al}_x\text{Ga}_{1-x}\text{As}$  are plotted in Fig. 5. Most studies find that the split-off gap can be fit quite well by linear interpolation.<sup>101,138,143</sup> A value of  $C(\Delta_{so}) = 0.147$  eV derived by Aubel *et al.*<sup>142</sup> cannot be considered fully reliable, since it was based on data points in a rather narrow composition range.

Several studies of the composition dependence of the  $\Gamma$ -valley electron mass have been reported for  $x < 0.33$ .<sup>146,147,421</sup> The points have been fit to a quadratic dependence,<sup>421</sup> although owing to the narrow composition range and spread in the data points, it is difficult to judge the accuracy of such a scheme. From other reports, it appears that the linear approximation gives adequate results for small  $x$ .<sup>3,104,140,146,147</sup> Since the effective mass in AlAs was chosen to be consistent with the results in AlGaAs, a zero bowing parameter is recommended and gives good agreement with the interpolation procedures discussed at the beginning of Sec. V. The same procedures should be used to obtain the  $X$ -valley and  $L$ -valley electron masses, Luttinger parameters, and hole masses.

Qiang *et al.* have derived a hydrostatic deformation potential of  $a = -10.6$  to  $-10.85$  eV for  $x=0.22$ .<sup>422</sup> However, the same authors obtained a much smaller value of  $a = -8.6$  eV for  $x=0.27$ . The latter result is in good agreement with a linear interpolation between the GaAs and AlAs values ( $a = -8.3$  eV, in this case). A linear dependence of the shear deformation potentials on composition was suggested by the ellipsometry study of exciton splittings and

TABLE XII. Nonzero bowing parameters for AlGaAs.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	$-0.127 + 1.310x$	$-0.127 - 1.183$
$E_g^X$	0.055	0.055–0.245
$E_g^L$	0	0–0.055
$\Delta_{so}$	0	0–0.147



shifts by Logothetidis *et al.*,<sup>153</sup> although their best fit was obtained for a slightly smaller value of  $b$  in GaAs than we recommend in Table I. The relative paucity of deformation-potential data for this important alloy is due in no small part to the very property that is one of its greatest attractions, namely its excellent lattice match to GaAs that renders strain effects on the band structure rather insignificant.

The recommended bowing parameters for AlGaAs are collected in Table XII. In those cases where no value is listed, linear variation should be assumed.

## 2. GaInAs

The GaInAs alloy is a key component in the active regions of high-speed electronic devices,<sup>423</sup> infrared lasers,<sup>424</sup> and long-wavelength quantum cascade lasers.<sup>425</sup> It remains a direct-gap material over its entire composition range. While bowing parameters spanning the wide range 0.32–0.6 eV have been reported,<sup>101,166,201,410,426–434</sup> the most recent and seemingly most reliable values lie within the more restricted vicinity of 0.45–0.5 eV. It has also been proposed that the bowing depends on temperature, being almost flat below 100 K and decreasing rapidly at higher temperatures.<sup>434</sup> Owing to the spread in values, we have fixed our recommended  $\text{Ga}_{1-x}\text{In}_x\text{As}$  bowing parameter by emphasizing the fit at the important  $x=0.53$  alloy that is lattice matched to InP. The fundamental energy gap of  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$  has been studied extensively, e.g., by absorption,<sup>435,436</sup> magnetoabsorption,<sup>437</sup> photoluminescence,<sup>430,438,439</sup> and photoconductivity experiments.<sup>440</sup> On the basis of low-temperature results ranging from 810 to 821 meV, we choose a composite average of  $E_g(T=0)=816\text{ meV}$ , which in turn implies a bowing parameter  $C=0.477\text{ eV}$ . This is quite close to the recent determinations of Paul *et al.* (0.475 eV),<sup>431</sup> Karachevtseva *et al.* (0.486 eV),<sup>434</sup> Kim *et al.* (0.479 eV),<sup>433</sup> and Jensen *et al.*<sup>441</sup> This bowing parameter also agrees well with photoreflectance measurements on GaAs-rich GaInAs by Hang *et al.*<sup>442</sup> We choose to assume that the bowing is temperature independent,<sup>431</sup> in disagreement with Karachevtseva *et al.*,<sup>434</sup> because the room-temperature gap implied by that  $C(T)$  is higher than nearly all experimental values.<sup>438,439,443</sup> The composition dependence of the Varshni parameters obtained in this manner is in good agreement with the functional form of Karachevtseva *et al.*<sup>434</sup>

Bowing parameters for the indirect energy gaps were calculated by Porod and Ferry<sup>428</sup> using a modified virtual crystal approximation. That study predicts large bowing parameters for both  $E_g^X(1.4\text{ eV})$  and  $E_g^L(0.72\text{ eV})$ .<sup>166</sup> Tiwari and Frank<sup>432</sup> give a much different set:  $C(E_g^X)=0.08\text{ eV}$  and  $C(E_g^L)=0.5\text{ eV}$ . The only reliable experimental result appears to be a determination of  $E_g^L$  in  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$ .<sup>444</sup> That study supports a lower value for the bowing parameter. The experimental and theoretical bowing parameters for the split-off gap have been reported by Vishnubhatla *et al.*,<sup>426</sup> Van Vechten *et al.*,<sup>445</sup> and Berolo *et al.*<sup>446</sup> These are in reasonably good agreement with the electrophotoluminescence measurement of Perea *et al.*<sup>443</sup> for  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$ , and imply  $C(\Delta_{so})=0.15\text{ eV}$ .

The electron effective mass in GaInAs has been studied both theoretically and experimentally.<sup>171,172,446,447</sup> As in the

TABLE XIII. Nonzero bowing parameters for GaInAs.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	0.477	0.32–0.46
$E_g^X$ (eV)	1.4	0.08–1.4
$E_g^L$ (eV)	0.33	0.33–0.72
$\Delta_{so}$ (eV)	0.15	0.15–0.20
$m_e^*$ ( $\Gamma$ )	0.0091	...
$m_{hh}^*(001)$	–0.145	...
$m_{lh}^*(001)$	0.0202	...
$\gamma_3 - \gamma_2$	0.481	...
$E_p$ (eV)	–1.48	...
$F$	1.77	...
VBO (eV)	–0.38	...
$a_c$ (eV)	2.61	...

case of the energy gap, the most reliable data are for  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$  lattice matched to InP. While early studies proposed  $m_e^*=0.041m_0$ ,<sup>443,448–452</sup> and even smaller values,<sup>453</sup> more recent experiments in strong magnetic fields have suggested that the polaron effective mass is in fact higher.<sup>440</sup> That agrees with modeling of the diamagnetic shift of the exciton absorption peaks in  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}/\text{InP}$  quantum wells.<sup>454,455</sup> In recent years, evidence has accumulated favoring a low-temperature value of  $m_e^*=0.043m_0$ .<sup>447,456–458</sup> This result implies the presence of bowing if the electron mass is interpolated directly using an expression similar to Eq. (4.1). Application of the more general approach using Eq. (2.15) in conjunction with interpolated values for the interband matrix element and the  $F$  parameter is discussed below. Since no reliable data on the bowing parameters for the  $X$ - and  $L$ -valley electron masses appear to exist, we suggest linear interpolation.

For  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$ , Alavi *et al.*<sup>437</sup> suggested the set of Luttinger parameters:  $\gamma_1=11.01$ ,  $\gamma_2=4.18$ ,  $\gamma_3=4.84$ . Those values are in good agreement with the light-hole masses derived from spin-polarized photoluminescence measurements by Hermann and Pearsall,<sup>459</sup> and with cyclotron resonance experiments.<sup>460</sup> On the other hand, Sugawara *et al.*<sup>455</sup> obtained a much larger light-hole mass, although with considerable spread in the results. We suggest that the bowing parameters for the hole effective masses should be consistent with the results of Alavi *et al.*<sup>437</sup> The split-off hole mass should be interpolated linearly.

Most studies have employed an interband matrix element of  $E_p=25.3\text{ eV}$  for  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$ ,<sup>437,448,453,459</sup> although Zielinski *et al.*<sup>436</sup> derived a much smaller value from an analysis of absorption spectra. The former value is much more consistent with the matrix elements employed for GaAs and InAs (see above), and implies only a small  $E_p$  bowing parameter. The bowing of  $F$  is then obtained using the already-derived relations for the energy gap and the effective mass.

The hydrostatic deformation potential in  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}$  was measured by People *et al.*<sup>461</sup> to be  $a=-7.79\text{ eV}$ . A reduction in  $a$  was also observed by Wilkinson *et al.*<sup>462</sup> in a study of GaInAs strained to a GaAs substrate. These results indicate some bowing in the hydrostatic deformation poten-

tial, which we ascribe to a nonlinear shift of the conduction band edge.<sup>4</sup>

The recommended nonzero bowing parameters for GaInAs are collected in Table XIII.

### 3. AlInAs

AlInAs serves as the barrier layer in the important Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As heterostructure system that is lattice matched to InP. For this reason, the most precise band gap determinations are available for Al<sub>1-x</sub>In<sub>x</sub>As with the  $x = 0.52$  composition. While Matyas reported a  $\Gamma$ -valley bowing parameter of 0.24 eV for  $x < 0.7$  on the basis of absorption measurements,<sup>463</sup> theoretical work indicated that it should be larger.<sup>201,418</sup> Wakefield *et al.*<sup>464</sup> reported a value of 0.74 eV based on cathodoluminescence spectroscopy data. Similar results were recently obtained by Kopf *et al.*,<sup>465</sup> and were also recommended in several compilations of bowing parameters.<sup>101,432</sup> With the inclusion of strain effects, the temperature-dependent band gap of Al<sub>0.46</sub>In<sub>0.54</sub>As on InP reported by Abraham *et al.* implies a bowing parameter of  $\approx 0.66$  eV.<sup>466</sup> We select a composite value of  $C = 0.70$  eV to reflect the majority of these results.

In contrast to GaInAs, the X conduction valley is lower than the  $\Gamma$  valley in AlAs-rich Al<sub>x</sub>In<sub>1-x</sub>As. Linear interpolations are usually employed to obtain the X-valley and L-valley minima in AlInAs. That approximation implies that the X and  $\Gamma$  valleys should cross at a composition of  $x = 0.64$ , which is slightly lower than the early experimental result of  $x = 0.68$  by Lorenz and Onton.<sup>467</sup> Since the larger crossover composition would require a negative bowing parameter for the X-valley gap, we recommend  $C = 0$ . Krijn<sup>101</sup> gave a bowing parameter of 0.15 eV for the spin-orbit splitting, which is equal to the GaInAs value adopted in the previous subsection.

Optically detected cyclotron resonance measurements have yielded  $m_e^* = 0.10 \pm 0.01 m_0$  for Al<sub>0.48</sub>In<sub>0.52</sub>As.<sup>468</sup> On the other hand, Cury *et al.*<sup>457</sup> obtained a much smaller mass of  $0.069 m_0$ , which is only a little lower than extrapolations from GaInAs-rich AlGaInAs.<sup>456,465</sup> The smaller result is supported by the cyclotron-resonance measurements of Chen *et al.*<sup>469</sup> Calculations by Shen and Fan<sup>470</sup> also indicate an effective mass of  $\approx 0.075 m_0$ . The reasonably good agreement of all but one result allows us to suggest a  $\Gamma$ -valley effective mass bowing parameter for AlInAs. In view of the lack of hard data, we recommend linear interpolation for the other masses in the AlInAs alloy.

In order to explain the electron effective mass in AlGaInAs quaternaries, Fan and Chen introduced a disorder-induced conduction-valence band mixing. They found that an interband matrix element of 22.5 eV was necessary to account for the experimental results. This value of  $E_p$  requires  $F = -0.63$  for consistency. We have derived bowing parameters for AlInAs employing this system of values, although it should be noted that the results depend sensitively on the electron effective mass adopted for Al<sub>0.48</sub>In<sub>0.52</sub>As.<sup>458</sup>

The hydrostatic deformation potential for  $x = 0.52$  was measured by Ferguson *et al.*<sup>471</sup> to be  $a = -6.7$  eV, which falls between the values adopted for InAs ( $-6.1$  eV) and AlAs ( $-8.1$  eV). On the other hand, Yeh *et al.*<sup>472</sup> obtained a

TABLE XIV. Nonzero bowing parameters for AlInAs.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	0.70	0.24–0.74
$E_g^X$ (eV)	0	–0.5–0
$\Delta_{so}$ (eV)	0.15	...
$m_e^*$ ( $\Gamma$ )	0.049	...
$E_p$ (eV)	–4.81	...
$F$	–4.44	...
VBO (eV)	–0.64	...
$a_c$ (eV)	–1.4	...

valence-band deformation potential opposite in sign from the trend predicted by the model-solid theory of Van de Walle.<sup>129</sup> That result would imply a considerable bowing parameter even within the  $a_v$  theory presented by Wei and Zunger.<sup>42</sup> Pending further confirmation, we recommend linear interpolation.

The recommended nonzero bowing parameters for AlInAs are collected in Table XIV.

## B. Phosphides

### 1. GaInP

The GaInP alloy exhibits some of the largest direct gaps among the non-nitride III–V semiconductors. Furthermore, Ga<sub>0.51</sub>In<sub>0.49</sub>P ( $E_g = 1.9$  eV at 300 K) is lattice matched to GaAs, which makes it an attractive material for wide-gap GaAs-based quantum well devices such as red diode lasers.<sup>473</sup> This application has spurred extensive studies of the band structure characteristics of GaInP, which are at present rather well known.

For the  $\Gamma$ -valley band gap, early photoluminescence and cathodoluminescence determinations yielded bowing parameters ranging from 0.39 to 0.76 eV.<sup>467,474–478</sup> Subsequent electroreflectance and modulation spectroscopy studies favored a value near the higher end of that range.<sup>479–481</sup> Theoretical studies have also produced a wide range of bowing parameters,<sup>101,201,410,418,482</sup> with the most reliable results clustered around 0.5–0.75 eV. By analogy to GaInAs and AlInAs, it is useful to consider the Ga<sub>0.51</sub>In<sub>0.49</sub>P alloy for which the most extensive data are available. Unfortunately, a precise measurement for this lattice-matched alloy is somewhat complicated by its proximity to the indirect crossover point, and by long-range ordering of the group-III atoms which can take the form of a monolayer InP–GaP superlattice along the [111] direction.<sup>483–486</sup> The ordering-induced reduction of the direct energy gap can be on the order of 100 meV.<sup>487</sup> Low-temperature band gaps of 1.969–2.018 eV have been reported for random GaInP alloys that are nominally lattice matched to GaAs.<sup>488–494</sup> Using the result of Emanuelsson *et al.*,<sup>495</sup> corrected for the exciton binding energy of 8 meV,<sup>493</sup> we obtain a recommended bowing parameter of  $C = 0.65$  eV. That value is consistent with recent data for nonlattice-matched compositions.<sup>496,497</sup>

The X-valley gap energies in InP and GaP are nearly equal (2.38 and 2.35 eV, respectively, at 0 K), and the  $\Gamma$ –X crossover composition in GaInP is believed to be close to  $x = 0.7$ .<sup>479</sup> Although early work usually assumed a linear

TABLE XV. Nonzero bowing parameters for GaInP.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	0.65	0.39–0.76
$E_g^X$ (eV)	0.20	0–0.35
$E_g^L$ (eV)	1.03	0.23–0.86
$\Delta_{so}$ (eV)	0	–0.05–0
$m_e^*$ ( $\Gamma$ )	0.051	...
$F$	0.78	...
$d$ (eV)	0	0–2.4

variation of the X-valley gap, Auvergne *et al.* have more recently suggested  $C(E_g^X)=0.147$  eV on the basis of piezoreflectance spectroscopy in the composition range near the crossover point. Somewhat larger bowing parameters are implied by the pressure experiments of Goni *et al.*<sup>496</sup> and Meney *et al.*<sup>498</sup> Our recommended value of  $C(E_g^X)=0.2$  eV agrees with other experimental and theoretical results.<sup>482</sup> Early experimental and theoretical determinations of the bowing parameter for the L-valley gap were summarized by Bugajski *et al.*<sup>482</sup> The  $\Gamma$ –L crossover most likely occurs at  $x$  slightly smaller than the  $\Gamma$ –X crossover point,<sup>480</sup> which makes L the lowest conduction valley for  $x$  greater than  $\approx 0.67$ . Krutogolov *et al.*<sup>499</sup> suggested  $C(E_g^L)=0.71$  eV, although that article assumed L-valley indirect band gaps in the end-point binaries that are considerably different from the ones adopted here. Modeling of the ellipsometric and thermoreflectance data of Ozaki *et al.*<sup>500</sup> yielded  $E_g^L=2.25$  eV in  $\text{Ga}_{0.5}\text{In}_{0.5}\text{P}$  at 300 K, which favors a small L-valley bowing. In deriving our recommended bowing parameter, we employed the  $\Gamma$ –L crossover point of  $x=0.67$ ,<sup>482,499</sup> which was confirmed recently by Interholinger *et al.*<sup>501</sup> The bowing of the spin-orbit splitting in GaInP is known to be very small,<sup>446,476,479</sup> with recent results<sup>502</sup> implying a linear interpolation to within experimental uncertainty.

The electron effective mass in a random alloy with  $x=0.5$  was measured by Emanuelsson *et al.*<sup>495</sup> to be  $m_e^*=0.092m_0$ , which is somewhat lower than the linearly interpolated values quoted in other papers.<sup>473,490</sup> Similar results were obtained by Wong *et al.*<sup>503</sup> In the absence of reliable data for the other electron and hole masses, linear interpolation is advised using the scheme outlined above. With a linearly interpolated value of  $E_P=26$  eV for the interband matrix element in  $\text{Ga}_{0.5}\text{In}_{0.5}\text{P}$ , we derive an  $F$  parameter of  $-1.48$ , and from it the corresponding bowing.

The shear deformation potential  $d$  was measured for GaInP grown on GaAs(111)*B* substrates.<sup>504</sup> While the results imply a bowing parameter of 2.4 eV, the large uncertainties in existing determinations make it difficult to conclusively prefer this value over a linear interpolation.

The recommended nonzero bowing parameters for GaInP are collected in Table XV.

## 2. AlInP

$\text{Al}_x\text{In}_{1-x}\text{P}$  has a direct energy gap for  $x<0.44$ , and at the crossover composition the  $\Gamma$ -valley value of  $E_g^\Gamma \approx 2.4$  eV is the largest of any non-nitride direct-gap III–V

TABLE XVI. Nonzero bowing parameters for AlInP.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	–0.48	–0.48–0.38
$E_g^X$ (eV)	0.38	...
$\Delta_{so}$ (eV)	–0.19	...
$m_e^*$ ( $\Gamma$ )	0.22	...

semiconductor.<sup>2</sup> For a precise determination of the bowing parameter, it is convenient to consider compositions close to  $\text{Al}_{0.52}\text{In}_{0.48}\text{P}$ , which is lattice-matched to GaAs. However, the inherent difficulty of experimentally determining  $E_g^\Gamma$  in close proximity to the indirect-gap transition caused underestimates by some workers. Bour *et al.*<sup>203</sup> obtained 0.38 eV for the direct-gap bowing parameter from relatively early electoreflectance measurements. Mowbray *et al.*<sup>505</sup> reported a low-temperature direct excitonic gap of 2.680 eV for the lattice-matched composition, which implies a negative  $C$ . This result was supported by the work of Dawson *et al.*<sup>506,507</sup> and by the ellipsometry experiments of Adachi *et al.*<sup>502</sup> and Schubert *et al.*<sup>508</sup> In fact, a direct gap of 2.69 eV for  $\text{Al}_{0.52}\text{In}_{0.48}\text{P}$  at 0 K (corrected for the exciton binding energy) must be considered a better-established value than the 3.63 eV gap for AlP (see above). However, instead of extrapolating the AlInP gap to the AlP binary, we recommend using a negative bowing parameter of  $C=-0.48$  eV, while noting that considerable uncertainty exists for large  $x$ .

For  $\text{Al}_{0.52}\text{In}_{0.48}\text{P}$ , indirect X-valley gaps of 2.34–2.36 eV have been deduced from a variety of optical measurements.<sup>500,505,507</sup> Taking into account the correction for the exciton binding energy (a rough estimate insofar as precise values have not been calculated), a bowing parameter  $C(E_g^X)=0.38$  eV is deduced. Few data are available for the position of the L-valley minimum in AlInP, although a room-temperature value of  $E_g^L=2.7$  eV is given by Ozaki *et al.*<sup>500</sup> Since that implies at most a very small bowing parameter, linear interpolation is recommended. The spin-orbit splitting in  $\text{Al}_{0.5}\text{In}_{0.5}\text{P}$  is thought to be 135 meV,<sup>502,509</sup> which translates into an upward bowing of 0.19 eV. No direct experimental determinations of the effective masses in AlInP appear available, although various estimates put the  $\Gamma$ -valley electron mass close to  $0.11m_0$ .<sup>509,510</sup>

The recommended nonzero bowing parameters for AlInP are collected in Table XVI.

## 3. AlGaP

The “exotic” AlGaP alloy has an indirect band gap throughout its composition range.<sup>202</sup> The lowest-energy optical transitions are typically associated with donor or acceptor impurities. Linear interpolation of the indirect X-valley gap was found to give good agreement with photolumines-

TABLE XVII. Nonzero bowing parameters for AlGaP.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0	0.0–0.49
$E_g^X$	0.13	0–0.13



cence spectra, once impurity and phonon band transitions were carefully separated from the interband transitions.<sup>202,511</sup> The direct gap in AlGaP was studied by Rodriguez *et al.*<sup>512,513</sup> Using a limited number of data points, the authors concluded that either a linear variation or a quadratic variation with a bowing parameter of 0.49 eV were consistent with the data. As in the case of AlInP, extrapolation to AIP gives a value for  $E_g^\Gamma$  that is somewhat higher than the value listed in Table V for the binary (also based on limited data). Recent cathodoluminescence experiments support a small bowing of 0.13 eV for the lowest X-valley gap in AlGaP.<sup>514</sup>

We recommend that a linear variation be assumed for all other band structure parameters of AlGaP (see Table XVII).

## C. Antimonides

### 1. GaInSb

Although GaInSb cannot by itself be lattice matched to any of the readily available substrates, it serves as the hole quantum well material in type-II infrared lasers<sup>155</sup> and photodetectors<sup>515</sup> with strain-balanced active regions. A number of experimental<sup>243,260,426</sup> and theoretical<sup>410,516</sup> studies of the direct band gap in GaInSb have been published. The different reports, which are generally in excellent agreement with each other, support a bowing parameter of 0.415 eV. Negligible dependence of the bowing parameter on temperature was obtained using the photovoltaic effect,<sup>259</sup> whereas the pseudopotential calculations of Bouarissa and Aourag<sup>517</sup> suggested a slow variation from 0.43 at 0 K to 0.415 at room temperature.

Bowing parameters for the X- and L-valley gaps were estimated by Adachi<sup>166</sup> and Glisson *et al.*<sup>201</sup> The method employed by Adachi is rather indirect, in that an average of the bowing for two direct critical points is used to represent the bowing of the indirect gap. Nonetheless, in the absence of experimental data for the X-valley gap, it appears to be the best available approximation. The pseudopotential calculations of Bouarissa *et al.*<sup>516</sup> yielded very weak bowing of the two indirect gaps. This finding is in apparent contradiction with the limited data of Lorenz *et al.*,<sup>518</sup> which suggest a smaller L-valley gap for GaInSb than that for GaSb (no estimate of the L-valley gap in InSb was available at the time, so the article assumed a linear variation with composition). Also, the data presented in clear form by Zitouni *et al.*,<sup>519</sup> which cover only part of the composition range, indicate appreciable bowing for both the X and L valleys. We conclude that the considerable uncertainty for the indirect gaps in GaSb and especially InSb translates into a poor understanding of the indirect-gap bowing in GaInSb. We recommend using bowing parameters of 0.33 and 0.4 eV for the X-valley and L-valley gaps, respectively, which are near the top of the reported range. A small bowing parameter of 0.1 eV was found for the spin-orbit splitting in GaInSb.<sup>243,260</sup>

A small bowing of the electron effective mass in the  $\Gamma$  valley has been determined both experimentally and theoretically.<sup>260,446</sup> Roth and Fortin<sup>243</sup> compiled results from a number of references, from which Levinshtein *et al.*<sup>11</sup> deduced a bowing parameter of  $0.0092m_0$ . We assume a linear

TABLE XVIII. Nonzero bowing parameters for GaInSb.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	0.415	0.36–0.43
$E_g^X$ (eV)	0.33	–0.14–0.33
$E_g^L$ (eV)	0.4	0.093–0.6
$\Delta_{so}$ (eV)	0.1	0.06–0.72
$m_e^*$ ( $\Gamma$ )	0.0092	...
$m_{lh}^*$ (001)	0.011	...
$F$	–6.84	...

variation of the interband matrix element and determine the  $F$  bowing parameter from that assumption. Linear interpolation is also suggested for the heavy-hole and split-off hole masses. Levinshtein *et al.*<sup>11</sup> give a large bowing of the light-hole mass, in agreement with the band structure model of Auvergne *et al.*<sup>260</sup> Since the light-hole masses in InSb and GaSb are only a little larger than the electron masses, it follows that the bowing should be similar in the two cases. While considerably larger masses were reported by Barjon *et al.*<sup>520</sup> on the basis of a model of their galvanomagnetic measurements, the bowing parameter for light holes is chosen to be consistent with the results of Roth and Fortin.<sup>243</sup>

The recommended nonzero bowing parameters for GaInSb are collected in Table XVIII.

### 2. AlInSb

While not widely used, AlInSb provides a convenient strain-compensating barrier material for mid-IR interband cascade lasers<sup>521</sup> and other antimonide device structures. Early absorption measurements of Agaev and Bekmedova<sup>522</sup> yielded a linear variation of the direct energy gap with composition. However, that result was discounted<sup>1,2</sup> in favor of the electoreflectance determination of  $C=0.43$  eV by Isomura *et al.*,<sup>523</sup> which is in good agreement with the empirical curve charting the increase of the bowing parameter with lattice mismatch between the binary constituents.<sup>201</sup> While Dai *et al.*<sup>524</sup> recently found a linear variation of the direct energy gap with alloy lattice constant (i.e., composition) for InSb-rich AlInSb, those results were confined to a relatively small range of compositions and as such were conceivably not sensitive enough to the quadratic bowing term. Since the electoreflectance measurements should have been more precise than the absorption experiments of Agaev and Bekmedova, we recommend use of the bowing parameter determined by Isomura *et al.*<sup>523</sup>

The only other band structure parameter whose composition dependence has been studied is the spin-orbit splitting. Isomura *et al.*<sup>523</sup> deduced a relatively strong bowing of  $C=0.25$  eV in the split-off gap. The recommended nonzero bowing parameters for AlInSb are collected in Table XIX.

TABLE XIX. Nonzero bowing parameters for AlInSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0.43	0–0.43
$\Delta_{so}$	0.25	...



TABLE XX. Nonzero bowing parameters for AlGaSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	$-0.044 + 1.22x$	$-1.18-0.69$
$E_g^X$	0	$0-0.48$
$E_g^L$	0	$0.21-0.754$
$\Delta_{so}$	0.3	...

### 3. AlGaSb

AlGaSb is an important material employed in high-speed electronic<sup>525</sup> and infrared optoelectronic<sup>526</sup> devices. Apart from a considerably larger lattice mismatch, the GaSb/AlGaSb heterostructure is a lower-gap analog of the GaAs/AlGaAs material system. The band structure in AlGaSb was originally studied by piezomodulation, and bowing parameters of 0.69 and 0.48 eV were proposed for the  $\Gamma$ -valley and X-valley gaps, respectively.<sup>251</sup> A much more comprehensive investigation was carried out by Alibert *et al.*,<sup>236</sup> who incorporated the results of many other reports. They obtained direct-gap bowing parameters of 0.48 and 0.47 eV at low temperatures and room temperature, respectively, values that have been used by many subsequent workers.<sup>255,527</sup> However, recently Bignazzi *et al.*<sup>254</sup> obtained a better fit to the absorption spectra by assuming a linear band gap variation at low Al mole fractions. Those results were confirmed by thermoreflectance spectroscopy performed by Bellani *et al.*<sup>528</sup> Consequently, a cubic band gap variation was proposed for the direct gap of  $\text{Al}_x\text{Ga}_{1-x}\text{Sb}$ :  $C = -0.044 + 1.22x$ , which produces little deviation from linearity at small  $x$  but also bowing parameters in the range suggested by Mathieu *et al.*<sup>251</sup> and Alibert *et al.*<sup>236</sup> in the middle of the composition range (with the inflection point at  $x=0.35$ ). In spite of the fact that only  $x < 0.5$  alloys were investigated in that article, it must be considered to be the most reliable study to date.

Although there was an early indication of appreciable X-valley bowing,<sup>251</sup> later reports have established that it is quite small or nonexistent.<sup>2,236</sup> L-valley gap bowing parameters ranging from 0.21 to 0.75 eV are encountered in the literature.<sup>2,236,527,528</sup> The  $\Gamma$ -L crossover composition is quite sensitive to the exact choice of the bowing parameters, owing to the proximity of the two valleys in both GaSb and AlSb. Crossover compositions of  $x=0.27$  and  $x=0.23$  were determined on the basis of photoluminescence measurements<sup>529</sup> and from wavelength-modulated absorption spectra,<sup>2</sup> respectively. If those crossover points are to be consistent with our choice for the direct gap's dependence on composition, we must choose a very weak L-valley bowing. Therefore, we recommend  $C(E_g^L)=0$  and note that with this choice the bowing in AlGaSb becomes rather similar to the case of AlGaAs covered above. A bowing parameter of 0.3 eV was deduced by Alibert *et al.*<sup>236</sup> for the spin-orbit splitting.

For electron effective masses in the AlGaSb alloy, it is recommended that the procedure outlined in the AlGaAs section be followed. That is, any nonlinearity in the composition dependence of the effective mass stems entirely from the bowing of the energy gap.<sup>251,527</sup> This is expected to give

TABLE XXI. Nonzero bowing parameters for GaAsSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	1.43	$1.0-1.44$
$E_g^X$	1.2	...
$E_g^L$	1.2	...
$\Delta_{so}$	0.6	$0.1-0.61$
VBO	-1.06	...

better results than using the Landolt-Bornstein bowing parameter<sup>1</sup> or interpolating linearly between the masses in GaSb and AlSb.

The recommended nonzero bowing parameters for AlGaSb are collected in Table XX.

## D. Arsenides antimonides

### 1. GaAsSb

$\text{GaAs}_{1-x}\text{Sb}_x$  is most often encountered with the  $x=0.5$  composition that matches the lattice constant of InP, although it should also be noted that at  $x=0.91$  is lattice matched to InAs. Direct-gap bowing parameters in the range 1.0–1.2 eV have been determined by a number of workers from absorption measurements.<sup>530–535</sup> It was noted in the first study<sup>536</sup> of epitaxial  $\text{GaAs}_{0.5}\text{Sb}_{0.5}$  on InP in 1984 that the apparent band gap of 0.804–0.807 eV was smaller than that implied by previously determined bowing parameters.<sup>537–539</sup> Recently, a low-temperature  $E_g^\Gamma$  of 0.813 eV was measured by Merkel *et al.*<sup>540</sup> and Hu *et al.*,<sup>541</sup> and its temperature dependence was obtained. Those results implied a bowing parameter of 1.42–1.44 eV, although it was suggested that ordering effects may have reduced the band gap.<sup>537</sup> A low-temperature bowing parameter of 1.3 eV was determined for  $\text{GaAs}_{0.09}\text{Sb}_{0.91}$  lattice matched to InAs,<sup>542</sup> and quite recently a bowing parameter of 1.41 eV was obtained by Ferrini *et al.*<sup>543</sup> from ellipsometry and photoreflectance studies. Since different growth temperatures were employed in recent studies of  $\text{GaAs}_{1-x}\text{Sb}_x$  with a rather small range of compositions near  $x \approx 0.5$ , the evidence for ordering is inconclusive at present. We recommend a bowing parameter of 1.43 eV, although this value should be revised downward if additional investigations substantiating the partial ordering in GaAsSb with compositions close to a lattice match with InP become available.

Rough estimates of the bowing parameters for the X-valley and L-valley gaps (both 1.09 eV) have been published by Adachi.<sup>166</sup> We recommend slightly higher values, in order to assure consistency with both the experimental crossover points and the larger adopted direct-gap bowing parameter. L-gap and X-gap bowing parameters of 1.1–1.2 eV are consistent with the reported measurements.<sup>11</sup> On the basis of rather limited data, Mani *et al.*<sup>542</sup> suggested a bowing parameter of 0.1 eV for the spin-orbit splitting in GaAsSb. On the other hand, theoretical studies<sup>101,166</sup> have derived a considerably larger value of 0.6 eV, which we recommend.

The composition dependence of the GaAsSb effective mass was determined by Delvin *et al.*<sup>544</sup> Although they pro-

posed a bowing parameter of  $0.0252m_0$ , the room-temperature GaSb mass obtained in that study was significantly higher than our recommendation based on a consensus of other data. A safer procedure is to take the mass nonlinearity to arise from the band gap bowing as outlined above.

The recommended nonzero bowing parameters for GaAsSb are collected in Table XXI.

## 2. InAsSb

The InAsSb alloy has the lowest band gap among all III–V semiconductors, with values as small as 0.1 eV at room temperature. For that reason, it is an important material for a variety of mid-infrared optoelectronic devices, including lasers<sup>545</sup> and photodetectors.<sup>546</sup> Initial reports put the direct-gap bowing parameter in InAsSb at 0.58–0.6 eV.<sup>160,161,426,547</sup> Those studies were performed at temperatures above or near 100 K, and gaps were extrapolated to lower temperatures in a linear fashion. It is now understood that this resulted in an overestimate of the low-temperature energy gap and an underestimate of the bowing parameter. Theoretical considerations led to a higher projected bowing parameter of 0.7 eV,<sup>410</sup> which is recommended by Rogalski and Jozwikowski.<sup>548</sup> This estimate was revised to  $C = 0.65$  eV by a more accurate pseudopotential calculation,<sup>549</sup> while Bouarissa *et al.*<sup>516</sup> computed an even smaller value. More recent photoluminescence studies on MBE-grown InAsSb obtained  $C = 0.67$ – $0.69$  eV.<sup>164,261,550</sup> Similar results (e.g.,  $C = 0.64$  eV) were obtained by Gong *et al.*<sup>551,552</sup> from measurements on a sequence of InAs-rich samples. Elies *et al.*<sup>553</sup> obtained Varshni parameters for InAs<sub>0.91</sub>Sb<sub>0.09</sub>, and suggested a temperature dependence of the bowing parameter based on those results. The possible importance of ordering has been discussed in several recent works (Wei and Zunger,<sup>554</sup> Kurtz *et al.*,<sup>555</sup> Marciniak *et al.*<sup>556</sup>). Smaller than expected band gaps were obtained for compositions close to the lattice-matching condition on GaSb ( $x = 0.09$ ).<sup>557</sup> On the basis of all these investigations, we recommend a composite bowing parameter of 0.67 eV. Currently, the bowing parameters for both the  $X$ -valley and  $L$ -valley gaps are both thought to be  $\approx 0.6$  eV.<sup>166,201,516</sup>

Experimental and theoretical data for the composition dependence of the spin-orbit splitting in InAsSb were collected by Berolo *et al.*,<sup>446</sup> who suggest a bowing parameter of 1.1–1.2 eV. The estimated<sup>558</sup> spin-orbit splitting of 0.325 eV in InAs<sub>0.91</sub>Sb<sub>0.09</sub> (lattice matched to GaSb) implies a similar bowing parameter of 1.26 eV.

Plasma reflectance and other measurements of the electron effective mass in InAsSb were summarized by Thomas and Woolley.<sup>171</sup> The best fit to the data collected in that article favored a mass of  $0.0103m_0$  for the alloy with the smallest direct gap (InAs<sub>0.4</sub>Sb<sub>0.6</sub>). That result agreed well with the theory developed by Berolo *et al.*<sup>446</sup> While magneto-optical measurements by Kuchar *et al.* indicated an extrapolated band edge electron mass of  $0.0088m_0$  for InAs<sub>0.145</sub>Sb<sub>0.855</sub>, which corresponds to a larger mass bowing, that finding is inconsistent with a linear interpolation of the interband matrix elements and  $F$  parameters between InAs and InSb, and also disagrees with the model of Rogalski and Jozwikowski.<sup>548</sup> A recent report of the electron effective

TABLE XXII. Nonzero bowing parameters for InAsSb.

Parameters	Recommended values	Range
$E_g^\Gamma$ (eV)	0.67	0.58–0.7
$E_g^X$ (eV)	0.6	...
$E_g^L$ (eV)	0.6	0.55–0.8
$\Delta_{so}$ (eV)	1.2	...
$m_e^*(\Gamma)$	0.035	0.03–0.055

mass in InAsSb is from a cyclotron resonance measurement by Stradling *et al.*<sup>184</sup> for two alloy compositions. Their measurements appear to support a smaller mass bowing as well as negative bowing for the interband matrix element, although a great deal of uncertainty is inherent in assigning a value based on two data points. Our recommended bowing parameter for the electron effective mass is  $0.035m_0$ , which is near the bottom of the reported range and roughly consistent with the results of assuming the mass bowing to be caused entirely by band gap bowing.

The recommended nonzero bowing parameters for InAsSb are collected in Table XXII.

## 3. AlAsSb

AlAsSb is a versatile large-gap barrier material that can be lattice matched to InP, InAs, or GaSb substrates. Whereas many workers assume a linear variation of the direct energy gap in AlAsSb,<sup>559</sup> theoretical projections indicate a bowing parameter in the 0.72–0.84 eV range.<sup>101,201</sup> The little experimental information that is available on AlAsSb alloys lattice matched to GaSb<sup>560</sup> and InP<sup>561</sup> can be interpreted to support either a small ( $\approx 0.25$  eV)<sup>560</sup> or a large ( $\approx 0.8$  eV)<sup>561</sup> value. We recommend the latter, but also note that the uncertainty may not greatly affect most quantum heterostructures calculations in view of the large absolute value of the gap. Bowing parameters for the two indirect gaps are both chosen to be 0.28 eV in accordance with photoluminescence and electroluminescence measurements, the results of which have been summarized by Ait Kaci *et al.*<sup>560</sup> The bowing parameter for the spin-orbit splitting (0.15 eV) is taken from the theoretical estimate of Krijn.<sup>101</sup>

The recommended nonzero bowing parameters for AlAsSb are collected in Table XXIII.

## E. Arsenides phosphides

### 1. GaAsP

GaAs<sub>1-x</sub>P<sub>x</sub> is a wide-band gap alloy that is often employed in red LEDs.<sup>562</sup> The alloy becomes indirect for  $x > 0.45$  (at 0 K)<sup>482</sup> when the  $X$  valley minimum crosses below

TABLE XXIII. Nonzero bowing parameters for AlAsSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0.8	0–0.84
$E_g^X$	0.28	...
$E_g^L$	0.28	...
$\Delta_{so}$	0.15	...
VBO	–1.71	...

TABLE XXIV. Nonzero bowing parameters for GaAsP.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0.19	0.174–0.21
$E_g^X$	0.24	0.20–0.28
$E_g^L$	0.16	0.16–0.25

the  $\Gamma$  valley minimum. Most experimental results for the direct-gap bowing parameter lie within a relatively narrow range, 0.175–0.21 eV.<sup>93,426,467,482,562–565</sup> A small bowing parameter is also expected on theoretical grounds, for both the direct and indirect gaps.<sup>191</sup> However, it has been noted that the bowing parameter more than doubles if CuPt-like ordering sets in.<sup>566</sup> While a recent ellipsometry study of disordered GaAsP alloys produced a direct-gap bowing parameter of 0.54 eV,<sup>567</sup> that outlying result lacks other verification and relied on only two data points with intermediate  $x$ . We therefore assume that either it was anomalous or some ordering did occur. Since a meaningful temperature dependence cannot be extracted from the existing data, we recommend  $C = 0.19$  eV for the direct gap at all temperatures. This is somewhat higher than the value suggested by Aspnes,<sup>93</sup> partly because we employ a larger band gap for GaP at 77 K.

The X-valley gap bowing parameter was studied by a number of workers.<sup>93,482,562,568,569</sup> Again, there is not much controversy since the crossover composition is rather well established. Our recommended value ( $C = 0.24$  eV) lies approximately in the middle of the reported range of 0.20–0.28 eV. Both experimental and theoretical results for the L-valley bowing parameter imply  $C = 0.16$  eV.<sup>93,482</sup> The spin-orbit splitting was found to vary linearly with composition.<sup>563</sup>

A linear variation of the electron effective mass with  $x$  in GaAsP was reported by Wetzel *et al.*<sup>190</sup> A  $\mathbf{k} \cdot \mathbf{P}$  calculation with explicit inclusion of the higher conduction bands and slightly different band parameters predicts a small bowing parameter of  $0.0086m_0$ .<sup>191</sup> We recommend following the general procedure tying the mass bowing to the direct-gap bowing as outlined above, which yields reasonable agreement with that theory and experiment.

The deformation potentials in GaAsP were studied by Gonzalez *et al.*<sup>570</sup> The shear deformation potential  $b$  found in that work lies between the recommended values for GaAs (−2.0 eV) and GaP (−1.7 eV). Although the hydrostatic deformation potentials were found to be somewhat smaller than either of the binary values, that may have been an artifact of the measurements rather than an alloy-specific property.

The recommended nonzero bowing parameters for GaAsP are collected in Table XXIV.

## 2. InAsP

InAsP spans an interesting IR wavelength range (0.87–3  $\mu\text{m}$ ), retains a direct gap throughout, and has a high electron mobility. However, it has found far less practical use than its quaternary cousin GaInAsP because except at the endpoints the InAs <sub>$x$</sub> P <sub>$1-x$</sub>  lattice constant does not match any of the binary III–V substrate materials.

TABLE XXV. Nonzero bowing parameters for InAsP.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0.10	0.09–0.38
$E_g^X$	0.27	...
$E_g^L$	0.27	...
$\Delta_{\text{so}}$	0.16	...

The dependence of the energy gap on composition was originally studied by Vishnubhatla *et al.*<sup>426</sup> and Antypas and Yep.<sup>571</sup> Whereas the first group reported a bowing parameter of 0.27 eV at 300 K, the second group obtained a similar  $C$  at  $T = 77$  K but a much smaller value (0.10 eV) at 300 K. Bodnar *et al.* later reported the opposite trend for the temperature dependence of  $C$ ,<sup>158</sup> and Nicholas *et al.* suggested similar bowing parameters of 0.32–0.36 eV throughout the entire temperature range.<sup>572</sup> A recent fitting of the absorption spectra of InAsP/InP strained quantum wells also yielded a weak temperature dependence, but with values between 0.10 and 0.12 eV.<sup>573</sup> Similar results were reported by Wada *et al.*,<sup>574</sup> who used a combination of PL, x-ray diffraction, and absorption measurements. We recommend a value of  $C = 0.10$  eV, which is consistent with the latest experimental works and is slightly lower than the theoretical estimate of 0.23 eV.<sup>410</sup>

The bowing parameters for the indirect gaps were estimated by Adachi<sup>166</sup> and Glisson *et al.*<sup>201</sup> Using their projections, we recommend  $C = 0.27$  eV for both  $X$  and  $L$  valleys. A bowing parameter of 0.16 eV was determined for the spin-orbit splitting.<sup>446</sup>

The electron effective mass in InAsP alloys was first investigated by Kesamanly *et al.*<sup>173</sup> This work and also the subsequent magnetophonon experiments of Nicholas *et al.*<sup>572,575</sup> found a nearly linear dependence of the mass on composition. Although the authors conjectured a reduction in the interband matrix element in the alloy, their quantitative conclusions are in doubt since they overestimated the direct-gap bowing parameter as well as the interband matrix element for InAs. With these corrections, it is unclear whether a nonlinear term needs to be introduced for  $E_p$ . The effective mass for InAs-rich alloys was determined by Kruzhaev *et al.* from tunneling magnetospectroscopy<sup>576</sup> and for three different compositions by Sotomayor Torres and Stradling using far-IR magneto-optics.<sup>577</sup> Again, due to the experimental uncertainty it is difficult to determine whether the standard procedure needs to be supplemented. In fact, the most recent experimental results are in very good agreement with the assumption that both the interband matrix element and the  $F$  parameter vary linearly with composition.

TABLE XXVI. Nonzero bowing parameters for AlAsP.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	0.22	...
$E_g^X$	0.22	...
$E_g^L$	0.22	...

TABLE XXVII. Nonzero bowing parameters for GaPSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	2.7	2.7–3.8
$E_g^X$	2.7	...
$E_g^L$	2.7	...

The recommended nonzero bowing parameters for InAsP are collected in Table XXV.

### 3. AlAsP

If the exotic AlAsP alloy has ever been grown, it was apparently not reported. Glisson *et al.* surmised that the direct-gap bowing parameter in AlAsP would be quite small (0.22 eV).<sup>201</sup> Using the criterion relating to the bond-length difference in the endpoint binaries, one would not expect the bowing parameter to exceed those in GaAsP (0.19 eV) and InAsP (0.22 eV) (see Table XXVI).

## F. Phosphides antimonides

### 1. GaPSb

The growth of GaPSb was first reported by Jou *et al.*<sup>578,579</sup> The primary object was to determine whether the energy gap in the GaP<sub>0.68</sub>Sb<sub>0.32</sub> alloy, which is lattice matched to GaAs, is direct or indirect. Strong PL was observed, which led the authors to conclude that the energy gap is direct. Large bowing parameters of 3.8 and 2.7 eV (lower bound) were derived for the  $\Gamma$ -valley and X-valley gaps, respectively. Since these greatly exceed the available theoretical estimates,<sup>201,580</sup> it cannot be ruled out that ordering substantially reduced the energy gaps in these and perhaps most other investigated GaPSb alloys. Subsequently, Loualiche *et al.*<sup>581</sup> studied GaSb<sub>0.65</sub>P<sub>0.35</sub>, which is lattice matched to an InP substrate. Since at this composition the direct nature of the energy gap is not in question, it may be argued that the analysis of their data should yield a more reliable value for the direct-gap bowing parameter ( $C=2.7$  eV). The room-temperature PL measurements of Shimomura *et al.*<sup>582</sup> produced approximately the same result, which is our recommended value. The same  $C$  is also recommended for the X and L-valley gaps, since no studies have been reported (see Table XXVII).

### 2. InPSb

The energy gap in InPSb remains direct at all compositions. Bowing parameters in the 1.2–2.0 eV range have been reported for the direct gap.<sup>101,166,201,579,580,583–586</sup> The study by Jou *et al.*<sup>579</sup> of alloys with a range of compositions ap-

TABLE XXVIII. Nonzero bowing parameters for InPSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	1.9	1.2–2.0
$E_g^X$	1.9	...
$E_g^L$	1.9	...
$\Delta_{so}$	0.75	...

TABLE XXIX. Nonzero bowing parameters for AlPSb.

Parameters (eV)	Recommended values	Range
$E_g^\Gamma$	2.7	1.2–2.7
$E_g^X$	2.7	...
$E_g^L$	2.7	...

pears to be the most useful. A recent experiment<sup>587</sup> obtained an energy gap of 0.48 eV for InP<sub>0.69</sub>Sb<sub>0.31</sub> lattice matched to an InAs substrate, which implies an even larger value of the bowing parameter. Although further work will be needed to establish complete confidence, our recommended direct-gap bowing parameter is  $C=1.9$  eV. Since the indirect gaps in InPSb have not been studied, it is not unreasonable to assume the same values for their bowing. The bowing parameter for the spin-orbit splitting has been calculated to be 0.75 eV (see Table XXVIII).<sup>101</sup>

### 3. AlPSb

The successful growth of AlP<sub>0.40</sub>Sb<sub>0.60</sub> lattice matched to InP has been reported.<sup>582</sup> An early projection of Glisson *et al.*<sup>201</sup> was  $C=1.2$  eV for the direct-gap bowing parameter. However, considering the trends in the common group-III alloys, it is likely that the gaps corresponding to the three major valleys have bowing parameters that are not too different from those in GaPSb. We therefore recommend  $C=2.7$  eV (see Table XXIX).

## G. Nitrides

### 1. GaInN

GaInN quantum wells represent a key constituent in the active regions of blue diode lasers and LEDs.<sup>293</sup> This technological significance justifies the quest for a thorough understanding of the bulk properties of wurtzite GaInN alloys. Unfortunately, however, there is still considerable disagreement over such fundamental parameters as the bowing of the energy gap. A (partial) phase decomposition of the GaInN quantum wells employed in blue and green LEDs is believed to occur.<sup>588</sup> Nearly pure InN quantum dots are formed, which act as efficient radiative recombination centers. Since it is not yet clear whether this phase segregation has been com-

TABLE XXX. Energy-gap bowing parameters for nitride ternaries. For other information available for these compounds, see Table XXXI and the text.

Materials	Recommended values
Wurtzite GaInN	3.0
Zinc blende GaInN	3.0
Wurtzite AlGaIn	1.0
Zinc blende AlGaIn	0
Wurtzite AlInN	16–9.1x
Zinc blende AlInN	16–9.1x
Zinc blende GaAsN	120.4–100x
Zinc blende GaPN	3.9
Zinc blende InPN	15
Zinc blende InAsN	4.22



TABLE XXXI. Bowing parameters for quantities other than the energy gap of nitride ternaries.

Parameters (eV)	Materials	Recommended values
$E_g^X$	Zinc blende GaInN	0.38
$E_g^X$	Zinc blende AlGaIn	0.61
$E_g^L$	Zinc blende AlGaIn	0.80
$\Delta_{so}$	Zinc blende GaAsN	0

pletely avoided in thicker layers of GaInN, interpretation of the reported bowing parameters requires great care (see Tables XXX and XXXI).

Early studies suggested an energy-gap bowing parameter  $C$  of between 0 and 1.0 eV.<sup>402,589,590</sup> Wright and Nelson more recently derived  $C=1$  eV for zinc blende GaInN,<sup>591</sup> which is relevant because of the common expectation that the zinc blende and wurtzite alloys should have approximately the same bowing parameters. Nakamura found that this bowing parameter produced a good fit to the results of PL measurements for low In compositions.<sup>592</sup> A slightly larger bowing parameter (1.6 eV if our values for the energy gaps of GaN and InN are employed) was found by Li *et al.*, on the basis of PL from GaInN/GaN superlattices.<sup>593</sup> A similar bowing parameter of 1.4 eV was reported for zinc blende GaInN; however, the results were given for relatively thin GaInN layers, the strain in which cannot be considered fully relaxed.<sup>594</sup> Bellaiche and Zunger<sup>595</sup> investigated the effects of short-range atomic ordering in GaInN, and established that a large reduction in the band gap should be expected for that scenario. Although all of these studies are consistent with a bowing parameter of  $\approx 1$  eV for the random GaInN alloy, several more recent investigations of GaInN layers with small In fractions arrived at significantly larger values. The experimental band gap results of McCluskey *et al.* for  $\text{Ga}_{1-x}\text{In}_x\text{N}$  epilayers with  $x < 0.12$  were found to be consistent with bowing parameters as large as 3.5 eV.<sup>596</sup> Furthermore, first-principles calculations performed by those authors showed that the bowing parameter itself may be a strong function of composition, at least for small In fractions. Similarly large bowing parameters (in the range 2.4–4.5 eV) were obtained in a large number of subsequent studies by different groups.<sup>597–602</sup> A bowing parameter of 2.7 eV can also be inferred from a recent investigation of zinc blende GaInN.<sup>603</sup> Some of those works tentatively attributed the previous reports of small bowing to erroneous estimates of the alloy composition. On the other hand, Shan *et al.*<sup>599</sup> suggested that the more recent PL emission may have resulted from local fluctuations in the In fraction, which could lead to overestimates of the bowing parameter. Since the most important practical applications of GaInN alloys require only a small In fraction, we suggest a bowing parameter of 3 eV for both the wurtzite and zinc-blende phases, although we emphasize that at present there exists no verification that this  $C$  applies equally well to higher In compositions. There is also a strong possibility that the alloys studied in recent works are not truly random. It should be emphasized that the physical understanding of these materials is far from complete, and that the parameters recommended in this review are provi-

sional quantities that will almost surely be revised in the course of future work. A further comment which applies to all of the nitride alloys as well as other systems affected by unknown degrees and types of segregation, is that the parameter set most relevant to a given theoretical comparison with data may not be that representing the ideal materials, but rather the nonideal properties resulting from specific growth conditions of interest.

There is very little information on the other band parameters for GaInN. Tight-binding calculations<sup>321</sup> provide some support for our recommended standard procedure of using the band-gap bowing parameter to derive the compositional variation of the electron effective mass and interpolating the rest of the quantities linearly. For the  $X$ -valley gap in zinc blende GaInN, a small bowing parameter of  $C=0.38$  eV was estimated from first principles.<sup>591</sup>

## 2. AlGaIn

AlGaIn is often used as the barrier material for nitride electronic and optoelectronic devices. Initial studies of the compositional dependence of the energy gap reported downward,<sup>604</sup> upward,<sup>605</sup> and negligible<sup>606</sup> bowing. Subsequent early PL<sup>607</sup> and absorption<sup>608</sup> measurements found a bowing parameter of 1.0 eV, which continues to be widely used in band structure calculations even though a number of more recent investigations question the conclusions of the early work. Several studies<sup>597,609,610</sup> found negligible bowing, and it has been suggested that the other values resulted from an incomplete relaxation of strain in the AlGaIn thin films.<sup>609</sup> This statement is supported to some extent by a large bowing parameter of 1.78 eV reported for highly strained layers grown on SiC.<sup>611</sup> Other workers quite recently calculated<sup>612</sup> and measured<sup>613</sup> smaller bowing parameters (0.25–0.6 eV depending on the measurement method and assumed binary end points). Brunner *et al.*<sup>318</sup> reported  $C=1.3$  eV and the data of Huang and Harris<sup>614</sup> imply an even larger bowing parameter for AlGaIn epilayers grown by pulsed laser deposition, although in both cases residual strain due to the differing lattice and thermal expansion coefficients of AlGaIn and sapphire could have affected the results. Cathodoluminescence measurements for AlGaIn epitaxially grown on Si(111) suggest  $C=1.5$  eV.<sup>615</sup> We recommend continued use of the accepted bowing parameter of 1.0 eV until a broader consensus is reached on the effects of strain and other issues.

Theory projects that the  $\Gamma$ -valley bowing parameter in zinc blende AlGaIn is small.<sup>369,591</sup> This is consistent with the experimental report of a linear variation of PL energies in thin films of cubic AlGaIn.<sup>616</sup> We therefore recommend a zero bowing parameter for this case. Recommended values for the  $X$ -valley (0.61 eV) and  $L$ -valley (0.80 eV) bowing parameters are taken from the empirical pseudopotential method calculations of Fan *et al.*<sup>369</sup>

## 3. AlInN

$\text{Al}_x\text{In}_{1-x}\text{N}$  is drawing attention because at  $x=0.83$  it can be lattice matched to GaN. The first experimental study observed such a strong bowing that the band gap for the lattice-

matched composition was found to be smaller than that of GaN.<sup>617</sup> Furthermore, the standard quadratic expression did not fit the compositional variation of the band gap very well. Guo *et al.*<sup>618</sup> and Kim *et al.*<sup>619</sup> subsequently presented results for InN-rich and AlN-rich AlInN, respectively, which indicated somewhat weaker bowing. Peng *et al.*<sup>620</sup> gave a cubic expression for the energy gap, based on results over the entire range of compositions. A similarly large bowing was observed by Yamaguchi *et al.*<sup>621</sup> On the theoretical side, a first-principles calculation for zinc blende AlInN yielded a bowing parameter of 2.53 eV, which was assumed to be equal to that in the wurtzite alloy.<sup>622</sup> Of these, the most trustworthy quantitative report appears to be that of Peng *et al.* However, the suggested expression,  $E_g(300\text{ K}) = 1.97 + 1.968x - 6.9x^2 + 9.1x^3$  eV, has been corrected to reflect our recommendations for the binary end points. In the absence of further information, we recommend that the temperature dependence be incorporated by using the recommended end points to fix the constant and linear terms at each  $T$ , and then use the Peng *et al.* quadratic and cubic terms at all temperatures. The same approach is recommended for zinc blende AlInN.

#### 4. GaAsN

Although it has been known for a long time that small quantities of nitrogen form deep-level impurities in GaAs and GaP, growth of the GaAsN alloy with appreciable (close to 1%) N fractions has been reported only recently.<sup>623,624</sup> The somewhat unexpected discovery of a giant bowing parameter in this and other  $\text{AB}_{1-x}\text{N}_x$  alloys in principle opens prospects for growing direct-gap III–V semiconductors with band gaps in the near-IR onto Si substrates.

As a general rule, the non-nitride constituents do not easily take the wurtzite form. It is therefore expected that GaAsN and the other analogous alloys will crystallize in a zinc blende lattice, and that a large miscibility gap will make it difficult to prepare alloys with large N fractions. Phase separation has indeed been observed in GaN-rich alloys.<sup>625</sup> Furthermore, the substantial differences between the properties of the light-atom constituent (e.g., GaN) and the heavy-atom constituent (e.g., GaAs) call for a close scrutiny of the usual quadratic relations for the alloy band parameters, since one expects the alloy concentration dependence to be highly nonlinear.

An early theoretical study predicted a bowing parameter of 25 eV for the direct energy gap of GaAsN.<sup>626</sup>  $C = 18$  eV was obtained from PL measurements of GaAsN with N fractions of no more than 1.5%.<sup>627</sup> The same result was inferred from studies of the GaAsN near the two binary limits, with the decrease in the energy gap being linear for N fractions as high as 3%.<sup>628</sup> A quadratic form with  $C \approx 11$  eV fit the results of an ellipsometry study for  $x < 3.3\%$  fairly well.<sup>629</sup> Other studies of dilute GaAsN indicated bowing parameters as large as 22 eV.<sup>630–632</sup> A series of first-principles calculations examined various aspects of the band structure for GaAsN, including ordering effects.<sup>666,633–638</sup> Those studies found that the band-edge wave functions in GaAsN tend to be localized impurity-like states, with the conduction-band wave function strongly localized on the As sublattice and the valence-band

wave function on the N sublattice. The projected bowing parameters were large and composition-dependent (varying in the range from 7 to 16 eV between  $\text{GaAs}_{0.5}\text{N}_{0.5}$  and  $\text{GaAs}_{0.875}\text{N}_{0.125}$ ) whenever the dilute alloy displayed a localized deep impurity level in the gap.<sup>666,635</sup> Recent experimental work on GaAsN with N fractions as large as 15% confirmed the strong composition dependence of the bowing, with values ranging from 20 eV for dilute alloys to 5 eV for concentrated alloys.<sup>639,640</sup> On the other hand, Uesugi *et al.*<sup>641</sup> found a more gradual reduction of the bowing parameter with composition, and attributed the discrepancy to different strain conditions in the different studies. On the basis of the most complete available data set,<sup>639</sup> a compromise cubic form for the band-gap dependence on composition (at all temperatures) can be derived with the following nonlinear terms:  $20.4x^2 - 100x^3$  eV. This expression avoids the early semimetallic transition (predicted by using  $C = 20$  eV) that was not observed in the single relevant experimental study.<sup>639</sup> A note of caution is that this expression is expected to be valid only in the region  $x < 0.15$ , beyond which no experimental data are available. This description may in fact be a rather crude approximation of the band-gap dependence over the entire range of compositions.

An alternative description of the energy gap in GaAs-rich GaAsN in terms of the level repulsion model has been developed recently.<sup>642</sup> The transformation from N acting as an isoelectronic impurity to band formation was found to occur at  $x = 0.2\%$ . The energy gap is sublinear with composition for N fractions as small as a few percent. No upper limit on the composition, for which this description is valid, is available at this moment and the results have been verified only for  $x < 3\%$ . Nonetheless, in view of the strong evidence for its correctness, it may be advisable to use that description rather than the nonlinear bowing approximation for low N compositions, which are of interest for most device applications. A potentially more accurate four-level repulsion model was recently introduced by Gil.<sup>643</sup>

The Varshni parameters measured by Malikova *et al.*<sup>644</sup> for two GaAsN alloys were found to lie between those of GaAs and zinc-blende GaN. The temperature dependence of the energy gap in a few GaAsN alloys was found to be much weaker (60%) than that in GaAs for N fractions as small as 1%.<sup>645</sup> The spin-orbit splitting obtained from electroreflectance measurements<sup>646</sup> was found to vary approximately linearly in GaAsN. The interband matrix element of GaAsN (and other alloys such as GaPN) is predicted<sup>647</sup> to be strongly reduced relative to the virtual crystal approximation. This theoretical result, which is important primarily at large N compositions, has yet to be verified experimentally. Furthermore, an abrupt increase in the effective mass in GaAsN/GaAs quantum wells with 1.2% and 2% N has been reported.<sup>648,649</sup> The effective mass is larger than that predicted on the basis of theoretical calculations.<sup>638,650</sup>

The valence-band shear deformation potential  $b$  in dilute GaAsN epilayers was studied by Zhang *et al.*<sup>651</sup> using electroreflectance measurements to determine the splitting between the heavy-hole and light-hole bands. The deformation

potential did not follow a simple linear interpolation between GaAs and GaN. The cause is not quite clear, since N incorporation is expected to affect primarily the conduction band of GaAsN, and further studies over a wider composition range are required to pin down the (possibly complicated) N fraction dependence.

### 5. GaPN

Most of the band properties of GaPN are expected to be analogous to those of GaAsN, based on the simple observation that the N impurity behaves in a similar manner in both GaAs and GaP. The main complication is that GaP is an indirect-gap semiconductor. Both the  $\Gamma$ -valley and X-valley gaps in GaPN were predicted to have bowing parameters of 14 eV,<sup>652</sup> and subsequent experimental data agreed with those projections.<sup>652–654</sup> Sakai *et al.* used the same theoretical description and obtained similar results.<sup>626</sup> Recently, Bi and Tu were able to observe the energy-gap variation for alloys incorporating up to 16% N.<sup>639</sup> Their results are consistent with the predictions of another model, which yields bowing parameters of 10 and 3.9 eV for the X-valley and  $\Gamma$ -valley gaps, respectively. These results are quite close to the recent tight-binding calculations of Miyoshi *et al.*<sup>655</sup> and appear to be the best available values for interpolating between GaP and zinc blende GaN using the conventional model. Pseudopotential calculations indicate that even though both GaP and GaN have substantial matrix elements, the momentum matrix element in GaPN is very small for almost any concentrated GaPN alloy.<sup>647</sup> On the other hand, Xin *et al.*<sup>656</sup> recently observed intense PL from GaPN alloys with a N fraction larger than 0.43% and demonstrated a red LED based on  $\text{GaP}_{0.989}\text{N}_{0.011}$ .<sup>657</sup> These results are quite consistent with the picture developed by Shan *et al.*,<sup>658</sup> which challenges the once accepted wisdom that GaPN retains an indirect gap for very small N concentrations ( $\approx 1\%$ ). These authors formulated a model based on the interaction between highly localized nitrogen states and extended states at the  $\Gamma$  conduction-band minimum. According to the so-called “band anticrossing” picture, incorporation of even small amounts of N into GaP changes the nature of the fundamental optical transition from indirect to direct. The optical transition energy is smaller than the nitrogen level in GaP (2.18 eV) by a term linear in  $x$  for small  $x$  and varying as  $x$  for larger  $x$ . Another piece of the evidence supporting strong  $\Gamma$ –X mixing is the recent measurement of a heavy ( $0.9m_0$ ) electron mass in  $\text{GaP}_{0.975}\text{N}_{0.025}$ /GaP quantum wells.<sup>659</sup> Provided the accuracy and validity limits of the “band anticrossing” picture are conclusively established, the theoretical approach summarized in Ref. 658 should be employed to determine the optical transition energies in GaPN. Similar considerations apply to other low-N-fraction-containing alloys (see Sec. IV G 4). In this review, we refrain from exploring the consequences of the band anticrossing model in more detail.

### 6. InPN

InPN with less than 1% N has been studied by Bi and Tu.<sup>660</sup> In spite of the low solubility of N in InP, they, found

a significant band gap reduction that corresponded to a bowing parameter in the range 13–17 eV. We recommend an average value of  $C=15$  eV, and refer the reader to Sec. IV G 4 for the necessary caveats.

### 7. InAsN

A theoretical calculation of the band structure of InAsN has been reported,<sup>661</sup> and one recent experimental study of the growth of this interesting ternary has been made.<sup>662</sup> The primary importance of InAsN is that it serves as one of the end points of the GaInAsN quaternary, which is promising for 1.55  $\mu\text{m}$  semiconductor lasers on GaAs substrates. A tight-binding calculation<sup>661</sup> deduced a bowing parameter of 4.22 eV, which was obtained assuming a particular value (3.79 eV) for the valence-band discontinuity between InAs and InN. This is our recommended value, although it must be noted that the quadratic fit in Ref. 661 was rather poor. Another recent tight-binding study<sup>663</sup> showed that the band gap variation for small N fractions depends on the degree of ordering present in the material and that the maximally N-clustered alloy has a lower energy gap than the As-clustered alloy. It remains to be determined which configuration can be realized experimentally.

The recommended bowing parameters for all the nitride ternary alloys are collected in Tables XXX and XXXI.

## V. QUATERNARY ALLOYS

The capabilities of III–V quantum well devices can frequently be expanded by introducing quaternary layers to the design. This increased flexibility does, however, come at the expense of a more difficult growth coupled with the need for multiple tedious calibration runs to accurately fix the composition. Furthermore, extensive miscibility gaps limit the range of stable compositions, since in thermal equilibrium the components often tend to segregate into inhomogeneous mixtures of binaries and ternaries. While the nonequilibrium MBE growth process can extend the miscibility boundaries considerably, inaccessible composition gaps remain for some of the III–V quaternary systems.

General methods for deriving quaternary alloy band parameters from those of the underlying binary and ternary materials have been summarized by a number of authors.<sup>101,166,201</sup> While no single approach guarantees good results in all cases, the interpolation procedure introduced by Glisson *et al.*<sup>201</sup> usually provides a reasonable approximation. It is applicable to the most commonly encountered quaternaries of the  $A_xB_{1-x}C_yD_{1-y}$  type, that are made up of two group-III and two group-V elements. Using the notation from Eq. (4.1), a given band parameter for the ternary  $A_{1-x}B_xC$  is given by

$$G'_{ABC}(x) = (1-x)G_{AC} + xG_{BC} - x(1-x)C_{ABC}, \quad (5.1)$$

where  $G_{AC}$  and  $G_{BC}$  are the values at the binary end points and  $C_{ABC}$  is the appropriate bowing. The corresponding band parameter in the quaternary  $A_xB_{1-x}C_yD_{1-y}$  is then expressed as a weighted sum of the related ternary values:



$$G''_{ABCD}(x,y) = \frac{x(1-x)[(1-y)G'_{ABD}(x) + yG'_{ABC}(x)] + y(1-y)[xG'_{ACD}(y) + (1-x)G'_{BCD}(y)]}{x(1-x) + y(1-y)}. \quad (5.2)$$

This approach can be extended to treat quaternary alloys of the  $AB_xC_yD_{1-x-y}$  and  $B_xC_yD_{1-x-y}A$  types<sup>664</sup>

$$G'_{ABCD}(x,y) = \frac{xyG'_{ABD}(u) + y(1-x-y)G'_{BCD}(v) + (1-x-y)xG'_{ACD}(w)}{xy + y(1-x-y) + (1-x-y)x}, \quad (5.3)$$

where  $u \equiv (1-x-y)/2$ ,  $v \equiv (2-x-2y)/2$ , and  $w \equiv (2-2x-y)/2$ . The approach of Eqs. (5.2) and (5.3) tends to give better agreement with experiment than an alternative treatment of Moon *et al.*,<sup>665</sup> which is known to overestimate the quaternary bowing.<sup>201,666</sup> Krijn<sup>101</sup> gives polynomial expansions of  $Q(x,y)$  derived from Eqs. (5.2) and (5.3) for the energy gaps and spin-orbit splittings of several III-V quaternaries.

Generally speaking, a given quaternary comprises a vast two-dimensional space of compositions,  $[x,y]$ . In practice, however, most experiments have focused on the one-dimensional subsets,  $[x,y(x)]$  that are (approximately) lattice matched to one of the common binary substrate materials (GaAs, InP, InAs, or GaSb). The quaternary may then be represented as a combination of two lattice-matched constituents, one of which must be a ternary while the other may be either a binary or a ternary. The treatment is considerably simplified by the usual absence of any strong bowing of the band parameters for such an alloy, which is expected on theoretical grounds because the two constituents have identical lattice constants.

In the following, we will assume two lattice matched binary or ternary end points,  $\alpha$  (e.g.,  $A_{1-x}B_xC$ ) and  $\beta$  (e.g.,  $AC_{1-y}D_y$ ), which are combined with arbitrary composition  $z$  to form the lattice-matched quaternary alloy  $\alpha_{1-z}\beta_z$ . We then employ the expression

$$G''_{\alpha\beta}(z) = (1-z)G'_\alpha + zG'_\beta - z(1-z)C_{\alpha\beta}, \quad (5.4)$$

where  $G'_\alpha$  and  $G'_\beta$  are the values at the end points and  $C_{\alpha\beta}$  is the additional bowing associated with combining the two end point materials to form a quaternary. For lattice-matched quaternaries, using Eq. (5.4) with the available experimental evidence to determine  $C_{\alpha\beta}$  for each property should lead to a better representation than either the procedure of Eqs. (5.2) and (5.3) or simple linear interpolation.

## A. Lattice matched to GaAs

### 1. AlGaInP

$(Al_zGa_{1-z})_{0.51}In_{0.49}P$  [or, more accurately,  $(Al_{0.52}In_{0.48}P)_z/(Ga_{0.51}In_{0.49}P)_{1-z}$ ] lattice matched to GaAs is often employed as the barrier and cladding material in GaInP/AlGaInP red diode lasers.<sup>473,498</sup> Early studies of lattice-matched AlGaInP, which is a quaternary of the second type (with one group-V element), found that the band gap variation between  $Ga_{0.51}In_{0.49}P$  and  $Al_{0.51}In_{0.49}P$  is indeed nearly linear, as expected.<sup>494,505,667</sup> However, subsequent PL, PL excitation (PLE),<sup>507</sup> electroreflectance,<sup>502</sup> thermorefectance,<sup>500</sup> and ellipsometry<sup>508</sup> measurements indicated that a small additional bowing parameter between 0.11 and 0.18 eV is needed to fully account for the data. Using  $C=0.18$  eV in conjunction with the recommended expressions for the temperature-dependent direct gaps of GaInP and

AlInP, Eq. (5.4) can be used to find the lattice-matched AlGaInP gaps for all  $z$  and  $T$ . For example, at  $T=0$  we obtain  $E_g = [2.007(1-z) + 2.691z - 0.18z(1-z)]$  eV.

Using linear interpolation for the X-valley energy gap in AlGaInP (supported by the PL data of Najda *et al.*<sup>507</sup>), we find that the direct-to-indirect crossover (at 0 K) should occur at  $z=0.55$ , which is in good agreement with experiment.<sup>494,507</sup> The composition-dependent variation of the 300 K energy gap in the lattice-matched quaternary  $(Al_zGa_{1-z})_{0.51}In_{0.49}P$  is plotted by Fig. 6, in which the  $\Gamma$ -valley gap is given by a solid curve and the X-valley gap by a dashed curve. Linear interpolation between the lattice-matched alloys is also suggested for the L-valley gap and the spin-orbit splitting.<sup>502</sup> There appears to be only one cyclotron resonance study of the electron mass in  $Al_{0.15}Ga_{0.35}In_{0.5}P$ ,<sup>495</sup> in which ordering and L-valley interactions could have distorted the reported electron mass of  $0.14m_0$ . It is therefore suggested that the standard procedure be followed, except that electron masses in the lattice-matched ternaries should be used as the end points in place of binaries. In this particular example, linear interpolation of the end point ternary masses should also give adequate results.

### 2. GaInAsP

Not very much is known about the band structure of GaInAsP lattice matched to GaAs [or  $(GaAs)_{1-z}(Ga_{0.51}In_{0.49}P)_z$ ]. There has been little motivation to pursue this quaternary, since its direct band gap spans roughly the same range as direct-gap AlGaAs, which is considerably easier to grow.

However, there has been some work<sup>668,669</sup> on lattice-matched and strained alloys (in the vicinity of  $z=0.67$ ), for

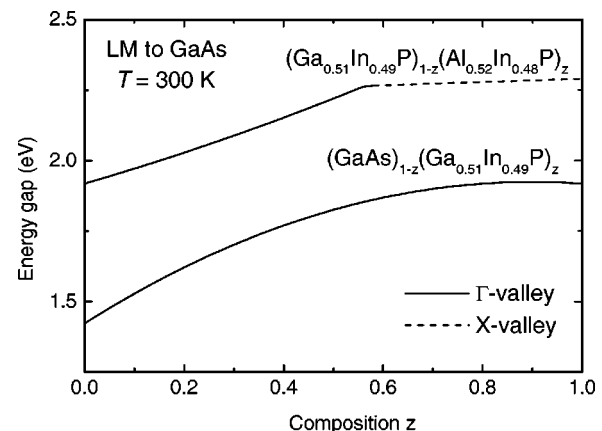


FIG. 6. Lowest energy gaps as a function of composition for  $(Al_{0.52}In_{0.48}P)_z/(Ga_{0.51}In_{0.49}P)_{1-z}$  and  $(Ga_{0.51}In_{0.49}P)_z/(GaAs)_{1-z}$  quaternary alloys, lattice matched to GaAs, at  $T=300$  K. The region of AlGaInP for which the X-valley gap is lowest is indicated with a dashed line.



which the quaternary constituents may be rewritten  $(\text{GaP})_x(\text{InAs})_{1-x}$  (with  $x \approx z$  for the case of lattice matching to GaAs). Absorption measurements<sup>669</sup> yielded  $x_c = 0.73$  for the direct-to-indirect crossover point. Since the authors greatly overestimated the  $X$  valley gap in InAs, their corresponding bowing parameter cannot be considered reliable. Instead we adopt their direct-gap bowing parameter of 0.40 eV and estimate  $C_X = -0.28$  eV from the crossover composition (note that these bowings are in terms of  $x$  with GaP and InAs as end points, not  $z$  with GaAs and  $\text{Ga}_{0.51}\text{In}_{0.49}\text{P}$  as end points). It should be noted that results for the GaP-rich quaternary do not necessarily support upward bowing, whereas a linear variation does produce a reasonably good fit.

Using the results for  $(\text{GaP})_x(\text{InAs})_{1-x}$  discussed above, a straightforward evaluation of the bowing parameters for the lattice-matched quaternary  $(\text{GaAs})_{1-z}(\text{Ga}_{0.51}\text{In}_{0.49}\text{P})_z$  gives  $C_X = 0.53$  eV and  $C_T = -0.62$  eV. The composition-dependent variation of the 300 K energy gap in GaInAsP lattice matched to GaAs is plotted in Fig. 6. The recommended parameters imply a direct band gap at all compositions  $z$ .

### 3. AlGaInAs

Band gaps for strained AlGaInAs on GaAs (with low Al and In fractions) have been reported by Jensen *et al.*,<sup>441</sup> on the basis of PL measurements.

### 4. GaInAsN

The GaInAsN quaternary has drawn considerable attention recently, since the addition of a small N fraction compensates the compressive strain that limits the critical thickness of GaInAs layers grown on GaAs substrates. In terms of the band structure properties, the alloy may be thought of as  $(\text{GaAs})_{1-z}(\text{InAs}_{0.62}\text{N}_{0.38})_z$  and represents a quaternary analog of the nitrogen-containing zinc blende ternaries discussed in the previous section. Unfortunately, the properties of InAsN have not been measured, and such experiments may run into difficulty in the future owing to the expected miscibility gap. An alternative approach proposed by Chow *et al.*<sup>670</sup> on the basis of the experimental result of Jones *et al.*<sup>671</sup> is to derive the energy gap from the GaInAs alloy with the same In fraction and then *reduce* it by  $(53\Delta\epsilon)$  eV, where  $\Delta\epsilon$  is the difference between the in-plane strains computed for the In-containing ternary and quaternary (we have revised the coefficient in order to fit our band-gap scheme). The results of absorption<sup>672</sup> and photomodulation spectroscopy<sup>673</sup> are in accord with the PL measurement of Jones *et al.*<sup>671</sup> Pseudopotential calculations<sup>674</sup> are in good agreement with this approach for low N fractions. Calculations and measurements for GaInAsN lattice matched to InP have also been reported.<sup>674,675</sup> Recently, a large increase in the electron mass in GaInAsN with a small N fraction was observed via reflectivity measurements.<sup>676</sup> This result appears to invalidate any simple interpolation scheme and favor the authors' proposed model of the interaction between localized N states and the extended states of the semiconductor matrix as discussed in Sec. IV G 4.

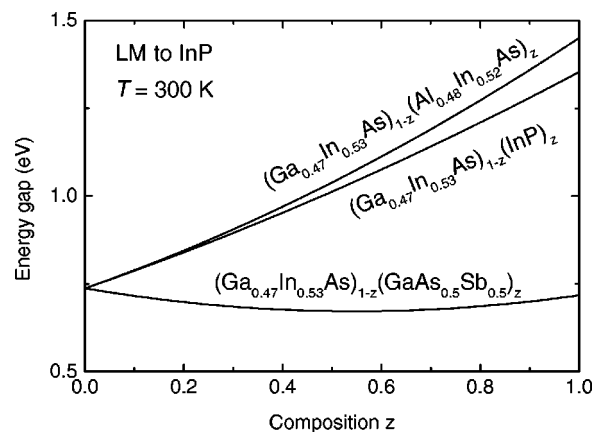


FIG. 7. Energy gaps as a function of composition for  $(\text{InP})_z(\text{Ga}_{0.47}\text{In}_{0.53}\text{As})_{1-z}$ ,  $(\text{Al}_{0.48}\text{In}_{0.52}\text{As})_z(\text{Ga}_{0.47}\text{In}_{0.53}\text{As})_{1-z}$ , and  $(\text{GaAs}_{0.5}\text{Sb}_{0.5})_z(\text{Ga}_{0.47}\text{In}_{0.53}\text{As})_{1-z}$  quaternary alloys, lattice matched to InP, at  $T = 300$  K.

## B. Lattice matched to InP

### 1. GaInAsP

GaInAsP lattice matched to InP  $[(\text{InP})_{1-z}(\text{Ga}_{0.47}\text{In}_{0.53}\text{As})_z]$ , which is  $\text{Ga}_x\text{In}_{1-x}\text{As}_z\text{P}_{1-z}$  with  $x = 0.47z$ , is an extremely important quaternary alloy. It is currently employed in commercial optoelectronic (especially semiconductor lasers emitting at 1.3 and 1.55  $\mu\text{m}$ ) and electronic (especially high-electron-mobility transistor) devices. This alloy has been the subject of numerous review articles<sup>5,6,429,666,677</sup> and at least one book.<sup>4</sup>

Numerous measurements of the direct energy gap in GaInAsP have been reported.<sup>427,443,678–680</sup> Pearsall summarized the experimental results available by 1982 in his review,<sup>677</sup> and deduced a bowing parameter of 0.149 eV. For the most part, a small spread in the experimental data was found, and it was pointed out that Perea *et al.*<sup>443</sup> ( $C = 0.25$  eV) underestimated the gaps somewhat in analyzing their electroreflectance data. Further electroreflectance experiments of Lahtinen and Tuomi<sup>680</sup> indicated a substantially smaller bowing parameter of 0.038 eV. An early tight-binding calculation also yielded a bowing parameter of 0.19 eV,<sup>428</sup> with error bounds sufficient to include almost all of the experimental data sets. We recommend using Eq. (5.4) with a bowing parameter of  $C = 0.13$  at all temperatures, which is consistent with the relations currently employed to estimate device characteristics.<sup>4</sup> This procedure yields  $E_g = [1.4236(1-z) + 0.816z + 0.13z^2]$  eV at 0 K and  $E_g = [1.353(1-z) + 0.737z + 0.13z^2]$  eV at 300 K. The composition-dependent variation of the 300 K energy gap in the lattice-matched quaternary  $(\text{InP})_{1-z}(\text{Ga}_{0.47}\text{In}_{0.53}\text{As})_z$  is plotted in Fig. 7.

Two studies have reported Varshni parameters for GaInAsP.<sup>681,682</sup> Although the band gaps obtained in the two studies were similar, the resulting Varshni parameters were very different. Deducing the temperature variation of the quaternary band gap from the bulk Varshni parameters given above is therefore probably a safer procedure (and gives reasonable agreement with the results of Satzke *et al.*<sup>682</sup>). A linear variation is usually assumed for the indirect band gaps

between the two end point materials,<sup>4</sup> although that dependence has apparently not been verified experimentally.

Electroreflectance studies have concluded that the bowing parameter for the spin-orbit splitting is either close to zero<sup>678,680</sup> or negative.<sup>443,679</sup> This upward bowing was explained by considering the interband and intraband contributions to disorder-induced mixing of conduction-band and valence-band states.<sup>683</sup> We derive our recommended value of  $C(\Delta_{so}) = -0.06$  eV, which implies  $\Delta_{so} = [0.108(1-z) + 0.33z - 0.06z^2]$  eV, by averaging all reported spin-orbit bowing parameters.

The electron mass in GaInAsP has been measured by a variety of approaches such as cyclotron resonance, magnetophonon resonance, Shubnikov-de Haas oscillations, and shallow donor photoconductivity.<sup>448–451,453,684</sup> Some studies found roughly zero bowing,<sup>448,449,684</sup> while others obtained appreciable downward bowing.<sup>450,451,453</sup> In the former case, it was claimed that the lack of effective mass bowing was due to the band gap bowing being compensated by a disorder-induced bowing of the interband matrix element.<sup>677</sup> However, from a consideration of all available experimental data there is no obvious reason to deviate from our standard mass-bowing procedure (e.g., see Fig. 6.7 in Ref. 4). Using our adopted band gap variation and interpolating the interband matrix element and the  $F$  parameter linearly, we find the totality of the data to be consistent with that procedure. The resulting masses are slightly lower than those in Refs. 448, 449, and 684, but not nearly as small as in Ref. 453. The light-hole effective mass in GaInAsP lattice matched to InP was measured by Hermann and Pearsall.<sup>459</sup> On the basis of those data, Adachi suggested a bowing parameter of  $0.03m_0$ .<sup>4</sup> However, we recommend using a slightly modified version of the Adachi expression,  $m_{lh}^* = (0.1208 - 0.099z + 0.0302z^2)$  eV, in order to assure consistency with the end point values in  $Ga_{0.47}In_{0.53}As$  and InP. Using linear interpolation for the heavy-hole mass and the valence-band anisotropy, the split-off mass can be determined using Eqs. (5.4) and (2.18).

By measuring the pressure dependence of the stimulated emission in a buried heterostructure near-IR diode laser, a hydrostatic deformation potential of  $a = -5.7$  eV was determined for  $Ga_xIn_{1-x}As_zP_{1-z}$  with  $y = 0.6$ .<sup>685</sup> This represents a smaller absolute value than in either InP ( $-6.6$  eV) or  $Ga_{0.47}In_{0.53}As$  ( $-7.79$  eV), and requires a rather large bowing parameter of  $C = -6.7$  eV. While we recommend this value in the absence of other information, additional experiments are necessary to confirm this strong bowing.

## 2. AlGaInAs

Another important quaternary lattice matched to InP is AlGaInAs [or  $(Al_{0.48}In_{0.52}As)_z(Ga_{0.47}In_{0.53}As)_{1-z}$ ], which combines two lattice-matched ternary alloys. Initial characterization of this quaternary was performed by Olego *et al.*,<sup>456</sup> who found a direct-gap bowing parameter of 0.20 eV [when cast into the form of Eq. (5.4)]. Subsequent PL measurements of Kopf *et al.*<sup>465</sup> and Cury *et al.*<sup>457</sup> implied a linear variation of the energy gap, whereas the low-temperature PL results of Bohrer *et al.*<sup>686</sup> suggested a large bowing parameter of 0.68 eV. Fan and Chen obtained a

value of 0.225 eV between those two extremes,<sup>458</sup> while Shen and Fan calculated a rather small bowing using the tight-binding method with the virtual-crystal approximation.<sup>470</sup> Averaging the various experimental results, we obtain a composite direct-gap bowing parameter of 0.22 eV, which is close to the values of Olego *et al.*<sup>456</sup> and Fan and Chen.<sup>458</sup> The composition-dependent variation of the 300 K energy gap in the lattice-matched quaternary  $(Al_{0.48}In_{0.52}As)_z(Ga_{0.47}In_{0.53}As)_{1-z}$  is plotted in Fig. 7.

The only other AlGaInAs band structure parameter with a validated nonlinear compositional variation is the electron effective mass, for which there is strong evidence for a slight upward bowing.<sup>457,469</sup> This can be explained by disorder-induced band mixing,<sup>447,458</sup> whose effect on the interband matrix element is described by expressions in Refs. 447 and 458. Whereas the evidence for a similar mechanism in GaInAsP was inconclusive, here we suggest an effective-mass bowing parameter of  $-0.016m_0$ . This is consistent with the other parameters if  $E_p$  is assumed to have a quadratic dependence, with  $C = -5.68$  eV adjusted to provide the correct result for AlGaInAs with  $x = 0.5$ . The  $F$  parameter is then interpolated linearly (between  $-2.89$  in  $Ga_{0.47}In_{0.53}As$  and  $-0.63$  in  $Al_{0.48}In_{0.52}As$ ) in that scheme.

## 3. GaInAsSb

Despite the presence of a miscibility gap, the growth of metastable GaInAsSb lattice matched to InP [or  $(Ga_{0.47}In_{0.53}As)_z(GaAs_{0.5}Sb_{0.5})_{1-z}$ ] has been reported over the entire composition range.<sup>687,688</sup> However, the usefulness of this quaternary is limited because both end points have nearly the same energy gap, even though the cutoff wavelengths are close to the important  $1.55 \mu m$  low-loss window for optical fiber communications.

The first reported growth and characterization study of this quaternary obtained little bowing,<sup>687</sup> whereas more recent PL measurements on bulk  $Ga_{0.64}In_{0.36}As_{0.84}Sb_{0.16}$  at 8 K implied a gap of 0.7654 eV,<sup>688</sup> as compared to  $\approx 0.81$  eV at the two end points. Based on this data point we recommend a composition dependence of  $E_g(T=0) = [0.808(1-z) + 0.816z - 0.22z(1-z)]$  eV. Further study is clearly desirable. The recommended composition-dependent variation of the 300 K energy gap in the lattice-matched quaternary  $(Ga_{0.47}In_{0.53}As)_z(GaAs_{0.5}Sb_{0.5})_{1-z}$  is plotted in Fig. 7. The approximate location of the miscibility gap according to recent calculations<sup>689</sup> is indicated with the dotted line. The precise extent of the miscibility gap depends on the growth procedure and temperature, and the growth of metastable materials inside the gap is not ruled out.

## C. Lattice matched to InAs

### 1. GaInAsSb

GaInAsSb lattice matched to InAs [or  $(InAs)_{1-z}(GaAs_{0.08}Sb_{0.92})_z$ ] has been studied by a number of authors.<sup>165,690,691</sup> The growth of slightly strained GaInAsSb layers has also been reported by Shin *et al.*<sup>692</sup> Although data for the composition dependence of the direct band gap are somewhat sparse, the available results are consistent with the relatively large bowing parameter of  $\approx 0.6$  eV suggested by

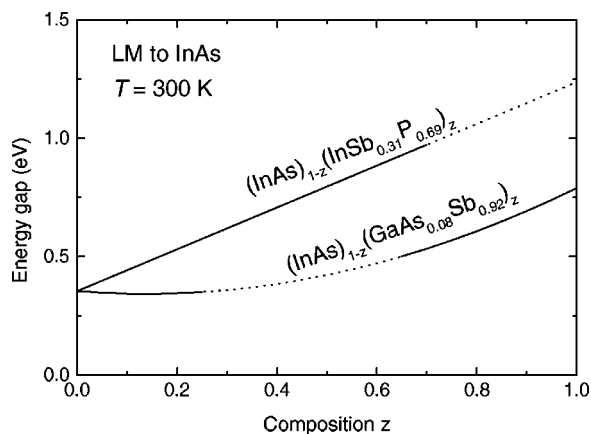


FIG. 8. Energy gaps as a function of composition for  $(\text{InAs})_{1-z}(\text{InSb}_{0.31}\text{P}_{0.69})_z$  and  $(\text{InAs})_{1-z}(\text{GaAs}_{0.08}\text{Sb}_{0.92})_z$  quaternary alloys, lattice matched to InAs, at  $T = 300$  K. The approximate locations of miscibility gaps are indicated by dotted lines.

Levinshstein *et al.*<sup>11</sup> (see also Fig. 3 of Ref. 691). This is our recommended value, which implies  $E_g(T=0) = [0.412z + 0.876(1-z) - 0.6z(1-z)]$  eV. In the following section it will be seen that this value is similar to the recommended bowing parameter for GaInAsSb on GaSb, which is not surprising in view of the near equality of the InAs and GaSb lattice constants. The empirical relation suggested in Ref. 691 also appears to produce good agreement with the data, although it cannot be recast in the form of Eq. (5.4) with a constant bowing parameter. While in one study Varshni parameters have been deduced for GaInAsSb on InAs,<sup>165</sup> it is recommended that our usual procedure be followed to derive the temperature dependence of the energy gap in this quaternary. The composition-dependent variation of the 300 K energy gap in GaInAsSb lattice matched to InAs is plotted in Fig. 8. The approximate location of the miscibility gap is indicated by the dotted line. Bouarissa<sup>693</sup> obtains  $X$ -valley and  $L$ -valley bowing parameters of 0.15 and 0.60 eV from pseudopotential calculations accommodating the effects of alloy disorder.

## 2. AlGaAsSb

The direct and indirect energy gaps in AlGaAsSb lattice matched to InAs [or  $(\text{GaAs}_{0.08}\text{Sb}_{0.92})_{1-z}(\text{AlAs}_{0.16}\text{Sb}_{0.84})_z$ ] were studied theoretically by Adachi,<sup>166</sup> and Anwar and Webster.<sup>559</sup> They respectively employed expressions suggested by Glisson *et al.*<sup>201</sup> and Moon *et al.*<sup>665</sup> (who combined the direct and indirect-gap composition dependences). Abid *et al.*<sup>694</sup> also treated AlGaAsSb, using the empirical pseudopotential method with the virtual crystal approximation. That little bowing was found for any of the energy gaps may be an artifact of neglecting the disorder potential. We therefore recommend using the bowing parameters specified below for AlGaAsSb on GaSb.

## 3. InAsSbP

$\text{InAs}_{1-x-y}\text{Sb}_x\text{P}_y$  is the only quaternary with three group-V elements that has been studied in the literature. In spite of some miscibility-gap problems, it has been success-

fully grown on InAs substrates  $[(\text{InAs})_{1-z}(\text{InSb}_{0.31}\text{P}_{0.69})_z]$ , where  $z = x + y$  by several groups.<sup>583,695–697</sup> Because of the large uncertainty in the  $\text{InSb}_{0.31}\text{P}_{0.69}$  energy gap, the first study tried to use the quaternary data, assuming a linear variation between the InAs and  $\text{InP}_{0.69}\text{Sb}_{0.31}$  end points, to deduce the bowing parameter for the ternary.<sup>583</sup> Subsequent studies similarly derived a vanishing bowing parameter for the quaternary.<sup>695–697</sup> Since with that assumption the most recent data<sup>696,697</sup> are consistent with our adopted band gap for  $\text{InP}_{0.69}\text{Sb}_{0.31}$ , we recommend  $C=0$ . However, Adachi<sup>166</sup> suggested the possibility of upward bowing based on the general quaternary relations of Glisson *et al.*<sup>201</sup> and the data of Voronina *et al.*<sup>695</sup> can possibly be explained in that manner. The recommended composition-dependent variation of the 300 K energy gap in InAsSbP lattice matched to InAs is plotted in Fig. 8. The approximate location of the miscibility gap is indicated with a dotted line.

The spin-orbit splitting in InAsSbP has been found to be larger than in either InAs or  $\text{InP}_{0.69}\text{Sb}_{0.31}$ ,<sup>696</sup> although only theoretical estimates are available for the latter. The measurements imply the form:  $\Delta_{so} = 0.39(1-z) + 0.166z + 0.75z(1-z)$ , where the upward bowing parameter is larger than in Ref. 696 owing to a different value assumed for InPsb. While an electron effective mass of  $0.027m_0$  determined<sup>698</sup> for  $\text{InAs}_{0.62}\text{Sb}_{0.12}\text{P}_{0.26}$  is lower than the value of  $0.0288m_0$  derived from a linear interpolation of the interband matrix element and the  $F$  parameter, the latter is nonetheless quite close to the band edge mass found from the band structure fits to the carrier density dependence performed in the same reference. We therefore recommend employing the usual procedure.

## D. Lattice matched to GaSb

### 1. GaInAsSb

GaInAsSb lattice matched to GaSb [or  $(\text{GaSb})_{1-z}(\text{InAs}_{0.91}\text{Sb}_{0.09})_z$ ] is particularly well studied,<sup>699</sup> in part because it is an important active-region constituent of diode lasers emitting at  $\lambda = 2 \mu\text{m}$ .<sup>700</sup> Early work<sup>687,690,701</sup> on the direct band gap in GaSb-rich GaInAsSb was summarized by Karouta *et al.*,<sup>558</sup> who suggested a bowing parameter of 0.6 eV. At the other extreme, data for  $\text{InAs}_{0.91}\text{Sb}_{0.09}$ -rich alloys were found to be consistent with a slightly higher bowing parameter of 0.65–0.73 eV.<sup>695,702</sup> Photoreflectance studies by Herrera-Perez *et al.*<sup>703</sup> and spectral ellipsometry results of Munoz *et al.*<sup>704</sup> support an even higher value for  $C$ . Similarly, recent reports of GaInAsSb grown by liquid-phase epitaxy tend toward higher bowing parameters.<sup>705,706</sup> Our recommended value of  $C=0.75$  eV is a composite obtained by averaging all of the available results. The dependence on composition is then:  $E_g = [0.812(1-z) + 0.346z - 0.75z(1-z)]$  eV at 0 K and  $E_g = [0.727(1-z) + 0.283z - 0.75z(1-z)]$  eV at 300 K. The data of Karouta *et al.*<sup>558</sup> suggest  $C = -0.26$  eV for the spin-orbit splitting, which implies:  $\Delta_0 = [0.76(1-z) + 0.33z + 0.26z(1-z)]$  eV. However, this expression is at variance with the recent ellipsometric data of Munoz *et al.*, which suggests downward bowing of the spin-orbit splitting with  $C=0.25$  eV.<sup>704</sup> The latter result was obtained only for compositions of  $z=0.14$ – $0.15$ . Both the



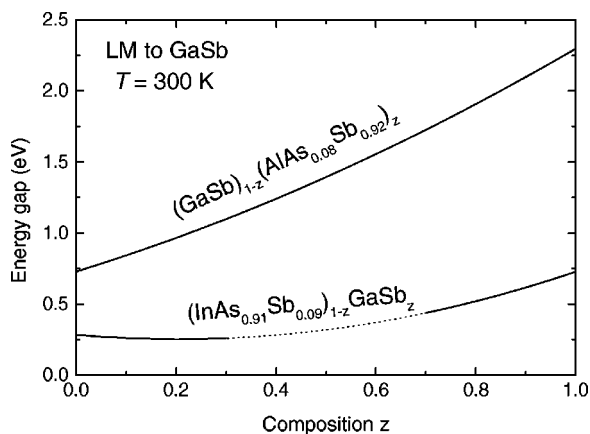


FIG. 9. Energy gaps as a function of composition for  $(\text{GaSb})_{1-z}(\text{AlAs}_{0.08}\text{Sb}_{0.92})_z$  and  $(\text{InAs}_{0.91}\text{Sb}_{0.09})_{1-z}(\text{GaSb})_z$  quaternary alloys, lattice matched to GaSb, at  $T=300$  K. The approximate location of a miscibility gap for InGaAsSb is indicated by a dotted line.

downward bowing of the energy gap and the upward bowing of the spin-orbit splitting are well described<sup>699</sup> quantitatively by the expression of Moon *et al.*,<sup>665</sup> although it should be remarked that in performing such calculations some authors used different bowing parameters for the related ternary alloys.<sup>695</sup> Energy gaps for certain strained GaInAsSb compositions have also been reported.<sup>707–709</sup> The composition-dependent variation of the 300 K energy gap in GaInAsSb lattice matched to GaSb is plotted in Fig. 9. The approximate location of the miscibility gap is indicated by the dotted line.

Pseudopotential results of Bouarissa<sup>710</sup> predict bowing parameters of 0.85 and 0.43 eV for the  $L$ -valley and  $X$ -valley gaps, respectively. The direct-gap bowing parameter quoted in that reference is in reasonably good agreement with the experimental results.

## 2. AlGaAsSb

AlGaAsSb lattice matched to GaSb [or  $(\text{GaSb})_{1-z}(\text{AlAs}_{0.08}\text{Sb}_{0.92})_z$ ] is a natural barrier and cladding material for mid-infrared semiconductor lasers. Relations for the direct and indirect energy gaps were calculated by Adachi,<sup>166</sup> and the experimental results have been summarized by Ait Kaci *et al.*<sup>560</sup> The quoted direct-gap bowing parameter of 0.47 eV agreed well with the pseudopotential calculation of Abid *et al.*<sup>694</sup> and the photoreflectance measurements of Herrera-Perez *et al.*<sup>703</sup> Based on all of these data points, we recommend a composite result of  $C = 0.48$  eV. The band gap at 300 K is then:  $E_g = [0.727(1-z) + 2.297z - 0.48z(1-z)]$  eV. This composition-dependent variation of the direct energy gap in AlGaAsSb lattice matched to GaSb is plotted in Fig. 9.

Although general considerations imply that the bowing of the  $L$ -valley gap should be similar while the  $X$ -valley gap should display little bowing,<sup>166</sup> pseudopotential calculations<sup>694</sup> have suggested bowing parameters of 0.807 and 1.454 eV, respectively. A consequence of the large  $X$ -valley bowing would be a decrease of the predicted direct-to-indirect crossover composition to  $z=0.14$ .

## E. Other substrates

### 1. AlGaAsP

AlGaAsP has been grown on commercially available  $\text{GaAs}_{0.61}\text{P}_{0.39}$  substrates.<sup>711–713</sup> It can be considered as a combination of GaAsP and AlAsP alloys with phosphorus fractions similar to the substrate. A careful investigation of the pump intensity dependence of the PL peaks revealed both impurity and band-to-band transitions.<sup>711</sup> Those results imply a surprisingly large direct-gap bowing parameter of 1.3 eV for the quaternary. However, that value would be reduced considerably if it turns out that the theoretical projection of 0.22 eV for the bowing parameter in AlAsP (see above) is too small.

## F. Nitride quaternaries

The growth of AlGaInN has been reported,<sup>602,621</sup> although little is known about its band structure properties. Recent results indicate a nearly linear band gap reduction for small In compositions ( $<2\%$ ).<sup>714</sup> The cutoff wavelengths of AlGaInN (lattice matched to GaN) ultraviolet photodetectors were also generally consistent with a linear interpolation.<sup>715</sup> Improved crystal quality in comparison with AlGaN has also been noted.<sup>716</sup> Until more precise data become available, we suggest employing the usual quaternary expressions in order to estimate the parameters of this poorly explored material.

## VI. HETEROSTRUCTURE BAND OFFSETS

The preceding sections have discussed the bulk properties of III–V semiconductors and their alloys in isolation. In this section, we turn to a consideration of the conduction and valence band alignments that result when the materials are joined to form heterojunctions in various combinations. Fortunately, it is usually a good approximation to view the valence band position as a bulk parameter for each individual material, which can then be subtracted to determine the relative band alignment at a given heterojunction. The interface dipole contribution, that is particular to each material combination tends to be small, since it is largely screened even when the interface bonding configurations are vastly different. However, it will be seen below that at least for the case of an InAs/GaSb interface, which has no common anion or cation, there is reliable experimental evidence for a small dependence of the offset on the interface bond type.

Our discussion will build upon the previous summary of Yu *et al.*<sup>717</sup> who comprehensively reviewed the understanding of band offsets as of 1991. That work, which may be considered an update of earlier reviews by Kroemer,<sup>718,719</sup> also provided an excellent overview of the methods commonly used in experimental band offset determinations.

Some of the existing theories, such as the model solid theory of Van de Walle,<sup>129</sup> assert that very little bowing of the valence band offset should be expected (although some bowing may arise if there is a strong nonlinearity in the spin-orbit splitting). However, if we are to maintain consistency with the most reliable experimental results for a variety of heterojunctions (e.g., GaAs/AlAs and lattice-matched  $\text{Ga}_{0.47}\text{In}_{0.53}\text{As}/\text{Al}_{0.48}\text{In}_{0.52}\text{As}$ ), a bowing parameter must be assigned to some of the ternary alloys. Since there are almost



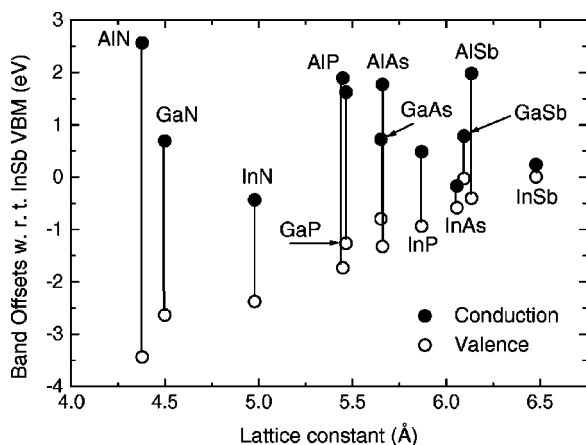


FIG. 10. Conduction (filled) and valence (open) band offsets for the 12 binaries. The  $\Gamma$ -valley energy gap for a given binary corresponds to the difference between the conduction and valence band positions, i.e., the length of the vertical line connecting the filled and open points. Similarly, the conduction (valence) band offset between two distinct binaries corresponds to the energy difference between their respective conduction or valence band positions on the absolute energy scale of the figure.

no reports of temperature variations that exceed the experimental uncertainties, in all cases we will take the valence band offsets to be independent of  $T$ .

Recommended valence band offsets (VBOs) (open points) and conduction band offsets (CBOs) (filled points) for all 12 of the binaries are summarized in Fig. 10. The extent of the energy gap for each material is indicated by the vertical line. Relative positions of the CBOs and VBOs in this figure may be compared to determine the offset for any given heterojunction combination.

The recommended VBOs for materials lattice matched to the common substrate materials of GaAs, InP, InAs, and GaSb are shown in Fig. 11. The points indicate offsets for binary and ternary compounds, while the vertical lines signify VBO ranges that are available using lattice-matched quaternaries. Since a linear variation with composition is assumed for all quaternaries, simple interpolation between the

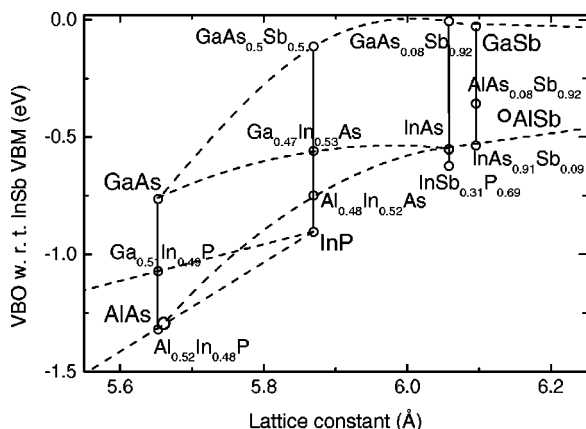


FIG. 11. Valence band offset as a function of lattice constant. The offsets for binaries and lattice-matched ternaries are indicated by points, offset variations with composition for lattice-mismatched ternaries (not including strain effects) are given by dashed curves, and the VBO ranges for quaternary alloys lattice matched to a particular substrate material (GaAs, InP, InAs, or GaSb) are given by the vertical solid lines.

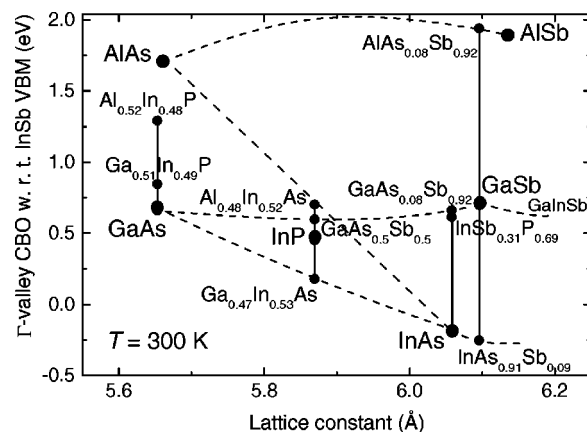


FIG. 12. Conduction band offsets corresponding to the VBOs in Fig. 11. The various points and curves have the same meaning as in that figure.

end point offsets yields the VBO for any desired quaternary alloy. The dashed lines illustrate VBO variations in a number of important lattice-mismatched ternary alloys. Corresponding conduction-band offsets are given in Fig. 12. Although strain effects are neglected in these plots, they are relatively strong and must be included to determine the correct CBO. Note also that since the band gap variation with composition is in general nonlinear (and sometimes double valued), a given point on one of the vertical lines in Fig. 12 does not necessarily map to a single, distinct quaternary alloy composition.

### A. GaAs/AlAs

The GaAs/AlAs heterojunction, which is unique among the III-V semiconductors in terms of growth quality and lattice match, is also the one that has received the most intensive investigation over the years. Although the early work by Dingle *et al.*<sup>720,721</sup> suggested that nearly all of the discontinuity was in the conduction band, later measurements established the well-known 65:35 split between the conduction and valence bands, respectively.<sup>717</sup> Batey and Wright examined the full range of AlGaAs compositions and found that a linear variation of the band offset with Al fraction fitted the results quite well.<sup>722</sup> Although other reports have implied a slight deviation from linearity,<sup>723</sup> we will take the small bowing to occur entirely in the CBO. With this assumption, we average the results obtained for GaAs/AlGaAs by various measurement methods<sup>717,724–743</sup> to obtain the relative VBO between GaAs and AlAs. The result is  $\Delta E_v = 0.53 \text{ eV} = 0.34\Delta E_g$ , which is the best known value for all of the III-V semiconductors and is well within the uncertainty limits of most experiments.

Ref. 717 presented a compilation of early theoretical results for the GaAs/AlAs band offset. While our composite experimental value agrees quite well with the predictions of first-principles calculations by Christensen,<sup>744</sup> Lambrecht *et al.*,<sup>745</sup> and Wei and Zunger,<sup>746</sup> the model-solid theory of Van de Walle<sup>129</sup> obtained a slightly larger offset of  $\Delta E_v = 0.59 \text{ eV}$  and the transition-metal impurity theory of Langer *et al.* yielded a smaller value of  $0.453 \text{ eV}$ .<sup>747</sup> Similarly small values were also predicted by the dielectric midgap energy models of Cardona and Christensen<sup>748</sup> and Lambrecht and

Segall.<sup>749</sup> Offsets ranging from 0.36 to 0.54 eV were obtained by Wang *et al.* from the alignment of the average bonding–antibonding energy on the two sides of the heterojunction.<sup>750</sup> The interface dipole theory of Ohler *et al.* yielded the lowest of the recently reported values,  $\Delta E_v = 0.38$  eV.<sup>751</sup> Considering the uncertainties involved in reliably calculating band offsets, it must be concluded that the bulk of the theoretical work agrees reasonably well with the experiments.

## B. GaInAs/AlInAs/InP

The other well-studied group of heterojunctions is Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As/InP. This system is especially interesting in that it provides a direct test of the degree of offset bowing, since the lattice-matched GaInAs and AlInAs alloys have nearly identical InAs fractions. In light of the well-established GaAs/AlAs result, the expected VBO in the absence of any bowing would be  $\Delta E_v = 0.25$  eV (with  $\Delta E_c = 0.46$ – $0.465$  eV). However, both the early evidence summarized by Yu *et al.*<sup>717</sup> and subsequent data have consistently favored a CBO in the 0.50–0.53 eV range. For example, CBO determinations include 0.52 eV by Welch *et al.* from low-temperature PL studies,<sup>752</sup> 0.505 eV by Satzke *et al.* from electroabsorption data,<sup>753</sup> 0.53 eV by Morris *et al.* from Schottky diode transport,<sup>754</sup> 0.51–0.52 eV by Baltagi *et al.* from photoreflectance data on single quantum wells,<sup>755,756</sup> 0.49 eV by Huang and Chang from an admittance spectroscopy technique,<sup>757</sup> and 0.5 eV by Lugand *et al.* from photocurrent spectroscopy.<sup>758</sup> By carefully modeling the results of PL measurements, Bohrer *et al.* suggested  $\Delta E_c = 0.504$  eV,<sup>759</sup> and a similar result was reported by Huang and Chang on the basis of capacitance–voltage (*C*–*V*) and current–voltage–temperature data.<sup>760</sup> From an XPS study of the Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As junction, Waldrop *et al.* obtained 0.22 eV for the VBO,<sup>761</sup> while Tanaka *et al.* measured the same result using photocurrent spectroscopy.<sup>762</sup> Hybertsen derived a VBO of 0.17 eV from first-principles calculations,<sup>763</sup> which was in good agreement with earlier theoretical determinations (0.14–0.21 eV).<sup>129,748</sup> A CBO of 0.516 eV was determined from tight-binding calculations of Shen and Fan.<sup>470</sup> While Seidel *et al.* observed nontransitivity for the GaInAs/AlInAs CBO using a combination of internal photoemission, current–voltage (*I*–*V*) measurements, and PLE spectroscopy (values of 0.5 and 0.64 eV were obtained for the two possible growth sequences<sup>764</sup>), further investigations of that effect are called for.

Based on this broad and remarkably consistent variety of experimental and theoretical determinations, we recommend a composite result of 0.52 eV (0.19 eV) for the CBO (VBO) at the Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As heterojunction. Making use of the already determined GaAs/AlAs VBO, we can also derive the *difference* between the offset bowing parameters for the two alloys, which is found to be 0.26 eV. This is higher than the value of 0.048 eV suggested by the average-bond-theory results of Zheng *et al.*<sup>765</sup> It will be seen below that by correlating with the data for other heterojunctions, we can further determine how this bowing is distributed between the two alloys.

Using the Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As results, we can also extract reliable band offsets for the Ga<sub>0.47</sub>In<sub>0.53</sub>As/InP and Al<sub>0.48</sub>In<sub>0.52</sub>As/InP heterojunctions. On the basis of experimental reports up to 1991, Yu *et al.*<sup>717</sup> suggested that the CBO for Ga<sub>0.47</sub>In<sub>0.53</sub>As/InP constituted approximately 40% of the total band gap discontinuity of 0.608–0.616 eV. This assignment is in excellent agreement with the later work of Bohrer *et al.*<sup>686,759</sup> Slightly smaller CBOs of 0.22 and 0.2 eV were obtained by Lee and Forrest<sup>766</sup> and Guillot *et al.*,<sup>767</sup> respectively, using *C*–*V* techniques. A much larger CBO of 0.41 eV was reported from the results of absorption spectroscopy by Koteles,<sup>732</sup> and the XPS measurements of Waldrop *et al.* yielded a VBO of 0.34 eV (corresponding to  $\Delta E_c = 0.27$  eV).<sup>761</sup> Theoretical work by Van de Walle<sup>129</sup> and Hybertsen<sup>763</sup> indicated CBOs in the 0.2–0.26 eV range.

A number of works have reported nontransitivity of the Ga<sub>0.47</sub>In<sub>0.53</sub>As/InP band offset. Landesman *et al.* used ultraviolet transmission spectroscopy to study the junction and found a considerable (180 meV) difference between the offsets resulting from the two possible growth sequences (with different interface bond types).<sup>768</sup> The average VBO of 0.35 eV obtained in that study is in good agreement with the results given in other reports. A smaller noncommutativity of 86 meV was also reported by Seidel *et al.*,<sup>764</sup> whose average CBO of 0.23 eV once again agreed reasonably well with the experiments that did not find transitivity violations. The issue of noncommutativity at heterojunctions with no common anion across the interface is controversial from the theoretical point of view as well.<sup>763,769,770</sup> A first-principles pseudopotential calculation by Hybertsen<sup>763</sup> found the GaInAs/InP offset to be transitive to within 10 meV, whereas the self-consistent tight-binding model of Foulon and Priester<sup>769</sup> yielded a 60 meV difference, depending on whether the growth sequence employed InAs-like or GaInP-like interface bonds. Since the evidence for appreciable noncommutativity is inconclusive at this point, we do not specify an interface-bond-type dependence of the band offset in this review. If future work confirms noncommutativity for a particular heterojunction, our recommended offset values can still be used as long as they are considered to be an average for the two bond-type combinations.

Our recommended composite VBO for the Ga<sub>0.47</sub>In<sub>0.53</sub>As/InP heterojunction is 0.345 eV, irrespective of the growth sequence, which corresponds to a CBO of 0.263 eV. With the assumption of transitivity, we also recommend a VBO of 0.155 eV for the staggered Al<sub>0.48</sub>In<sub>0.52</sub>As/InP interface. This value is near the lower end of the 0.11–0.31 eV range of values reported in the literature.<sup>466,472,748,763,759,769–774</sup> One group reported noncommutativity with a 53 meV band-offset difference for that heterojunction.<sup>764,775</sup>

## C. Strained InAs/GaAs/InP and related ternaries

In(Ga)As/GaAs is another important heterojunction that is used in a wide variety of electronic and optoelectronic devices. However, direct measurement of its band offset is considerably complicated by the high degree of strain that was not present in the more straightforward GaAs/AlAs and

Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As/InP cases. One approach is to measure the offset for the lattice-matched Ga<sub>0.47</sub>In<sub>0.53</sub>As/InP (or Al<sub>0.48</sub>In<sub>0.52</sub>As/InP) heterojunction and then make some assumption regarding the GaAs/InP band alignment. (Note that determination of the Ga<sub>0.47</sub>In<sub>0.53</sub>As/Al<sub>0.48</sub>In<sub>0.52</sub>As offset is not helpful, insofar as InAs is present in both alloys in almost equal amounts.) Measurements of the offsets for heterojunctions with varying degrees of strain should be useful, as long as a consistent set of deformation potentials is used to eliminate the strain contributions.

The x-ray photoemission spectroscopy measurements of Hwang *et al.*<sup>776</sup> and Kowalczyk *et al.*<sup>777</sup> predicted VBOs of  $0.11 \pm 0.05$  and  $0.17 \pm 0.07$  eV, respectively, for the bulk, unstrained InAs/GaAs junction. Similar measurements by Wal-drop *et al.*<sup>778,779</sup> implied a consistent offset value of 0.12 eV, although it is somewhat questionable whether strain was completely relieved by dislocations in all of those studies.<sup>777</sup> Correlating the results of Hirakawa *et al.*<sup>780</sup> for strained InAs/GaAs heterojunctions with our assumed deformation potentials, we obtain an average VBO of 0.365 eV. A similar study by Ohler *et al.*<sup>781</sup> claimed good agreement with the model-solid theory of Van de Walle,<sup>129</sup> yielding an offset of 0.28 eV.

Early results for strained InGaAs/GaAs were summarized by Yu *et al.*<sup>717</sup> Although an explicit value for the band offset was not derived in most works, Menendez *et al.* extrapolated  $\Delta E_v = 0.49$  eV for the InAs/GaAs junction.<sup>782</sup> More recently, Hrivnak pointed out the consistency of several experiments with an unstrained conduction (valence) band offset of 0.69 (0.38) eV.<sup>783</sup> Numerous reports of band offsets in InGaAs/GaAs quantum wells have been published.<sup>732,784–801</sup> Since many of those values were found not to be a constant fraction of the band gap, extrapolating to InAs/GaAs is of doubtful validity. Relative CBOs (with respect to the gap difference) tended to be in the 0.57–0.90 range. Variation of the offset with growth direction was also reported.<sup>802</sup>

InAs/GaAs band offsets have also been determined from optical measurements on very thin InAs layers imbedded in GaAs, although strain effects must again be subtracted from the offsets that were actually measured for heavy and light holes.<sup>803</sup> The recent results of Brubach *et al.* are consistent with an unstrained VBO of approximately 0.22 eV,<sup>804</sup> and a theoretical fit of PL data indicated an even smaller value of 0.08 eV.<sup>805</sup> A combination of *C–V* and deep level transient spectroscopy (DLTS) measurements yielded 0.69 eV for the strained CBO.<sup>806</sup> On the other hand, another DLTS study of InAs/GaAs self-organized quantum dots found a CBO of 0.341 eV.<sup>807</sup> A study of InAs/AlAs superlattices produced an unstrained VBO of 0.5 eV (implying a nearly null VBO for InAs/GaAs), although the error bounds were rather large for that result.<sup>808</sup> *I–V* measurements on relaxed InAs/GaAs interfaces yielded 0.34 eV for the VBO.<sup>809</sup>

Considering the wide spread in the experimental offsets for In(Ga)As/GaAs, it is useful to compare with theoretical findings. The Schottky-barrier arguments of Tersoff led to an offset of 0.2 eV,<sup>810</sup> while the transition-metal impurity theory of Langer *et al.* yielded  $\Delta E_v = 0.33$  eV.<sup>747</sup> Using midgap energy levels as a point of reference, Menendez<sup>811</sup> predicted a

VBO of 0.13 eV. The model-solid theory of Van de Walle<sup>129</sup> predicted  $\Delta E_v = 0.28$  eV, and Ohler *et al.* obtained a slightly larger result of 0.33 eV.<sup>751</sup> The common-anion rule,<sup>717</sup> as reformulated by Wei and Zunger for the Ga/In cation pair, predicts a much smaller VBO of 0.06 eV.<sup>746</sup>

Weighing the large number of experimental and theoretical findings together, we conclude that the VBO for the unstrained InAs/GaAs heterojunction is most likely in the 0.1–0.35 eV range. We recommend a composite value of 0.21 eV.

X-ray photoemission spectroscopy has yielded 0.31 eV for the VBO at the InAs/InP heterojunction.<sup>779</sup> A somewhat smaller offset of 0.27 eV was reported on the basis of optical data.<sup>812</sup> Similar offsets were deduced from InAsP/InP quantum well measurements,<sup>573,813–816</sup> although a considerably larger VBO was found in one study.<sup>817</sup> An unstrained VBO of 0.39 eV was determined from PL measurements by Disseix *et al.*,<sup>818</sup> and 0.41 eV was obtained from fits to the PL data for very thin InAs/InP quantum wells.<sup>819</sup> The model-solid theory of Van de Walle<sup>129</sup> predicted a VBO of 0.44 eV, whereas Ohler *et al.*<sup>751</sup> and Tersoff<sup>810</sup> calculated smaller values of 0.26–0.27 eV. In order to be consistent with the majority of investigations, an intermediate VBO value of 0.35 eV is recommended for the unstrained InAs/InP heterojunction.

Assuming transitivity, the discussion above implies that the VBO for the unstrained GaAs/InP heterojunction should be 0.14 eV, which is roughly consistent with the result of x-ray photoemission spectroscopy (0.19 eV).<sup>779</sup> With these results in hand, we can calculate VBO bowing parameters for the GaInAs and AlInAs alloys, and find  $-0.38$  and  $-0.64$  eV, respectively. Note that the negative sign for the VBO bowing parameter is consistent with the reduction of the energy gap below the virtual-crystal approximation in alloys.

Accurate measurements of the VBO at heterojunctions combining GaAsSb with GaInAs and AlInAs have also been performed.<sup>537,541,820–822</sup> In Ref. 823, the CBO appears reliable, but the VBO was determined incorrectly, the accurate result being 0.48 eV. These data are reasonably well converged for the case of GaAsSb lattice matched to InP, and imply a large VBO bowing parameter of  $-1.06$  eV. GaPSb lattice matched to InP has also been studied and tentatively found to exhibit a VBO of 0.5 eV, which is roughly consistent with a linear variation of the VBO in this alloy (no bowing).<sup>581</sup> A VBO of 0.28 eV has been reported for the InAlAs/AlAsSb heterojunction lattice matched to InP (with a type-II staggered alignment).<sup>561</sup> On the basis of this result, we tentatively assign a large bowing parameter of  $-1.71$  eV to the AlAsSb alloy.

#### D. GaInP/AlInP/GaAs

The band gap for the lattice-matched alloy Ga<sub>0.51</sub>In<sub>0.49</sub>P is 0.49 eV higher than that of GaAs in the temperature range up to 300 K. An early Shubnikov–de Haas experiment yielded a CBO of 0.39 eV.<sup>824</sup> Watanabe and Ohba measured a smaller CBO of 0.19 eV using the conduction–voltage profiling technique,<sup>825</sup> which is in good agreement with similar studies by Rao *et al.*,<sup>826</sup> Lee *et al.*,<sup>827</sup> and Feng *et al.*,<sup>828</sup> and



with the DLTS measurements of Biswas *et al.*<sup>829</sup> Other experiments found that the VBO constitutes an even larger fraction of the band gap discontinuity ( $\Delta E_v = 0.32\text{--}0.46\text{ eV}$ ).<sup>830–837</sup> One study obtained a small CBO for the GaInP/AlGaAs heterojunction in the low-Al-fraction limit,<sup>838</sup> while other recent reports have found values intermediate between the two limits.<sup>839–841</sup> Considering the persisting disagreement, we have averaged all of the available data points to obtain a composite recommended VBO of 0.31 eV for Ga<sub>0.51</sub>In<sub>0.49</sub>P. This value is near the median of the reported range, and is consistent with the latest studies. Foulon *et al.* predicted noncommutativity for the band offset at the GaInP/GaAs interface.<sup>842</sup>

The important GaInP/Al(Ga)InP heterojunction for which both constituent materials are lattice matched to GaAs has also been investigated extensively. The earliest PL study<sup>843</sup> assigned 57% of the total GaInP/AlInP band-gap discontinuity of 0.68 eV to the VBO. Subsequent PL and PLE studies<sup>489,844</sup> found the offset to be 35% and 25%, respectively. The smaller values were confirmed by the widely cited report of Dawson and Duggan who found a VBO of 33%,<sup>493</sup> as well as Kowalski *et al.* (35%),<sup>845</sup> Interholzinger *et al.* (31%),<sup>501</sup> and Zhang *et al.* (32%).<sup>846</sup> Whereas all of those authors considered a quaternary on one side of the heterojunction, the GaInP/AlInP junction was also investigated and found to exhibit<sup>506,847</sup>  $\Delta E_v = 0.24\text{ eV}$  in good agreement with the other reports. Two studies<sup>498,848</sup> considered the full composition range of the quaternary and found an offset of 0.22 eV in the AlInP limit, with evidence for a VBO bowing parameter of 0.157 eV. On the other hand, photoemission measurements at a considerably larger number of compositions yielded  $\Delta E_v = 0.305\text{ eV}$  and no substantial deviation from linearity.<sup>849</sup> The VBO obtained from DLTS (0.36 eV)<sup>850</sup> was 53% of the total band gap discontinuity. On the other hand, the combined PL, PLE, and photoreflectance (PR) investigations of Ishitani *et al.*<sup>851</sup> gave only 25% (0.17 eV). It is unclear why these latter studies appear to disagree with the converging PL data on which we base our recommended value of  $\Delta E_v = 0.24\text{ eV}$  (35% of  $\Delta E_g$ ). Two available studies of the GaAs/AlInP heterojunction put the VBO at 0.62–0.63 eV.<sup>825,839</sup> Transitivity implies a GaInP/AlInP VBO of 0.31–0.32 eV, although the disagreement with the smaller recommended result is nearly within the stated error bounds. We recommend that the unconfirmed VBO bowing for the AlGaInP quaternary be disregarded.

### E. GaP and AIP

Both experimental and theoretical VBOs have been reported for the nearly lattice-matched GaP/AIP heterojunction.  $C-V$  profiling,<sup>852</sup> x-ray photoemission spectroscopy,<sup>853</sup> and PL<sup>854</sup> indicated  $\Delta E_v = 0.41, 0.43$ , and  $0.55\text{ eV}$ , respectively. A wide variety of theoretical calculations<sup>129,746,748–750,770,855,856</sup> produced results falling mostly in the 0.34–0.69 eV range. These values can be compared directly with the GaInP/AlInP VBO, since the InP fraction in the latter does not change across the interface. Linear extrapolation yields an offset of 0.47 eV for the GaP/AIP interface. In view of the experimental uncertainty and

the small strain correction, we recommend this value. Further inference is that the VBO bowing parameters for GaInP and AlInP are nominally equal (the simplest assumption is that they both vanish). A linear variation of the VBO may be taken for the AlGaP alloy.<sup>852,855</sup>

Experimental and theoretical studies of the GaAs/GaP band alignment are also available. Some extrapolated from the GaAsP alloy with the assumption that there is no offset bowing. Katnani and Margaritondo used photoemission to determine an unstrained VBO of 0.63 eV,<sup>857</sup> while Gourley and Biefeld obtained 0.6 eV from PL/PLE measurements.<sup>858</sup> The assumption by Pistol *et al.*<sup>859,860</sup> that nearly all of the low-temperature band gap discontinuity of 0.54 eV is in the valence band, while the  $X$ -valley conduction minima line up in the two unstrained materials, was corroborated by PL measurements. Another recent optical study<sup>861</sup> obtained  $\Delta E_v = 0.6\text{ eV}$ . On the other hand, optical experiments on GaAs/GaAsP quantum wells found a much smaller VBO of 0.38–0.39 eV.<sup>862,863</sup> Large CBOs were derived by many of the same authors for GaAsP/GaP quantum wells.<sup>864</sup> A small extrapolated VBO of 0.28 eV was also proposed by Shan *et al.* on the basis of pressure-optical measurements.<sup>865</sup> Pseudopotential calculations in conjunction with PL measurements performed by Neff *et al.*<sup>866</sup> imply a VBO of 0.41 eV, which is similar to the value calculated by Di Ventra *et al.*<sup>867</sup> Experimental and calculated band offsets for the GaAsP/AlGaAs heterojunction with small P and Al fractions have also been reported,<sup>868,869</sup> although extrapolation to GaP may be problematic in that case. Various theories<sup>129,746,870–873</sup> found values in the 0.19–0.63 eV range. Averaging the reported experimental values we obtain a recommended GaAs/GaP VBO of 0.47 eV, which is also in the middle of the theoretical range and equal to recent first-principles calculations.<sup>746</sup> This value is also fully consistent with an independent report of 0.6 eV for the VBO at the GaP/InP heterojunction.<sup>874</sup> In view of the GaAs/InAs, InAs/InP, and GaAs/GaInP offsets derived above, it is apparent that the VBO bowing for GaInP (and by implication AlInP) can be assumed to vanish.

### F. GaSb/InAs/AlSb

Since the InAs/GaAs band offset was already established above, we can use the alignment for the nearly lattice-matched InAs/GaSb and InAs/AlSb heterojunctions to forge a link between the antimonides and the GaAs-based and InP-based systems.

We first focus on the GaSb/AlSb heterojunction, which has a type-I band alignment. Early results suggesting a small VBO were reviewed by Yu *et al.*<sup>717</sup> However, Tejedor *et al.*<sup>875</sup> deduced  $\Delta E_v > 0.27\text{ eV}$  from a comparison of resonant Raman scattering experiments with tight-binding theory. Using x-ray photoemission spectroscopy, Gualtieri *et al.*<sup>876</sup> reported  $\Delta E_v = 0.40\text{ eV}$  with relatively large (38%) error bounds. While that finding was later disputed by Ley,<sup>877</sup> who suggested a revision to 0.27 eV, the former authors responded by insisting on the accuracy of their result.<sup>878</sup> Menendez *et al.* obtained  $\Delta E_v = 0.45\text{ eV}$  using a light-scattering method.<sup>879</sup> Cebulla *et al.* found 0.35 eV from

absorption and excitation spectroscopy,<sup>880</sup> Yu *et al.* measured 0.39 eV using x-ray photoelectron spectroscopy,<sup>881</sup> and Shen *et al.* obtained 0.23 eV from PR measurements on GaSb/AlSb quantum wells.<sup>882</sup> Chen *et al.* deduced a VBO of 0.48 eV from a comparison of band structure calculations with tunneling measurements on InAs/AlSb/GaSb single-barrier interband diodes.<sup>883</sup> Leroux and Massies<sup>884</sup> derived an unstrained offset of  $0.3 \pm 0.075$  eV from fits to the PL spectra for GaSb/AlGaSb quantum wells. Yu *et al.* noted previously<sup>717</sup> that most of the later experimental studies converge on an average value of 0.38 eV, which is our recommendation as well. More recent theoretical studies have also produced results in the 0.30–0.49 eV range.<sup>129,745,746,749,750,770,870,885,886</sup> Theory predicts a linear variation of the offset in the AlGaSb ternary.<sup>887</sup>

The InAs/GaSb junction has a type-II broken-gap lineup, with the bottom of the conduction band in InAs being lower than the top of the valence band in GaSb. This unusual band alignment has stimulated numerous investigations of type-II superlattices and quantum wells. For example, the junction exhibits semimetallic properties as long as quantum confinement and field-induced energy shifts are not too strong.

There have been many theoretical calculations of the valence band offset at the InAs/GaSb interface,<sup>129,717,744–746,748–750,769,770,810,888,889</sup> the most reliable tending to yield results in the 0.43–0.59 eV range. Several models predicted that the VBO should be larger for the InSb-like interface bond type than for GaAs-like interfaces. Foulon *et al.*,<sup>769</sup> Dandrea *et al.*,<sup>890</sup> and Montanari *et al.*<sup>888</sup> reported an average difference of 35 meV. *Ab initio* molecular dynamics calculations of Hemstreet *et al.* yielded a difference as large as 150 meV due to varying interface charge distributions,<sup>891</sup> later refinements in the calculation reduced this difference to 40 meV.<sup>892</sup>

Experimentally, energy gaps were measured to be 25–90 meV lower in InAs/GaSb superlattices with InSb-like interface bonds than in structures with nominally identical layer thicknesses and GaAs-like bonds.<sup>893–895</sup> Based on a magnetotransport study the Naval Research Laboratory (NRL) concluded that the valence band offset is 14 meV larger for InSb-like bonds.<sup>896</sup> The Oxford University group obtained 40 meV<sup>897</sup> and 30 meV<sup>898</sup> differences in two studies, whereas Wang *et al.* did not observe any variation of the VBO with bond type.<sup>899</sup> It is possible that the offset may depend on details of the interface structure produced by particular growth conditions. Since most of the experimental and theoretical studies have found a small but real dependence on bond type, we recommend that the “average” InAs/GaSb VBO specified below should be applied only to cases where no particular bond type was forced in the growth. For InSb-like bonds 15 meV should be added to that result, while for GaAs-like bonds 15 meV should be subtracted.

Experimental band offset determinations for this material system fall into two main classes: (1) direct determinations, and (2) fits to the measured optical transitions in semiconducting superlattices and quantum wells (i.e., in which there is enough quantum confinement to induce an energy gap). Among the former class of results, Gualtieri *et al.* obtained a VBO of  $0.51 \pm 0.1$  eV using x-ray photoemission

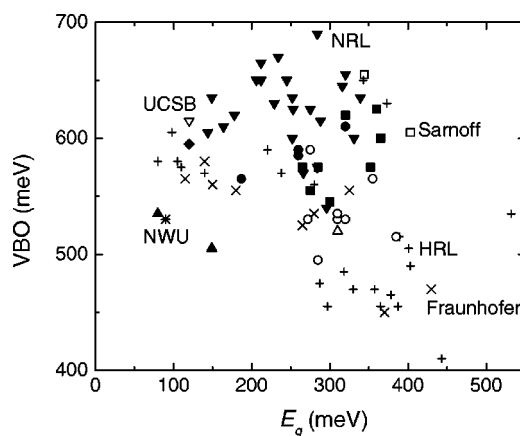


FIG. 13. InAs/GaSb valence-band offsets derived from fits to energy gaps measured for various type-II quantum well and superlattice structures. An 8-band  $\mathbf{k}\cdot\mathbf{p}$  finite-element algorithm was used to calculate the offset corresponding to each energy gap when all other band structure parameters assumed their recommended values. The data are taken from Refs. 904 (solid squares), 905 (solid circles), 906 (solid upright triangles), 911, 912, 931, 933 (solid inverted triangles), 907, 908, 910, 913, 914, 916, 918, 920, 922, 923, 926 (crosses), 915, 921 (multiplication signs), 909 (diamond), 917 (open inverted triangle), 924, 925, 927, 929 (open circles), 930 (open upright triangles), 932 (open squares), and 919 (star).

spectroscopy.<sup>900</sup> Whereas Srivastava *et al.*<sup>901</sup> measured  $\Delta E_v = 0.67$  eV from  $C-V$  profiling of a GaSb/InAs<sub>0.95</sub>Sb<sub>0.05</sub> heterojunction, Mebarki *et al.*<sup>902</sup> obtained 0.36 eV for a GaSb/InAs<sub>0.89</sub>Sb<sub>0.11</sub> interface using essentially the same technique. X-ray photoelectron spectroscopy yielded 0.62 eV.<sup>903</sup> For an InAs/GaSb long-period superlattice at 4 K, the Oxford group measured band overlap energies of 100–140 meV, depending on the interface bond type.<sup>897</sup> That those values increased by 30 meV at room temperature implies an average VBO of 0.52 eV, with little temperature variation ( $<8$  meV). Another study by the same group produced an average offset of 0.54 eV.<sup>898</sup> Wang *et al.* found a 90 meV variation of the VBO based on growth sequence (InAs on GaSb versus GaSb on InAs).<sup>899</sup>

Next, we discuss a previously unpublished application of the second approach. Experimental optical transition energies for a variety of semiconducting type-II superlattices and quantum wells<sup>893,904–934</sup> have been fit to theory, in this case an eight-band finite-element method  $\mathbf{k}\cdot\mathbf{p}$  algorithm.<sup>57</sup> The important strain effects are included and the recommended band structure parameters in Tables III, VII, and XVIII are employed, with the only fitting parameter being the InAs/Ga(In)Sb interface VBO that is taken to be consistent with the recommended GaSb/InSb VBO discussed below. Most of the data are from PL and mid-IR laser experiments at temperatures in the 4.2–300 K range, and energies on the order of  $kT$  have been subtracted from the PL emission peaks.

Results for the fitted VBO, plotted as a function of energy gap for the given structure, are presented in Fig. 13. The various types of points correspond to data for structures grown by different groups, which are identified in the caption. The range of fitted VBO values is surprisingly large, spanning more than 200 meV. Especially noticeable are the substantial systematic differences between the offsets derived using data from different groups (or sometimes within

the same group for different types of structures or for structures grown during different time intervals). Possible implications include: (1) the growth conditions actually influence the offset, (2) the growth-dependent nonideality of the structure, e.g., related to interface roughness or anion cross contamination, has a larger-than-expected effect on the energy gap, or (3) the layer-thickness calibrations have large uncertainties. For example, while the energy gaps corresponding to growths at the Fraunhofer Institute<sup>915,921</sup> and HRL Laboratories<sup>907,908,910,913,914,916,918,920,922</sup> yield an average VBO of 0.53 eV and structures grown at the University of Houston<sup>924,925,927,929</sup> yield 0.54 eV (all with fluctuations of at least 100 meV), the band gaps corresponding to NRL growths<sup>911,912,933</sup> imply a much larger average VBO of 0.62 eV. In some cases the differences are as large as 100 meV for structures that are nominally quite similar. Such differences are well outside the usual bounds of experimental uncertainties in the spectral data and layer thicknesses. A relatively strong dependence of the energy gap on growth temperature for nominally identical structures has also been reported.<sup>935</sup> Although the primary mechanism has not been isolated, subsequent TEM measurements showed that threading dislocations are present in the samples grown above the optimal growth temperature, and cross-sectional STM indicated greater interface roughness.<sup>936</sup>

Averaging all of the band offsets displayed in Fig. 13, along with the direct determinations summarized above, we obtain a composite InAs/GaSb VBO of 0.56 eV. This value is somewhat larger than the earlier suggestion of 0.51 eV,<sup>717</sup> and is at the high end of the 0.51–0.56 eV range that is usually employed in modeling antimonide materials. Since the fluctuations in reported values are so large for this system at its current level of understanding, it is advisable to account for the source and type of the structure in deciding which offset to use. Again, the recommended 0.56 eV represents an “average” value that should be corrected for the interface bond type.

The transitivity rule, applied in conjunction with the recommended InAs/GaSb and GaSb/AlSb band offsets, implies an “average” VBO of 0.18 eV for the staggered InAs/AlSb heterojunction. Bearing in mind that the transitivity assumption may be of questionable validity when applied to systems with more than one anion,<sup>769</sup> we can examine whether that value is consistent with the direct experimental and theoretical evidence for this interface. Nakagawa *et al.*<sup>937</sup> employed  $C-V$  profiling to obtain a CBO of 1.35 eV between the  $\Gamma$ -valley minimum in InAs and the  $X$ -valley minimum in AlSb. Using our recommended band gap parameters, this corresponds to a VBO of 0.09 eV. More recently, that work was extended to AlAsSb barriers.<sup>938</sup> The findings are in reasonable agreement with the previously assumed large VBO ( $\sim 2$  eV) in AlAsSb. A PL study by Yang *et al.* found that the band alignment between InAs<sub>1-x</sub>Sb<sub>x</sub>/AlSb quantum wells becomes type I when  $x > 0.15$ .<sup>939</sup> In that study, InAsSb was realized as a digital superlattice. If all the offsets are referenced to the InSb valence band maximum, this implies that the AlSb VBO is no more than 85% of the InAs VBO. Using x-ray photoemission spectroscopy to study interfaces with InSb-like and AlAs-like bonds, Waldrop *et al.* obtained

an average VBO of 0.18–0.19 eV and derived a difference of 60 meV between the two bond types.<sup>940</sup> However, a first-principles calculation by Dandrea and Duke<sup>941</sup> found no dependence of the VBO on bond type, and suggested that Waldrop *et al.*<sup>940</sup> misinterpreted their data by discarding the smaller offset obtained for an AlAs-like bond in one experiment. Other calculations<sup>129,717,745,746,749,750,770,810,871,873,889</sup> have found  $\Delta E_v$  spanning the wide range between 0 and 0.54 eV, with the most reliable values clustered around 0.05–0.27 eV. The combined experimental and theoretical evidence appear to offer no compelling reason to reject the transitivity rule when applied to the antimonide heterojunctions. We also recommend neglecting any dependence of the InAs/AlSb VBO on interface bond type.

### G. GaSb/InSb and InAs/InSb

The corrected common-anion rule predicts a negligible band offset for the unstrained GaSb/InSb heterojunction.<sup>746</sup> Other theories have produced values in the range  $-0.08$  to  $0.16$  eV<sup>129,810,872,873,889,942,943</sup> (where we take the sign to be positive if the valence band maximum is higher in InSb). In experimental practice, this offset must be derived from measurements on heterojunctions such as GaSb/Ga<sub>1-x</sub>In<sub>x</sub>Sb and InAs<sub>1-y</sub>Sb<sub>y</sub>/InAs<sub>1-x</sub>Sb<sub>x</sub> due to the large lattice mismatch between the two binaries. For an InAs<sub>1-y</sub>Sb<sub>y</sub>/InAs<sub>1-x</sub>Sb<sub>x</sub> junction in the Sb-rich limit (large  $x$  and  $y = 1$ ), initial optical measurements supported an unstrained VBO of  $(0.36-0.41)(1-x)$  eV.<sup>944,945</sup> In the As-rich limit (small  $x$  and  $y = 0$ ), on the other hand, Li *et al.* concluded from fits to magneto-optical spectra that the top of the InAsSb valence band appeared lower than that in InAs ( $-0.84x$  eV).<sup>946,947</sup> That result implied a substantial CBO and negative VBO for small  $x$ .<sup>948,949</sup> Wei and Zunger pointed out that a negative VBO for InAs/InSb directly contradicts other theoretical and experimental evidence.<sup>549</sup> Other experiments<sup>950-952</sup> are in much better agreement with the usual theoretical finding of an essentially null CBO, which yields a type-I or type-II staggered alignment depending on details of the strain and ordering conditions. All of the above works found that the unstrained VBO in InAs<sub>1-x</sub>Sb<sub>x</sub> depends almost linearly on composition  $x$ . While an unstrained VBO of 1.1 eV was derived for ultrathin InSb embedded in InP,<sup>953</sup> one cannot place high confidence in that result owing to the difficulty of precisely accounting for the very large strain effects.

A few groups<sup>954-956</sup> have used PL, electroluminescence, and photoconductivity to measure VBOs for GaInSb/GaSb quantum wells. Those studies assumed a linear variation of the Ga<sub>1-x</sub>In<sub>x</sub>Sb VBO with alloy composition, although in one study<sup>957</sup> the PL peak energies could not be fit using a reasonable dependence. Finally, a recent study of exciton transitions in InSb/AlInSb strained quantum wells produced heavy-hole offsets that were 38% of the total band gap discontinuity for Al fractions below 12%.<sup>958</sup> Unfortunately, extrapolation to the InSb/AlSb VBO from the results of this work may not be justified.

Accounting for the effects of strain and averaging the various results, we recommend a GaSb/InSb VBO of 0.03 eV.



## H. Quaternaries

Band offsets involving lattice-matched quaternaries have also been studied both experimentally and theoretically.<sup>959</sup> See Sec. V A 1 for a discussion of the AlGaInP/GaAs heterojunction.

Cho *et al.* considered the GaInP/GaInAsP interface lattice matched to GaAs, and suggested a linear variation of the CBO with quaternary composition.<sup>960</sup> Since the direct GaInAsP band gap appears to be nearly independent of composition, this implies a linear variation of the VBO as well. However, note that the value employed for the absolute gap was somewhat different from our recommendation. The same authors also investigated the band offset transitivity in AlGaAs/GaInP/GaInAsP heterostructures lattice matched to GaAs.<sup>961</sup> The results are in good agreement with our suggested offsets, provided a linear variation is assumed for each constituent. The small direct-gap bowing parameter and the results discussed above also imply that any bowing in the VBO for the AlGaInP alloy should be small.

Sugawara has theoretically predicted a slight bowing in the position of the valence-band maximum for GaInAsP on InP.<sup>962</sup> Experimentally, a VBO of 0.08 eV was measured for  $\text{Ga}_{0.13}\text{In}_{0.87}\text{As}_{0.29}\text{P}_{0.71}/\text{InP}$ , as compared to 0.10 eV from linear interpolation.<sup>963</sup> Although error bounds were not cited, this discrepancy is probably within the experimental uncertainty. Forrest *et al.*<sup>964</sup> found evidence that the CBO bowing is at most small, which, in combination with the small band gap bowing, implies a negligible VBO bowing. Soucail *et al.* found a small bowing parameter of 0.09 eV, which is barely larger than the estimated experimental uncertainty.<sup>965</sup>

The band offsets for AlGaInAs on InP have also been studied both experimentally and theoretically.<sup>470,686,966–968</sup> There is no clear agreement as to whether most of the band gap bowing, which is rather small in any event, should be assigned to the CBO or the VBO. We recommend a linear interpolation between the dependence for GaInAs and AlInAs, both of which exhibit appreciable VBO bowing.

Recently, a series of three articles reported determinations of the offsets for GaInAsSb and AlInAsSb, lattice matched to InP, from fits to low-temperature PL measurements.<sup>688,969,970</sup> All of the results agree with linear interpolations of our recommended values (with appropriate VBO bowing parameters) to within the cited experimental uncertainty.

Calculations of the band offsets for AlGaAsSb quaternaries lattice matched to various substrates have been reported.<sup>559</sup> In particular, Polyakov *et al.* obtained a VBO of 0.15 eV for AlGaAsSb on GaSb.<sup>971</sup> Rather than using this value to derive the bowing parameter for AlGaAsSb, we interpret it as reflecting the uncertainty in the bowing parameter for AlAsSb. The study on the quaternary implies a bowing parameter of 2.4 eV, which is slightly larger than the assumed value of 1.7 eV. We recommend the VBOs for AlGaAsSb obtained by linear interpolation between the ternary relations.

Mikhailova and Titkov have reviewed band offset results for the GaInAsSb quaternary on InAs and GaSb (up to 1994).<sup>699</sup> A theoretical work by Nakao *et al.* predicted some

bowing in the VBO.<sup>959</sup> Results of the direct experimental study of GaInAsSb/GaSb by Mebarki *et al.*<sup>972</sup> are in good agreement with a linear interpolation of our recommended offsets for InAsSb and GaSb.  $C-V$  measurements of Polyakov *et al.* are also consistent with that procedure.<sup>973</sup> The linear interpolation approach differed appreciably only with the findings of Baranov *et al.*<sup>974</sup> and Afrailov *et al.*,<sup>702</sup> for which the discrepancies are opposite in sign. Considering all of the reported experimental results, we see no compelling reason to introduce bowing. The VBOs have also been reported for the GaInAsSb/AlGaAsSb heterojunctions lattice matched to GaSb.<sup>975</sup> The results for both In-rich and In-poor junctions indicated reasonably good agreement with a linear interpolation. Band offset measurements have also been reported for the strained GaInAsSb/AlGaAsSb system.<sup>976,977</sup> Except for the case of GaInAsSb, a tight-binding calculation<sup>959</sup> supports our conclusion that the bowing in these quaternaries is negligible.

## I. GaN, InN, and AlN

We emphasize at the outset that the band offsets recommended below for the nitride system should be understood to have large uncertainties. This is primarily because the reported results have rarely included the full effects of residual strain, spontaneous polarization, and piezoelectric fields in a completely satisfying manner. In particular, the presence of macroscopic polarization can render the notion of reference bulk energy levels somewhat ambiguous. The most significant future advancements in the understanding of nitride offsets will probably be connected with that issue.

Since the nitride materials typically crystallize in the wurtzite form, an obvious question is how the valence band edge of that phase lines up with the zinc blende phase of the same compounds. The issue was addressed by Murayama and Nakayama using a first-principles pseudopotential calculation,<sup>978</sup> which projected VBOs for the two phases that differed by only 34 meV in GaN and 56 meV in AlN (no results were quoted for InN). Those VBOs are much smaller than the error bounds for current experimental determinations of the nitride offsets. Wei and Zunger<sup>326</sup> calculated a similar difference of 30 meV between the wurtzite and zinc blende forms of the GaN/AlN interface, and also a difference on the order of 0.2 eV for GaN/InN and AlN/InN heterojunctions. While the effects of macroscopic polarization were not included, these results provisionally allow us to align the wurtzite and zinc blende materials on an absolute energy scale. Furthermore, study of the GaAs/GaN (zinc blende) heterojunction has provided a tentative connection with the other III–V materials. X-ray photoemission spectroscopy yielded a VBO of  $1.84 \pm 0.1$  eV,<sup>979</sup> which is the only available direct measurement and our recommended value. The implication of a staggered alignment with  $\Delta E_c = 0.03$  eV strongly disagrees with the finding of  $\Delta E_v = 0.5$  eV and a large positive CBO by Martin *et al.*<sup>980</sup> and Huang *et al.*<sup>981</sup> from electrical measurements. The discrepancy may be related to strain and other uncertainties in the electrical studies. The investigations of the VBO in the GaAsN/GaN heterojunctions yielded a range of different results, and the N frac-

tion was too low to extrapolate the GaAs/GaN VBO with any confidence.<sup>982–984</sup> The observed VBO was found to be quite small, with the question of type-I versus type-II alignment remaining somewhat controversial.

Theoretically, the GaAs/GaN VBO was first estimated by Harrison and Tersoff.<sup>985</sup> Their result of 2.21 eV is quite similar to the value of 2.18–2.28 eV recently suggested by Bellaiche *et al.*<sup>636,746</sup> A first-principles linear-muffin-tin-orbital calculation by Agrawal *et al.* yielded 1.86 eV for the free-standing (i.e., strain-free) GaAs/GaN superlattice.<sup>986</sup> Those authors also predicted a strong dependence on the interface properties. In view of the present uncertainties, the agreement between experiment and theory should be considered quite good (apart from the electrical studies).

The valence-band discontinuity at the (zinc blende) GaN/AlN interface was first probed experimentally by Sitar *et al.*,<sup>365</sup> who obtained 1.4 eV from fits to optical measurements on GaN/AlN superlattices. Subsequently, Baur *et al.* found a VBO of 0.5 eV by measuring the difference between the acceptor levels of iron in each material.<sup>987</sup> X-ray photoemission spectroscopy yielded a VBO of 0.8 eV at the wurtzite GaN/AlN junction,<sup>988</sup> which was revised to 0.70 eV in a later article by the same authors.<sup>989</sup> Using the same approach, Waldrop and Grant found a considerably different value of 1.36 eV.<sup>990</sup> Those authors also reported a nearly linear VBO variation in the AlGaIn alloy, with a positive bowing parameter of 0.59 eV.<sup>991</sup> Using x-ray and ultraviolet photoelectron spectroscopy, King *et al.* found that the GaN/AlN VBO ranged from 0.5 to 0.8 eV, depending on the growth temperature.<sup>992</sup> They surmised that the differences arose from strain, defects, and film stoichiometry effects. A VBO in the 0.15–0.4 eV range was reported by Rizzi *et al.*,<sup>993</sup> who pointed out that the Ga 3*d* core level, which has been used as a reference in GaN, is in fact hybridized with other valence bands.

On the theoretical front, calculations were performed by Albanesi *et al.*<sup>994</sup> and Chen *et al.*<sup>995</sup> for the zinc blende AlN/GaN interface, and by Satta *et al.*,<sup>996</sup> Ke *et al.*,<sup>997</sup> and Wei and Zunger<sup>746</sup> for the corresponding wurtzite junction. All of these works obtained VBOs in a rather narrow range from 0.7 to 0.85 eV. The last two articles found almost no difference between offsets for the cubic and hexagonal versions of the junction. A slightly lower value of 0.6 eV was calculated by Monch.<sup>998</sup> The importance of strain was studied by Binggeli *et al.* and Nardelli *et al.* The former found  $\Delta E_v = 0.94$  eV for the relaxed zinc blende interface,<sup>999</sup> while the latter obtained 0.44–0.73 eV for the strained zinc blende interface (depending on the substrate lattice constant) and 0.57 eV for the strained wurtzite interface.<sup>1000</sup> Recently, Bernardini and Fiorentini<sup>1001</sup> studied macroscopic bulk polarization effects on the interface-charge contribution to the offset at the wurtzite heterojunction. They found VBO values of 0.20 and 0.85 eV corresponding to the underlying GaN and AlN lattice constants. However, most of the reported difference was from band-edge shifts in the bulk band structure, with only 0.18 eV due to the interface-charge contribution. We recommend using an unstrained band offset of 0.8 eV for both wurtzite and zinc blende interfaces. This represents the median of the reported values, and is also closest to the larg-

est number of experimental and theoretical results. However, we caution again that the effects of spontaneous polarization and piezoelectric fields must be very carefully accounted for when applying this recommendation to the modeling of real GaN/AlN interfaces.

In comparison with GaN/AlN, the GaN/InN and AlN/InN junctions have strongly mismatched lattice constants. Theoretical values for the unstrained GaN/InN VBO are 0.3 eV<sup>381</sup> and 0.26 eV<sup>326</sup> for the zinc blende phase and 0.48 eV for the wurtzite phase.<sup>326</sup> The valence band in the technologically important GaInN alloy may be obtained from a linear interpolation. VBOs of 0.70 and 1.37 eV were calculated, respectively, for the wurtzite GaN/InN and AlN/InN junctions strained to AlN.<sup>1000</sup> Strain-induced piezoelectric fields, which can depend on the growth sequence, significantly complicate any experimental determination of the GaN/InN and AlN/InN band offsets. Only one experimental study of these two interfaces has been reported to date.<sup>989</sup> The VBO results of 1.05 and 1.81 eV were roughly corrected for piezoelectric fields due to residual strains, and it was concluded that transitivity for the GaN/AlN/InN system is obeyed to within experimental precision. Provisionally, we adopt a VBO of 1.05 eV for wurtzite GaN/InN. The large disagreement with the intuitive expectation of a small offset for this common-anion heterojunction remains to be resolved. Using transitivity, we derive 1.85 eV for the VBO of the wurtzite AlN/InN junction. For the zinc blende GaN/InN and AlN/InN interfaces, we recommend using the results of Wei and Zunger<sup>326</sup> (slightly modified to ensure transitivity): 0.26 eV and 1.06 eV, respectively.

## VII. SUMMARY

We have reviewed the available information about band structure parameters for 12 technologically important III–V semiconductors and their ternary and quaternary alloys at the close of the 20th century. Whereas numerous reports of such parameters may be found in the literature, no *complete* and *fully consistent* set has been published previously. Earlier reviews were either restricted to particular material systems, did not address all parameters of interest, or were biased to the results of a specific group of investigators. On the other hand, our goal has been to provide a comprehensive and even-handed reference source, as free of internal contradictions and significant omissions as is practically possible in a work of this scope. We have also illustrated how the proposed parameters fit into the band structure computations.

The semiconductor band parameter knowledge base continues to expand as new reports are published daily. While the most fundamental parameters such as the energy gaps and effective masses are by now fairly well established for most of the III–V materials, we anticipate many new advances, particularly concerning band offsets and other parameters for the less mature systems such as the nitrides and antimonides. Furthermore, novel ternary, quaternary, and even quinary alloys continue to be introduced and improved with an eye toward achieving greater flexibility in the design of quantum heterostructure devices. In view of the rapid ongoing progress on a broad front, this review should

be regarded as a snapshot of the status at a given moment in time rather than the final word on III–V semiconductor band parameters. The goal has been to provide a one-stop summary of the present understanding, which will be revised, refined, and augmented by future experimental and theoretical investigations.

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